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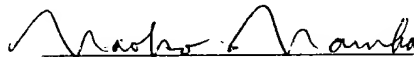


TRANSLATION

I, Naoko Namba, residing at 2-5-15-514, Honcho, Kawaguchi-shi, Saitama, Japan, state:

that I know well both the Japanese and English languages;  
that I translated, from Japanese into English, Japanese Patent Application No. 2000-299230, filed on September 29, 2000; and  
that the attached English translation is a true and accurate translation to the best of my knowledge and belief.

Dated: July 9, 2004

  
\_\_\_\_\_  
Naoko Namba

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[Title of the Invention] LIGHTSENSITIVE MATERIAL  
PACKAGE  
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[Name of Document]                      Specification

[Title of the Invention]   LIGHTSENSITIVE                      MATERIAL  
PACKAGE

[What is claimed is]

5                      [Claim 1]   A lightsensitive material package  
comprising a silver halide color photographic  
lightsensitive material having at least one each of a  
red-sensitive, green-sensitive and blue-sensitive  
silver halide emulsion layer on a support, the silver  
10   halide color photographic lightsensitive material being  
arranged in a common gas-phase atmosphere and sealed in  
the lightsensitive material package together with a  
plastic material member using a thermoplastic reclaimed  
resin, characterized in that 60% or more of the total  
15   projected area of silver halide grains contained in at  
least one of the light-sensitive emulsion layers is  
occupied by tabular silver halide grains having an  
aspect ratio of 8.0 or more, and the plastic material  
member is that produced from a resin to which a  
20   substance capable of adsorbing a substance having an  
adverse effect on a photographic property has been  
supplementally added prior to molding thereof.

                    [Claim 2]   The lightsensitive material package  
according to claim 1, characterized in that the tabular  
25   silver halide grains each have 10 or more dislocation  
lines per grain.

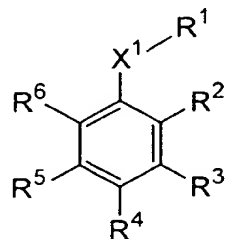
                    [Claim 3]   The lightsensitive material package



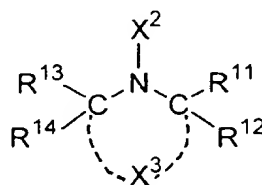
according to claim 1 or 2, characterized in that a twin plane spacing of the tabular silver halide grains is 0.020  $\mu\text{m}$  or less.

[Claim 4] A lightsensitive material package comprising a silver halide color photographic lightsensitive material having at least one each of a red-sensitive, green-sensitive and blue-sensitive silver halide emulsion layer on a support, the silver halide color photographic lightsensitive material being arranged in a common gas-phase atmosphere and sealed in the lightsensitive material package together with a plastic material member using a thermoplastic reclaimed resin, characterized in that 60% or more of the total projected area of silver halide grains contained in at least one of the light-sensitive emulsion layers is occupied by tabular silver halide grains having an aspect ratio of 8.0 or more, and the plastic material member is that produced from a resin to which a compound represented by the following general formula (TS-I) and/or (TS-II) has been supplementally added prior to molding thereof:

[Chem 1]



(TS-I)



(TS-II)

in the formula (TS-I),  $R^1$  represents a hydrogen

atom, a substituted or unsubstituted alkyl group  
(including cycloalkyl and bicycloalkyl groups),  
substituted or unsubstituted alkenyl group (including  
cycloalkenyl and bicycloalkenyl groups), substituted or  
5 unsubstituted aryl group, substituted or unsubstituted  
heterocyclic group, substituted or unsubstituted acyl  
group, substituted or unsubstituted alkoxycarbonyl  
group (including those whose alkyl moiety is cycloalkyl  
or bicycloalkyl), substituted or unsubstituted  
10 aryloxy carbonyl group, substituted or unsubstituted  
alkylsulfonyl group (including cycloalkylsulfonyl and  
bicycloalkylsulfonyl groups), substituted or  
unsubstituted arylsulfonyl group, substituted or  
unsubstituted phosphino group, substituted or  
15 unsubstituted phosphinoyl group, or a group of the  
formula  $-\text{Si}(\text{R}^{21})(\text{R}^{22})(\text{R}^{23})$ , wherein each of  $\text{R}^{21}$ ,  $\text{R}^{22}$   
and  $\text{R}^{23}$  independently represents a substituted or  
unsubstituted alkyl group, substituted or unsubstituted  
aryl group, substituted or unsubstituted alkoxy group,  
20 substituted or unsubstituted alkenyloxy group, or  
substituted or unsubstituted aryloxy group;  $-\text{X}^1-$   
represents  $-\text{O}-$ ,  $-\text{S}-$  or  $-\text{N}(\text{R}^{24})-$ , wherein  $\text{R}^{24}$  has the  
same meaning as  $\text{R}^1$ ; and  $\text{R}^2$ ,  $\text{R}^3$ ,  $\text{R}^4$ ,  $\text{R}^5$  and  $\text{R}^6$  may be  
the same or different from each other, and each thereof  
25 represents a hydrogen atom or a substituent, provided  
that  $\text{R}^1$  and  $\text{R}^2$ , or  $\text{R}^{24}$  and  $\text{R}^6$ , or  $\text{R}^1$  and  $\text{R}^{24}$ , may be  
bonded with each other to thereby form a 5- to 7-

membered ring, provided that  $R^2$  and  $R^3$ , or  $R^3$  and  $R^4$ ,  
or  $R^4$  and  $R^5$ , or  $R^5$  and  $R^6$ , may be bonded with each  
other to thereby form a 5- to 7-membered ring, or spiro  
ring or bicyclo ring, and provided that  $R^1$ ,  $R^2$ ,  $R^3$ ,  $R^4$ ,  
5  $R^5$ ,  $R^6$  and  $R^{24}$  are not simultaneously hydrogen atoms;  
and

in the formula (TS-II), each of  $R^{11}$ ,  $R^{12}$ ,  $R^{13}$  and  
 $R^{14}$  independently represents a hydrogen atom, an alkyl  
group (including cycloalkyl and bicycloalkyl groups),  
10 or alkenyl group (including cycloalkenyl and  
bicycloalkenyl groups), provided that  $R^{11}$  and  $R^{12}$ , or  
 $R^{13}$  and  $R^{14}$ , may be bonded with each other to thereby  
form a 5- to 7-membered ring;  $X^2$  represents a hydrogen  
atom, an alkyl group (including cycloalkyl and  
15 bicycloalkyl groups), alkenyl group (including  
cycloalkenyl and bicycloalkenyl groups), alkoxy group  
(including cycloalkyloxy and bicycloalkyloxy groups),  
alkenyloxy group (including cycloalkenyloxy and  
bicycloalkenyloxy groups), alkyl- and  
20 alkenyloxycarbonyl groups (including those whose alkyl  
moiety is cycloalkyl and bicycloalkyl, and those whose  
alkenyl moiety is cycloalkenyl and bicycloalkenyl),  
aryloxycarbonyl group, acyl group, acyloxy group,  
alkyloxycarbonyloxy group (including those whose alkyl  
25 moiety is cycloalkyl and bicycloalkyl),  
alkenyloxycarbonyloxy group (including those whose  
alkenyl moiety is cycloalkenyl and bicycloalkenyl),

aryloxycarbonyloxy group, alkyl- and alkenylsulfonyl groups (including those whose alkyl moiety is cycloalkyl and bicycloalkyl, and those whose alkenyl moiety is cycloalkenyl and bicycloalkenyl),  
5 arylsulfonyl group, alkyl- and alkenylsulfinyl groups (including those whose alkyl moiety is cycloalkyl and bicycloalkyl, and those whose alkenyl moiety is cycloalkenyl and bicycloalkenyl), arylsulfinyl group, sulfamoyl group, carbamoyl group, hydroxyl group, or  
10 oxy radical group; and  $X^3$  represents a group of nonmetallic atoms required for forming a 5- to 7-membered ring.

[Claim 5] The lightsensitive material package according to claim 4, characterized in that the tabular  
15 silver halide grains each have 10 or more dislocation lines per grain.

[Claim 6] The lightsensitive material package according to claim 4 or 5, characterized in that a twin plane spacing of the tabular silver halide grains is  
20 0.020  $\mu\text{m}$  or less.

[Claim 7] The lightsensitive material package according to any one of Claims 1 to 3, characterized in that the plastic material is that produced from a resin to which a compound represented by the general formula  
25 (TS-I) and/or (TS-II) described in claim 4 has been supplementally added prior to molding thereof.

[Claim 8] The lightsensitive material package

according to any one of Claims 4 to 6, characterized in that the plastic material is that produced from a resin to which a compound represented by the following general formula (TS-I) and/or (TS-II) has been  
5 supplementally added prior to molding thereof.

[Claim 9] The light-sensitive material package according to any one of claims 1 to 3 and 8, characterized in that the substance capable of adsorbing a substance having adverse effects on  
10 photographic properties is carbon black having an acetaldehyde gas equilibrium adsorption amount of 2 mg/g or more.

[Claim 10] The light-sensitive material package according to any one of claims 4 to 7 and 9,  
15 characterized in that the compound represented by the general formula (TS-I) and/or (TS-II) has a molecular weight of 300 or more.

[Detailed Description of the Invention]

[0001]

20 [Technical Field of the Invention]

The present invention relates to a light-sensitive material package. More particularly, the present invention relates to a light-sensitive material package in which a color photographic light-sensitive material  
25 having an emulsion of high aspect ratio is arranged in a common gas phase atmosphere and sealed with recycled plastic material members constituted of reclaimed

resins, the above reclaimed resins obtained through remelting of, for example, plastic material members made of thermoplastic resins.

[0002]

5 [Prior Art]

Reclaimed resins, as plastic material members, are used in, for example, a body of lens-fitted packaging unit and a spool or core of 35 mm patrone, and further used in, other than those accommodated together with a  
10 lightsensitive material, a photographic film case and other accommodating items. Further description will be made with reference to a lightsensitive material packaging unit including a built-in color negative photographic lightsensitive material and furnished with  
15 an exposure function (known as a lens-fitted film), now widespread for its convenience.

[0003]

Generally, the cartridge of lens-fitted lightsensitive material packaging unit is produced by  
20 molding a high impact polystyrene resin comprising a polystyrene resin (hereinafter referred to as "PS resin") to which a butadiene rubber polymerization has been carried out to thereby impart impact resistance, which high impact PS resin contains carbon black for  
25 light shielding and various additives for moldability enhancement.

This cartridge of lens-fitted lightsensitive

material packaging unit, because of its built-in  
photographic film, is constituted of resins selected  
with the care that there should be no fogging or  
abnormal sensitivity attributed to gases released from  
5 impurities or resin ingredients contained therein.

[0004]

Each lens-fitted lightsensitive material packaging  
unit, after photographing, is sent to a laboratory,  
where the film having undergone photographing is taken  
10 out, developed and fixed on a photographic paper.

The packaging unit from which the photographic  
film has been removed, for the purpose of environmental  
protection and resource saving, is collected, converted  
to reclaimed resins through steps such as disassembly,  
15 classification, crushing and melting, and reutilized as  
a molding material for the cartridge of lens-fitted  
lightsensitive material packaging unit or the like.

[0005]

With respect to reclaimed resins, the use thereof  
20 in parts brought into contact with the photographic  
film has been restricted because of the reclamation  
from products collected on the market, in particular  
because of the concern about any increase of the  
occurrence of photographically harmful substances  
25 attributed to resin pyrolysis by an increase of heat  
history and also the concern about the inclusion of  
substances harmful to photographic film as described in

Jpn. Pat. Appln. KOKAI Publication No. (hereinafter referred to as JP-A-) 5-165154.

[0006]

5 With respect to harmful substances from thermoplastic resins which have adverse effects on photographic lightsensitive materials, it is presumed that, as described in JP-A's-6-130565 and 6-67356, aldehydes, ketones, free sulfur, cyanide and other compounds resulting from resin pyrolysis are gasified  
10 and adsorbed on film surface to thereby denature the silver halides of the film with the result that the photographic properties are changed.

The generation of harmful substances from such resins would be attributable to carbon black, various  
15 additives and rubber components and, with respect to reclaimed resins, to impurities adhered thereto on the market.

[0007]

20 As a result of practical fogging tests of a high-speed special lightsensitive material it has been found that no adverse effect is exerted in the use of a virgin resin while an adverse effect disabling any practical use occurs in the use of a reclaimed resin.

[0008]

25 With respect to gases which are harmful to photographic films, it is described in JP-A-6-130565 that, the greater the heat history frequency at molding



or extrusion in the presence of an antioxidant, the greater the evaporation of impurities, so that the amount of antioxidant is less in the reclaimed resin than in the virgin resin. This would reflect that, with respect to the reclaimed resin, the heat history is increased to thereby reduce the amount of antioxidant and cause new photographically harmful gases to occur from the PS resin containing rubber components. Further, it is described in JP-A-6-67356 that harmful substances are suppressed by the addition of an antioxidant or the like. However, in the use of reclaimed resin, the above component reduction occurs with the result that the effect exerted by the virgin resin is diminished.

15 [0009]

On the other hand, a speed increase of lightsensitive material has been and is demanded for enhancing the quality of image obtained by the lens-fitted lightsensitive material packaging unit. Various researches for improvement have been carried out in order to attain a photographic speed increase. With respect to the use of tabular emulsion, U.S.P. No. 4,433,048 discloses a particular process for producing tabular silver halide grains and a method of using the same. It is known that the configuration of tabular grains is advantageous in, for example, improvement as to the relationship of photographic

speed/graininess, sharpness enhancement attributed to specific optical characteristics of tabular grains and increase of covering power. Such a technology that high speed, enhanced graininess and sharpness and  
5 excellent pressure resistance can simultaneously be attained by the use of tabular grains of 5 or more aspect ratio having dislocation lines in a lightsensitive material of 320 or more ISO speed in an emulsion layer most remote from its support is  
10 disclosed in JP-A-5-341459.

[0010]

However, the problem that the use of tabular silver halide grains of 8 or more aspect ratio in a high-speed layer for the purpose of photographic speed  
15 increase and image quality enhancement invites fogging of lightsensitive material, especially an increase of fogging by prolonged storage, has surfaced. Attaining an improvement on this problem is now an important task.

Moreover, with respect to the deterioration of  
20 photographic properties by harmful substances in the lens-fitted lightsensitive material packaging unit which includes the above reclaimed resin, the greater the speed of lightsensitive material, the greater the influence of harmful substances on the lightsensitive  
25 material. Therefore, in particular, the use of reclaimed resin has been restricted in the lens-fitted lightsensitive material packaging unit wherein a high-

speed lightsensitive material is accommodated.

[0011]

[Objects of the Invention]

It is an object of the present invention to  
5 provide a lightsensitive material package wherein a  
molding containing a substance capable of adsorbing  
harmful substances, in particular gasified harmful  
substances, in reclaimed resins or capable of  
suppressing the occurrence thereof, which molding has  
10 thus no adverse effects on photographic lightsensitive  
materials, in particular a photographic lightsensitive  
material of high-speed film, is accommodated in order  
to expand the use of reclaimed resins in plastic  
material members.

15 [0012]

[Means for Achieving the Objects]

This object can be attained by the following means.

[0013]

(1) A lightsensitive material package comprising  
20 a silver halide color photographic lightsensitive  
material having at least one each of a red-sensitive,  
green-sensitive and blue-sensitive silver halide  
emulsion layer on a support, the silver halide color  
photographic lightsensitive material being arranged in  
25 a common gas-phase atmosphere and sealed in the  
lightsensitive material package together with a plastic  
material member using a thermoplastic reclaimed resin,

characterized in that 60% or more of the total  
projected area of silver halide grains contained in at  
least one of the light-sensitive emulsion layers is  
occupied by tabular silver halide grains having an  
5 aspect ratio of 8.0 or more, and the plastic material  
member is that produced from a resin to which a  
substance capable of adsorbing a substance having an  
adverse effect on a photographic property has been  
supplementally added prior to molding thereof.

10 [0014]

(2) The lightsensitive material package according  
to (1) above, characterized in that the tabular silver  
halide grains each have 10 or more dislocation lines  
per grain.

15 [0015]

(3) The lightsensitive material package according  
to claim 1 or 2, characterized in that a twin plane  
spacing of the tabular silver halide grains is 0.020  $\mu\text{m}$   
or less.

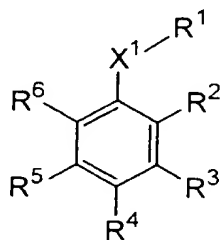
20 [0016]

(4) A lightsensitive material package comprising  
a silver halide color photographic lightsensitive  
material having at least one each of a red-sensitive,  
green-sensitive and blue-sensitive silver halide  
25 emulsion layer on a support, the silver halide color  
photographic lightsensitive material being arranged in  
a common gas-phase atmosphere and sealed in the

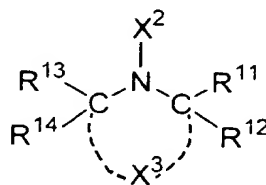
lightsensitive material package together with a plastic material member using a thermoplastic reclaimed resin, characterized in that 60% or more of the total projected area of silver halide grains contained in at least one of the light-sensitive emulsion layers is occupied by tabular silver halide grains having an aspect ratio of 8.0 or more, and the plastic material member is that produced from a resin to which a compound represented by the following general formula (TS-I) and/or (TS-II) has been supplementally added prior to molding thereof:

[0017]

[Chem 2]



(TS-I)



(TS-II)

[0018]

In the formula (TS-I), R<sup>1</sup> represents a hydrogen atom, a substituted or unsubstituted alkyl group (including cycloalkyl and bicycloalkyl groups), substituted or unsubstituted alkenyl group (including cycloalkenyl and bicycloalkenyl groups), substituted or unsubstituted aryl group, substituted or unsubstituted heterocyclic group, substituted or unsubstituted acyl group, substituted or unsubstituted alkoxycarbonyl group (including those whose alkyl moiety is cycloalkyl

or bicycloalkyl), substituted or unsubstituted  
aryloxycarbonyl group, substituted or unsubstituted  
alkylsulfonyl group (including cycloalkylsulfonyl and  
bicycloalkylsulfonyl groups), substituted or  
5 unsubstituted arylsulfonyl group, substituted or  
unsubstituted phosphino group, substituted or  
unsubstituted phosphinoyl group, or a group of the  
formula  $-\text{Si}(\text{R}^{21})(\text{R}^{22})(\text{R}^{23})$ , wherein each of  $\text{R}^{21}$ ,  $\text{R}^{22}$   
and  $\text{R}^{23}$  independently represents a substituted or  
10 unsubstituted alkyl group, substituted or unsubstituted  
aryl group, substituted or unsubstituted alkoxy group,  
substituted or unsubstituted alkenyloxy group, or  
substituted or unsubstituted aryloxy group;  $-\text{X}^1-$   
represents  $-\text{O}-$ ,  $-\text{S}-$  or  $-\text{N}(\text{R}^{24})-$ , wherein  $\text{R}^{24}$  has the  
15 same meaning as  $\text{R}^1$ ; and  $\text{R}^2$ ,  $\text{R}^3$ ,  $\text{R}^4$ ,  $\text{R}^5$  and  $\text{R}^6$  may be  
the same or different from each other, and each thereof  
represents a hydrogen atom or a substituent, provided  
that  $\text{R}^1$  and  $\text{R}^2$ , or  $\text{R}^{24}$  and  $\text{R}^6$ , or  $\text{R}^1$  and  $\text{R}^{24}$ , may be  
bonded with each other to thereby form a 5- to 7-  
20 membered ring, provided that  $\text{R}^2$  and  $\text{R}^3$ , or  $\text{R}^3$  and  $\text{R}^4$ ,  
or  $\text{R}^4$  and  $\text{R}^5$ , or  $\text{R}^5$  and  $\text{R}^6$ , may be bonded with each  
other to thereby form a 5- to 7-membered ring, or spiro  
ring or bicyclo ring, and provided that  $\text{R}^1$ ,  $\text{R}^2$ ,  $\text{R}^3$ ,  $\text{R}^4$ ,  
 $\text{R}^5$ ,  $\text{R}^6$  and  $\text{R}^{24}$  are not simultaneously hydrogen atoms.

25 [0019]

In the formula (TS-II), each of  $\text{R}^{11}$ ,  $\text{R}^{12}$ ,  $\text{R}^{13}$  and  
 $\text{R}^{14}$  independently represents a hydrogen atom, an alkyl

group (including cycloalkyl and bicycloalkyl groups),  
or alkenyl group (including cycloalkenyl and  
bicycloalkenyl groups), provided that R<sup>11</sup> and R<sup>12</sup>, or  
R<sup>13</sup> and R<sup>14</sup>, may be bonded with each other to thereby  
5 form a 5- to 7-membered ring; X<sup>2</sup> represents a hydrogen  
atom, an alkyl group (including cycloalkyl and  
bicycloalkyl groups), alkenyl group (including  
cycloalkenyl and bicycloalkenyl groups), alkoxy group  
(including cycloalkyloxy and bicycloalkyloxy groups),  
10 alkenyloxy group (including cycloalkenyloxy and  
bicycloalkenyloxy groups), alkyl- and  
alkenyloxycarbonyl groups (including those whose alkyl  
moiety is cycloalkyl and bicycloalkyl, and those whose  
alkenyl moiety is cycloalkenyl and bicycloalkenyl),  
15 aryloxycarbonyl group, acyl group, acyloxy group,  
alkyloxycarbonyloxy group (including those whose alkyl  
moiety is cycloalkyl and bicycloalkyl),  
alkenyloxycarbonyloxy group (including those whose  
alkenyl moiety is cycloalkenyl and bicycloalkenyl),  
20 aryloxycarbonyloxy group, alkyl- and alkenylsulfonyl  
groups (including those whose alkyl moiety is  
cycloalkyl and bicycloalkyl, and those whose alkenyl  
moiety is cycloalkenyl and bicycloalkenyl),  
arylsulfonyl group, alkyl- and alkenylsulfinyl groups  
25 (including those whose alkyl moiety is cycloalkyl and  
bicycloalkyl, and those whose alkenyl moiety is  
cycloalkenyl and bicycloalkenyl), arylsulfinyl group,

sulfamoyl group, carbamoyl group, hydroxyl group, or oxy radical group; and  $X^3$  represents a group of nonmetallic atoms required for forming a 5- to 7-membered ring.

5 [0020]

(5) The lightsensitive material package according to (4) above, characterized in that the tabular silver halide grains each have 10 or more dislocation lines per grain.

10 [0021]

(6) The lightsensitive material package according to (4) or (5) above, characterized in that a twin plane spacing of the tabular silver halide grains is 0.020  $\mu\text{m}$  or less.

15 [0022]

(7) The lightsensitive material package according to any one of (1) to (3) above, characterized in that the plastic material is that produced from a resin to which a compound represented by the general formula (TS-I) and/or (TS-II) described in claim 4 has been supplementally added prior to molding thereof.

[0023]

25 (8) The lightsensitive material package according to any one of (4) to (6), characterized in that the plastic material is that produced from a resin to which a compound represented by the following general formula (TS-I) and/or (TS-II) has been supplementally added



prior to molding thereof.

[0024]

(9) The lightsensitive material package according to any one of (1) to (3) and (8) above, characterized in that the substance capable of adsorbing a substance having adverse effects on photographic properties is carbon black having an acetaldehyde gas equilibrium adsorption amount of 2 mg/g or more.

[0025]

(10) The lightsensitive material package according to any one of (4) to (7) and (9) above, characterized in that the compound represented by the general formula (TS-I) and/or (TS-II) has a molecular weight of 300 or more.

[0026]

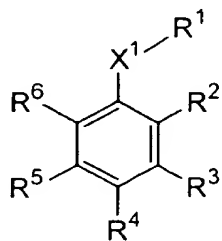
[Embodiments of the Invention]

The present invention will be explained in more detail below.

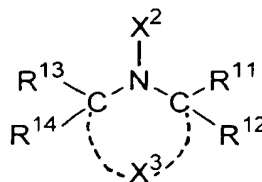
The compound represented by the following general formula (TS-I) or (TS-II) will be explained in detail:

[0027]

[Chem 3]



(TS-I)



(TS-II)

[0028]

In the formula (TS-I),  $R^1$  represents a hydrogen atom; a substituted or unsubstituted alkyl group (including cycloalkyl and bicycloalkyl groups), (preferably those having 1 to 30 carbon atoms, e.g., methyl, ethyl, n-butyl, cyclohexyl, and bicyclo[1,2,2]heptan-2-yl); substituted or unsubstituted alkenyl group (including cycloalkenyl and bicycloalkenyl groups) (preferably those having 3 to 30 carbon atoms, allyl, geranyl, and 2-cyclohexen-1-yl); substituted or unsubstituted aryl group (preferably those having 6 to 30 carbon atoms, e.g., phenyl, p-tolyl); substituted or unsubstituted heterocyclic group (preferably 5- or 6-membered, substituted or unsubstituted, aromatic or nonaromatic heterocycle from which a hydrogen atom is removed, more preferably, 5- or 6-membered aromatic heterocycle having 3 to 30 carbon atoms from which a hydrogen atom is removed, e.g., 2-furyl, 2-thienyl, and 2-pyrimidinyl); substituted or unsubstituted acyl group (preferably those having 1 to 30 carbon atoms, e.g., formyl, acetyl, and pivaloyl); substituted or unsubstituted alkoxycarbonyl group (preferably those having 2 to 30 carbon atoms, e.g., methoxycarbonyl, ethoxycarbonyl, and decyloxycarbonyl); substituted or unsubstituted aryloxycarbonyl group (preferably those having 7 to 30 carbon atoms, e.g., phenoxycarbonyl); substituted or unsubstituted alkylsulfonyl group (including

cycloalkylsulfonyl and bicycloalkylsulfonyl)  
(preferably those having 1 to 30 carbon atoms, e.g.,  
methanesulfonyl, ethanesulfonyl, and  
cyclohexylsulfonyl); substituted or unsubstituted  
5 arylsulfonyl group (preferably those having 6 to 30  
carbon atoms e.g., toluenesulfonyl, and  
benzenesulfonyl), substituted or unsubstituted  
phosphino group (preferably those having 0 to 30 carbon  
atoms, e.g., diphenylphosphino); substituted or  
10 unsubstituted phosphinoyl group (preferably those  
having 0 to 30 carbon atoms, e.g.,  
diphenylphosphinoyl); or  $-\text{SiR}^{21}\text{R}^{22}\text{R}^{23}$ , wherein each of  
 $\text{R}^{21}$ ,  $\text{R}^{22}$  and  $\text{R}^{23}$  independently represents a substituted  
or unsubstituted alkyl group (preferably those having 1  
15 to 30 carbon atoms, e.g., methyl), substituted or  
unsubstituted aryl group (preferably those having 6 to  
30 carbon atoms, e.g., phenyl), substituted or  
unsubstituted alkoxy group (preferably those having 1  
to 30 carbon atoms, e.g., methoxy), substituted or  
20 unsubstituted alkenyloxy group (preferably those having  
3 to 30 carbon atoms, e.g., geranyloxy), or substituted  
or unsubstituted aryloxy group (preferably those having  
6 to 30 carbon atoms, e.g., phenoxy).

[0029]

25  $\text{R}^2$ ,  $\text{R}^3$ ,  $\text{R}^4$ ,  $\text{R}^5$  and  $\text{R}^6$  independently represent a  
hydrogen, or halogen atom; or an alkyl group (including  
cycloalkyl and bicycloalkyl groups); alkenyl group

(including cycloalkenyl and bicycloalkenyl groups);  
alkynyl group; aryl group; heterocyclic group; cyano  
group; hydroxyl group; nitro group; carboxyl group;  
alkoxy group; aryloxy group; silyloxy group;  
5 heterocyclic oxy group; acyloxy group; carbamoyloxy  
group; alkoxycarbonyloxy group; aryloxycarbonyloxy  
group; amino group (including an anilino group);  
acylamino group; aminocarbonylamino group;  
alkoxycarbonylamino group; aryloxycarbonylamino group;  
10 sulfamoylamino group; alkyl- and arylsulfonylamino  
groups; mercapto group; alkylthio group; arylthio  
group; heterocyclic thio group; sulfamoyl group; sulfo  
group; alkyl- and arylsulfinyl groups; alkyl- and  
aryl-sulfonyl groups; acyl group; aryloxycarbonyl group;  
15 alkoxycarbonyl group; carbamoyl group; aryl- and  
heterocyclic azo groups; imido group; phosphino group;  
phosphinyl group; phosphinyloxy group; phosphinylamino  
group; or silyl group.

[0030]

20 More specifically,  $R^2$ ,  $R^3$ ,  $R^4$ ,  $R^5$  and  $R^6$   
independently represent a hydrogen atom; or a halogen  
atom (e.g., a chlorine atom, bromine atom, and iodine  
atom); or an alkyl group (which represents a  
straight-chain, branched, or cyclic, substituted or  
25 unsubstituted alkyl group. Examples are an alkyl group  
(preferably those having 1 to 30 carbon atoms, e.g.,  
methyl, ethyl, n-propyl, isopropyl, t-butyl, n-octyl,

eicosyl, 2-chloroethyl, 2-cyanoethyl, and 2-ethylhexyl),  
a cycloalkyl group (preferably substituted or  
unsubstituted cycloalkyl group having 3 to 30 carbon  
atoms, e.g., cyclohexyl, cyclopentyl, and  
5 4-n-dodecylcyclohexyl), a bicycloalkyl group  
(preferably a substituted or unsubstituted bicycloalkyl  
group having 5 to 30 carbon atoms, i.e., a monovalent  
group obtained by removing one hydrogen atom from a  
bicycloalkane having 5 to 30 carbon atoms. Examples  
10 are bicyclo[1,2,2]heptane-2-yl and  
bicyclo[2,2,2]octane-3-yl). Also an alkyl group having  
more cyclic structure such as a tricyclic alkyl group  
is included. The alkyl group to be described below,  
such as the alkyl group of an alkylthio group, also  
15 includes the concept of the alkyl group mentioned  
above.); alkenyl group (which represents a  
straight-chain, branched, or cyclic, substituted or  
unsubstituted alkenyl group. Examples are an alkenyl  
group (preferably a substituted or unsubstituted  
20 alkenyl group having 2 to 30 carbon atoms, e.g., vinyl,  
allyl, prenyl, geranyl, and oleyl), cycloalkenyl group  
(preferably a substituted or unsubstituted cycloalkenyl  
group having 3 to 30 carbon atoms, i.e., a monovalent  
group obtained by removing one hydrogen atom from a  
25 cycloalkene having 3 to 30 carbon atoms. Examples are  
2-cyclopentene-1-yl and 2-cyclohexene-1-yl),  
bicycloalkenyl group (a substituted or unsubstituted

bicycloalkenyl group, preferably a substituted or unsubstituted bicycloalkenyl group having 5 to 30 carbon atoms, i.e., a monovalent group obtained by removing one hydrogen atom from bicycloalkene having one double bond. Examples are bicyclo[2,2,1]hept-2-ene-1-yl and bicyclo[2,2,2]oct-2-ene-4-yl); an alkynyl group (preferably a substituted or unsubstituted alkynyl group having 2 to 30 carbon atoms, e.g., ethynyl, propargyl, and trimethylsilylethynyl); aryl group (preferably a substituted or unsubstituted aryl group having 6 to 30 carbon atoms, e.g., phenyl, p-tolyl, naphthyl, m-chlorophenyl, and o-hexadecanoylamino-phenyl); heterocyclic group (preferably a monovalent group obtained by removing one hydrogen atom from a 5- or 6-membered, substituted or unsubstituted, aromatic or nonaromatic heterocyclic compound, and more preferably, a 5- or 6-membered aromatic heterocyclic group having 3 to 30 carbon atoms. Examples are 2-furyl, 2-thienyl, 2-pyrimidinyl, and 2-benzothiazolyl); cyano group; hydroxyl group; nitro group; carboxyl group; and alkoxy group (preferably a substituted or unsubstituted alkoxy group having 1 to 30 carbon atoms, e.g., methoxy, ethoxy, isopropoxy, t-butoxy, n-octyloxy, and 2-methoxyethoxy); an aryloxy group (preferably a substituted or unsubstituted aryloxy group having 6 to 30 carbon atoms, e.g.,

phenoxy, 2-methylphenoxy, 4-t-butylphenoxy,  
3-nitrophenoxy, and 2-tetradecanoylamino-phenoxy),  
silyloxy group (preferably a silyloxy group having 3 to  
20 carbon atoms, e.g., trimethylsilyloxy and  
5 t-butyldimethylsilyloxy); heterocyclic oxy group  
(preferably a substituted or unsubstituted heterocyclic  
oxy group having 2 to 30 carbon atoms, e.g.,  
1-phenyltetrazole-5-oxy and 2-tetrahydropyranyloxy);  
and acyloxy group (preferably a formyloxy group, a  
10 substituted or unsubstituted alkylcarbonyloxy group  
having 2 to 30 carbon atoms, and a substituted or  
unsubstituted arylcarbonyloxy group having 7 to 30  
carbon atoms, e.g., formyloxy, acetyloxy, pivaloyloxy,  
stearoyloxy, benzoyloxy, and  
15 p-methoxyphenylcarbonyloxy); a carbamoyloxy group  
(preferably a substituted or unsubstituted carbamoyloxy  
group having 1 to 30 carbon atoms, e.g.,  
N,N-dimethylcarbamoyloxy, N,N-diethylcarbamoyloxy,  
morpholinocarbonyloxy, N,N-di-n-octylaminocarbonyloxy,  
20 and N-n-octylcarbamoyloxy); alkoxycarbonyloxy group  
(preferably a substituted or unsubstituted  
alkoxycarbonyloxy group having 2 to 30 carbon atoms,  
e.g., methoxycarbonyloxy, ethoxycarbonyloxy,  
t-butoxycarbonyloxy, and n-octylcarbonyloxy); and  
25 aryloxycarbonyloxy group (preferably a substituted or  
unsubstituted aryloxycarbonyloxy group having 7 to 30  
carbon atoms, e.g., phenoxycarbonyloxy,

p-methoxyphenoxy-carbonyloxy, and  
p-(n-hexadecyloxy)phenoxy-carbonyloxy); an amino group  
(preferably an unsubstituted amino group, a substituted  
or unsubstituted alkylamino group having 1 to 30 carbon  
5 atoms, and a substituted or unsubstituted anilino group  
having 6 to 30 carbon atoms, e.g., amino, methylamino,  
dimethylamino, anilino, N-methyl-anilino, and  
diphenylamino); acylamino group (preferably a  
formylamino group, a substituted or unsubstituted  
10 alkylcarbonylamino group having 2 to 30 carbon atoms,  
and a substituted or unsubstituted arylcarbonylamino  
group having 7 to 30 carbon atoms, e.g., formylamino,  
acetylamino, pivaloylamino, lauroylamino, benzoylamino,  
and 3,4,5-tri-(n-octyloxyphenyl)carbonylamino); and  
15 aminocarbonylamino group (preferably a substituted or  
unsubstituted aminocarbonylamino having 1 to 30 carbon  
atoms, e.g., carbamoylamino,  
N,N-dimethylaminocarbonylamino,  
N,N-diethylaminocarbonylamino, and  
20 morpholinocarbonylamino); an alkoxycarbonylamino group  
(preferably a substituted or unsubstituted  
alkoxycarbonylamino group having 2 to 30 carbon atoms,  
e.g., methoxycarbonylamino, ethoxycarbonylamino,  
t-butoxycarbonylamino, n-octadecyloxycarbonylamino, and  
25 N-methyl-methoxycarbonylamino); aryloxycarbonylamino  
group (preferably a substituted or unsubstituted  
aryloxycarbonylamino group having 7 to 30 carbon atoms,



e.g., phenoxycarbonylamino,  
p-chlorophenoxycarbonylamino, and  
m-(n-octyloxy)phenoxycarbonylamino); sulfamoylamino  
group (preferably a substituted or unsubstituted  
5 sulfamoylamino group having 0 to 30 carbon atoms, e.g.,  
sulfamoylamino, N,N-dimethylaminosulfonylamino, and  
N-n-octylaminosulfonylamino); an alkylsulfonylamino and  
arylsulfonylamino groups (preferably a substituted or  
unsubstituted alkylsulfonylamino having 1 to 30 carbon  
10 atoms, and a substituted or unsubstituted  
arylsulfonylamino having 6 to 30 carbon atoms, e.g.,  
methylsulfonylamino, butylsulfonylamino,  
phenylsulfonylamino, 2,3,5-trichlorophenylsulfonylamino,  
and p-methylphenylsulfonylamino); mercapto group;  
15 alkylthio group (preferably a substituted or  
unsubstituted alkylthio group having 1 to 30 carbon  
atoms, e.g., methylthio, ethylthio, and  
n-hexadecylthio); arylthio group (preferably a  
substituted or unsubstituted arylthio group having 6 to  
20 30 carbon atoms, e.g., phenylthio, p-chlorophenylthio,  
and m-methoxyphenylthio); and heterocyclic thio group  
(preferably a substituted or unsubstituted heterocyclic  
thio group having 2 to 30 carbon atoms, to which an  
aromatic ring such as a benzene ring may be condensed,  
25 e.g., 2-benzothiazolylthio and  
1-phenyl-tetrazole-5-ylthio); a sulfamoyl group  
(preferably a substituted or unsubstituted sulfamoyl

group having 0 to 30 carbon atoms, e.g.,  
N-ethylsulfamoyl, N-(3-dodecyloxypropyl)sulfamoyl,  
N,N-dimethylsulfamoyl, N-acetylsulfamoyl,  
N-benzoylsulfamoyl, N-(N'-phenylcarbamoyl)sulfamoyl);  
5 sulfo group; alkylsulfinyl and arylsulfinyl groups  
(preferably a substituted or unsubstituted  
alkylsulfinyl group having 1 to 30 carbon atoms, and a  
substituted or unsubstituted arylsulfinyl group having  
6 to 30 carbon atoms, e.g., methylsulfinyl,  
10 ethylsulfinyl, phenylsulfinyl, and  
p-methylphenylsulfinyl); an alkylsulfonyl and  
arylsulfonyl groups (preferably a substituted or  
unsubstituted alkylsulfonyl group having 1 to 30 carbon  
atoms, and a substituted or unsubstituted arylsulfonyl  
15 group having 6 to 30 carbon atoms, e.g., methylsulfonyl,  
ethylsulfonyl, phenylsulfonyl, and  
p-methylphenylsulfonyl); acyl group (preferably a  
formyl group, substituted or unsubstituted  
alkylcarbonyl group having 2 to 30 carbon atoms, a  
20 substituted or unsubstituted arylcarbonyl group having  
7 to 30 carbon atoms, and a substituted or  
unsubstituted heterocycliccarbonyl group, whose carbon  
atom in the heterocyclic ring bonds to the carbonyl  
group thereof, e.g., acetyl, pivaloyl, 2-chloroacetyl,  
25 stearoyl, benzoyl, p-(n-octyloxy)phenylcarbonyl, 2-  
pyridylcarbonyl and 2-furylcarbonyl); aryloxycarbonyl  
group (preferably a substituted or unsubstituted

aryloxycarbonyl group having 7 to 30 carbon atoms, e.g.,  
phenoxycarbonyl, o-chlorophenoxycarbonyl,  
m-nitrophenoxycarbonyl, and  
p-(t-butyl)phenoxycarbonyl); and an alkoxycarbonyl  
5 group (e.g., a substituted or unsubstituted  
alkoxycarbonyl group having 2 to 30 carbon atoms, e.g.,  
methoxycarbonyl, ethoxycarbonyl, t-butoxycarbonyl, and  
n-octadecyloxycarbonyl); a carbamoyl group (preferably  
a substituted or unsubstituted carbamoyl having 1 to 30  
10 carbon atoms, e.g., carbamoyl, N-methylcarbamoyl,  
N,N-dimethylcarbamoyl, N,N-di-(n-octyl)carbamoyl, and  
N-(methylsulfonyl)carbamoyl); arylazo and heterocyclic  
azo groups (preferably a substituted or unsubstituted  
arylazo group having 6 to 30 carbon atoms, and a  
15 substituted or unsubstituted heterocyclic azo group  
having 3 to 30 carbon atoms, e.g., phenylazo,  
p-chlorophenylazo, and  
5-ethylthio-1,3,4-thiadiazole-2-ylazo); imido group  
(preferably N-succinimido and N-phthalimido); phosphino  
20 group (preferably a substituted or unsubstituted  
phosphino group having 2 to 30 carbon atoms, e.g.,  
dimethylphosphino, diphenylphosphino, and  
methylphenoxyphosphino); and phosphinyl group  
(preferably a substituted or unsubstituted phosphinyl  
25 group having 0 to 30 carbon atoms, e.g., phosphinyl,  
dioctyloxyphosphinyl, and diethoxyphosphinyl).

R<sup>2</sup>, R<sup>3</sup>, R<sup>4</sup>, R<sup>5</sup> and R<sup>6</sup> independently also represent

a phosphinyloxy group (preferably a substituted or unsubstituted phosphinyloxy group having 2 to 30 carbon atoms, e.g., diphenoxyphosphinyloxy and dioctyloxyphosphinyloxy); phosphinylamino group  
5 (preferably a substituted or unsubstituted phosphinylamino group having 2 to 30 carbon atoms, e.g., dimethoxyphosphinylamino and dimethylaminophosphinylamino); and silyl group (preferably a substituted or unsubstituted silyl group  
10 having 3 to 30 carbon atoms, e.g., trimethylsilyl, t-butyl dimethylsilyl, and phenyl dimethylsilyl).

[0031]

Of the above substituents, those having a hydrogen atom may be further substituted by the above groups by  
15 removing the hydrogen atom. Examples of such substituents are an alkylcarbonylamino sulfonyl group, arylcarbonylamino sulfonyl group, alkylsulfonylamino carbonyl group, and arylsulfonylamino carbonyl group. Examples of these  
20 groups are methylsulfonylamino carbonyl, p-methylphenylsulfonylamino carbonyl, acetylaminosulfonyl, and benzoylamino sulfonyl groups.

[0032]

The structures of the formula (TS-1) are  
25 preferably those where  $R^1$  is a hydrogen atom, a substituted or unsubstituted alkyl group having 1 to 30 carbon atoms (including cycloalkyl and bicycloalkyl

groups); substituted or unsubstituted alkenyl group having 3 to 30 carbon atoms (including cycloalkenyl and bicycloalkenyl groups); or substituted or unsubstituted aryl group having 6 to 30 carbon atoms.

5 [0033]

-X<sup>1</sup>- is preferably -O-, or -N(R<sup>24</sup>)-, wherein R<sup>24</sup> is preferably a substituted or unsubstituted alkyl group having 1 to 30 carbon atoms.

[0034]

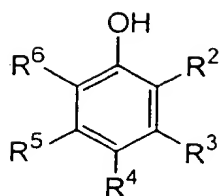
10 Preferably, R<sup>2</sup>, R<sup>3</sup>, R<sup>4</sup>, R<sup>5</sup> and R<sup>6</sup> may be the same or different from each other, and each thereof represents a hydrogen atom, a substituted or unsubstituted alkyl group having 1 to 30 carbon atoms, substituted or unsubstituted alkoxy group having 1 to  
15 30 carbon atoms, substituted or unsubstituted acylamino group having 1 to 30 carbon atoms, or a halogen atom. R<sup>4</sup> is preferably a substituted or unsubstituted alkyl group having 1 to 30 carbon atoms, more preferably, an alkyl group having a total carbon atoms including those  
20 of a substituent attached thereto of 4 or more.

[0035]

Among the compounds of the general formula (TS-I), those represented by the following formulae (TS-I- $\alpha$ ) and (TS-I- $\beta$ ) are preferred:

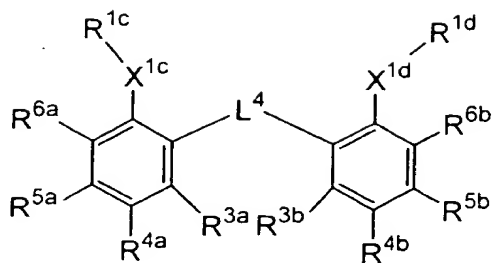
25 [0036]

[Chem 4]



(TS-I-α)

[0037]



(TS-I-β)

In the formula (TS-I-α), R², R³, R⁵ and R⁶ each independently have the same meaning as the R², R³, R⁵ and R⁶ of the general formula (TS-I).

[0038]

In the formula (TS-I-β), R³ᵃ, R³ᵇ, R⁴ᵃ, R⁴ᵇ, R⁵ᵃ, R⁵ᵇ, R⁶ᵃ and R⁶ᵇ each independently have the same meaning as the R³, R⁴, R⁵ and R⁶ of the general formula (TS-I). X¹ᶜ and X¹ᵈ each independently have the same meaning as the X¹ of the general formula (TS-I). R¹ᶜ and R¹ᵈ each independently have the same meaning as the R¹ of the general formula (TS-I). L⁴ represents a substituted or unsubstituted alkylene group having 1 to 20 carbon atoms.

[0039]

Among the compounds of the formula (TS-I-α), those wherein each of R², R³, R⁵ and R⁶ independently represents a hydrogen atom, a substituted or unsubstituted alkyl group having 1 to 20 carbon atoms, a halogen atom, a substituted or unsubstituted alkoxy group having 1 to 20 carbon atoms or an acylamino group having 1 to 20 carbon atoms are preferred. Among the

preferable groups of  $R^2$ ,  $R^3$ ,  $R^5$  and  $R^6$ , they independently represent more preferably a hydrogen atom, or a substituted or unsubstituted alkyl group having 1 to 8 carbon atoms.

5 [0040]

Of the preferable structure of formula (TS-I- $\alpha$ ),  $R^6$  is preferably an unsubstituted *tert*-alkyl group having 3 to 8 carbon atoms,  $R^5$  is a hydrogen atom,  $R^4$  is a substituted or unsubstituted alkyl group having 1 to 30 carbon atoms, either  $R^2$  or  $R^3$  is a hydrogen atom, and the other is an alkyl group having 1 to 8 carbon atoms.

[0041]

The compound having the structure of the formula (TS-I- $\beta$ ) is preferably those wherein each of  $R^{3a}$ ,  $R^{3b}$ ,  $R^{4a}$ ,  $R^{4b}$ ,  $R^{5a}$ ,  $R^{5b}$ ,  $R^{6a}$  and  $R^{6b}$  independently represents a hydrogen atom, a substituted or unsubstituted alkyl group having 1 to 20 carbon atoms, a halogen atom or an acylamino group having 1 to 20 carbon atoms. Preferably, each of  $X^{1c}$  and  $X^{1d}$  independently represents -O-. Further, preferably, each of  $R^{1c}$  and  $R^{1d}$  independently represents a hydrogen atom, a substituted or unsubstituted alkyl group having 1 to 20 carbon atoms, an acylamino group having 2 to 20 carbon atoms, or a substituted or unsubstituted alkenyl group having 3 to 20 carbon atoms.  $L^4$  preferably represents an unsubstituted alkylene group having 1 to

20 carbon atoms.

[0042]

More preferably, R<sup>1c</sup> and R<sup>1d</sup> simultaneously represent hydrogen atoms, and R<sup>3a</sup>, R<sup>3b</sup>, R<sup>5a</sup>, and R<sup>5b</sup> simultaneously represent hydrogen atoms. L<sup>4</sup> more preferably represents an unsubstituted alkylene group having 1 to 8 carbon atoms.

[0043]

More preferable compounds having the structure of formula (TS-I-β) are those in which R<sup>4a</sup>, R<sup>4b</sup>, R<sup>6a</sup>, and R<sup>6b</sup> each independently represent unsubstituted alkyl group having 1 to 8 carbon atoms, all of R<sup>1c</sup>, R<sup>1d</sup>, R<sup>3a</sup>, R<sup>3b</sup>, R<sup>5a</sup> and R<sup>5b</sup> simultaneously represent hydrogen atoms, both of X<sup>1c</sup> and X<sup>1d</sup> represent -O-, and L<sup>4</sup> represents an unsubstituted alkylene group having 1 to 8 carbon atoms.

[0044]

Among the compounds of the general formula (TS-II), those wherein each of R<sup>11</sup>, R<sup>12</sup>, R<sup>13</sup> and R<sup>14</sup> represents an unsubstituted alkyl group having 1 to 10 carbon atoms or an alkenyl group having 2 to 10 carbon atoms are preferred. More preferably, R<sup>11</sup>, R<sup>12</sup>, R<sup>13</sup> and R<sup>14</sup> are the same and represent an unsubstituted alkyl group having 1 to 3 carbon atoms. Still more preferably, R<sup>11</sup>, R<sup>12</sup>, R<sup>13</sup> and R<sup>14</sup> simultaneously represent a methyl group. R<sup>11</sup> and R<sup>12</sup>, or R<sup>13</sup> and R<sup>14</sup>, may be bonded with each other to thereby form a 5- to 7-membered ring. X<sup>2</sup>



preferably represents any of a hydrogen atom, alkyl groups (including cycloalkyl and bicycloalkyl groups), alkenyl groups (including cycloalkenyl and bicycloalkenyl groups), alkoxy groups (including a cycloalkyloxy group), acyl groups, acyloxy groups, a hydroxyl group and oxy radical group. Among them,  $X^2$  more preferably represents an unsubstituted alkoxy group having 1 to 20 carbon atoms (including a cycloalkyloxy group) or an oxy radical group.  $X^3$  preferably represents an atom group required for forming a nitrogen-containing 6-membered ring, in which the number of the nitrogen atom is preferably 1 to 3, and more preferably 1. The cyclic ring that  $X^3$  forms together with the nitrogen atom preferably have a substituent, and the position of the substituent is preferably para-position with respect to the nitrogen atom to which  $X^2$  of the general formula (TS-II) attaches.

[0045]

In a preferred form of the general formula (TS-II),  $R^{11}$ ,  $R^{12}$ ,  $R^{13}$  and  $R^{14}$  simultaneously represent a methyl group.  $X^2$  represents an unsubstituted alkoxy group having 1 to 20 carbon atoms (including a cycloalkyloxy group) or an oxyl radical group.  $X^3$  represents an atom group required for forming a nitrogen-containing 6-membered ring.

[0046]

Among the compounds represented by the general formula (TS-I) or (TS-II), those represented by formula (TS-I) are preferable, and those represented by formula (TS-I- $\alpha$ ) are more preferable.

5 [0047]

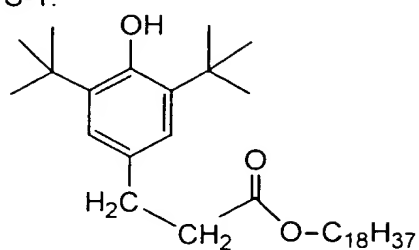
The molecular weight of the compounds represented by general formula (TS-I) or (TS-II) is preferably 150 or more, more preferable 200 or more, and much more preferably 250 or more. Still much preferably the  
10 molecular weight is 300 or more. The molecular weight is preferably 1000 or less, more preferably 800 or less.

[0048]

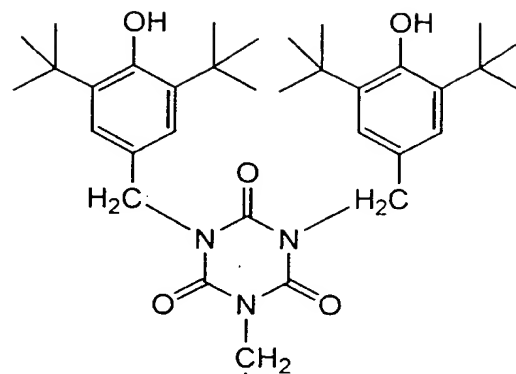
Specific examples of the preventive agent represented by general formula (TS-I) or (TS-II) are  
15 set for the below, however the present invention is not limited to those.

[0049]  
[Chem 5]

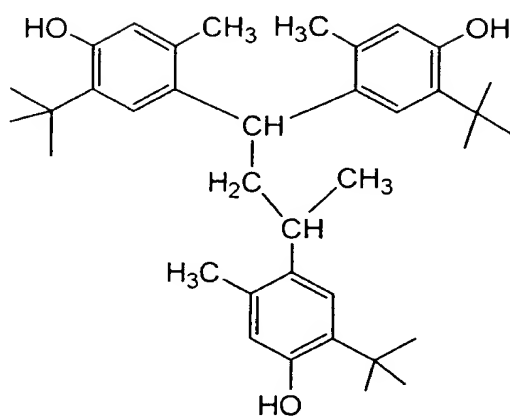
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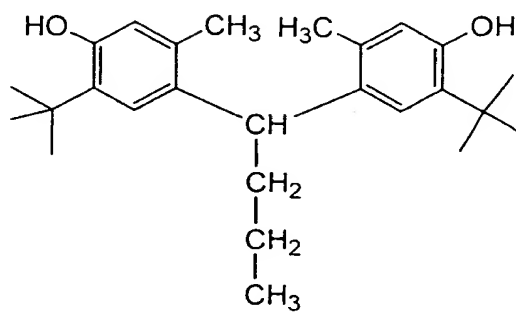
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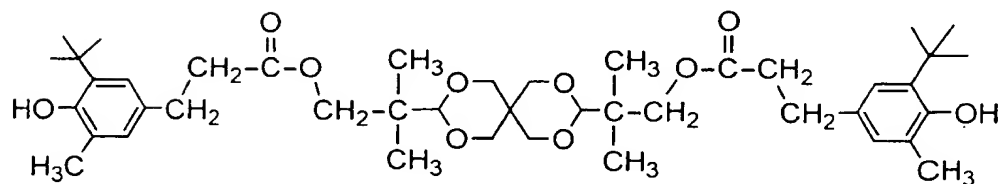
S-3.



S-4.

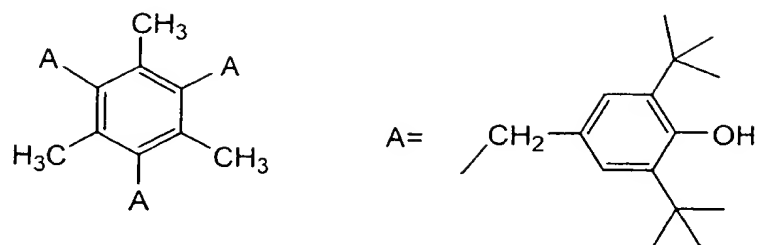


S-5.

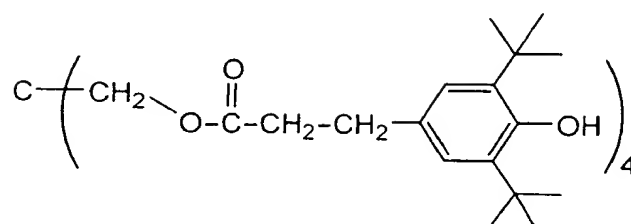


[0050]  
[Chem 6]

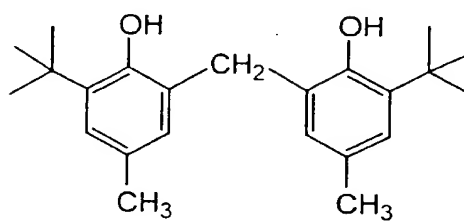
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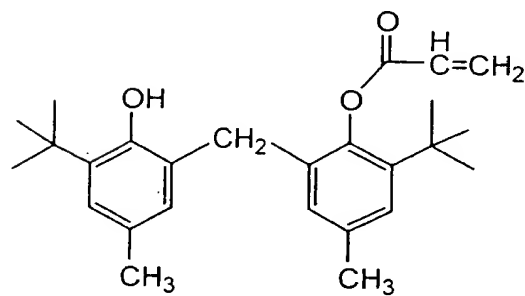
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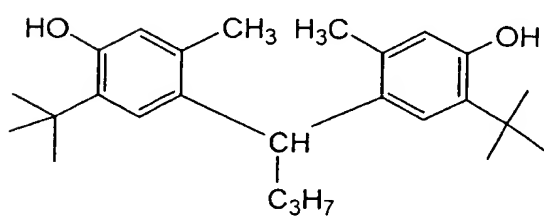
S-8.



S-9.

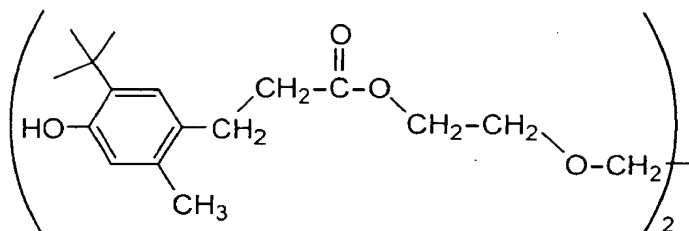


S-10.

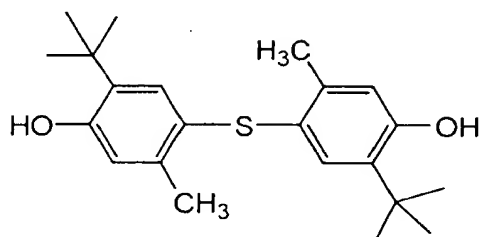


[0051]  
[Chem 7]

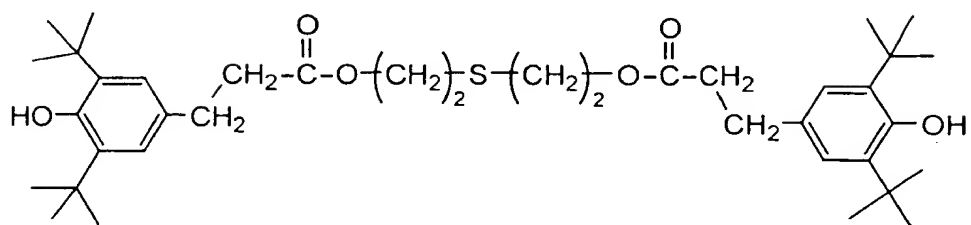
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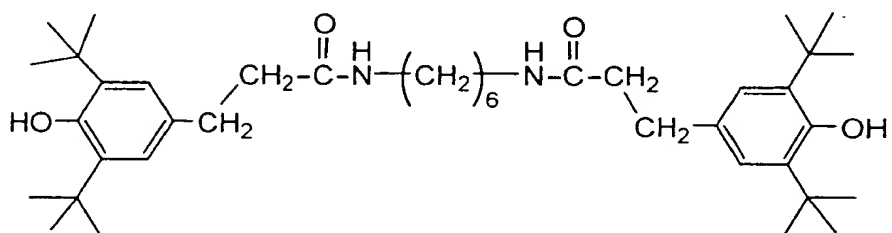
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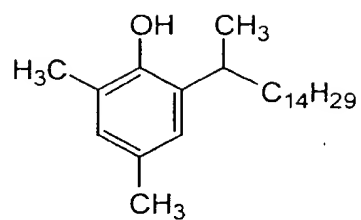


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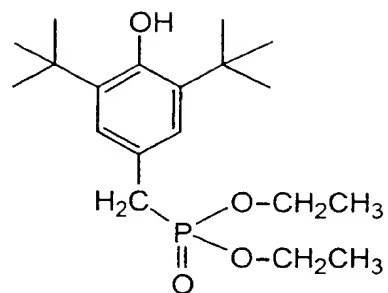


[0052]  
[Chem 8]

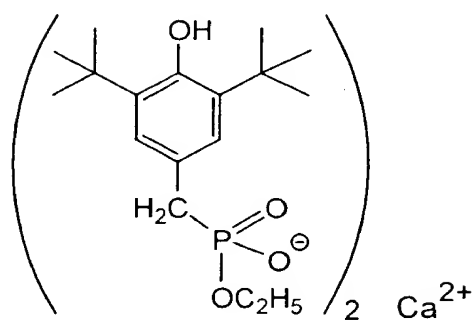
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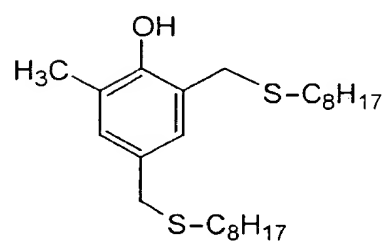
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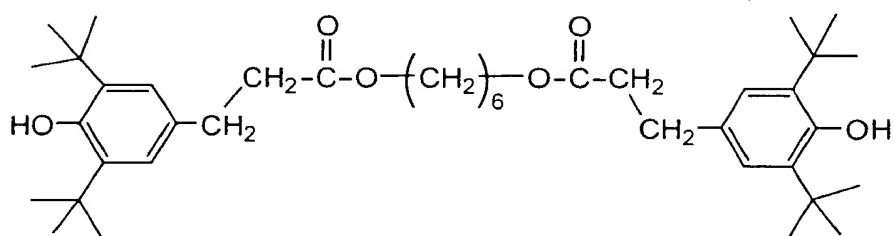
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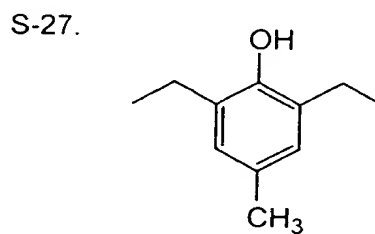
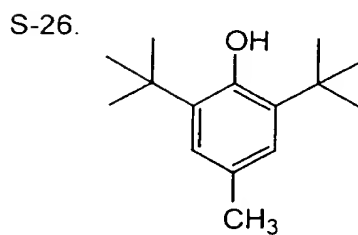
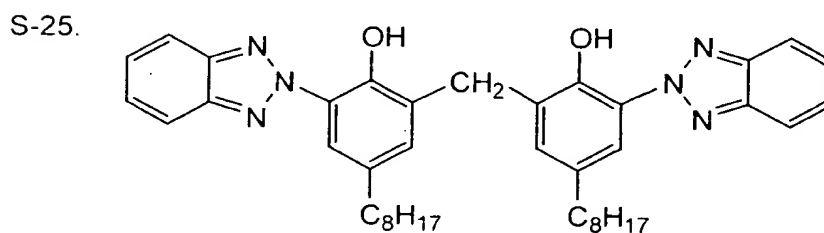
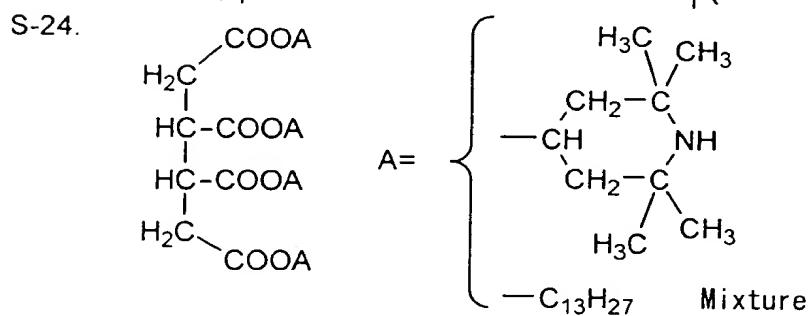
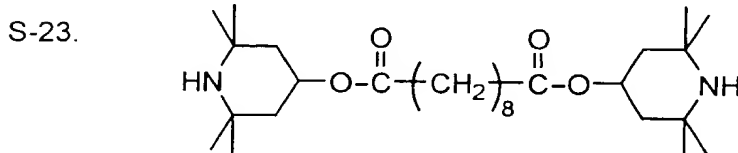
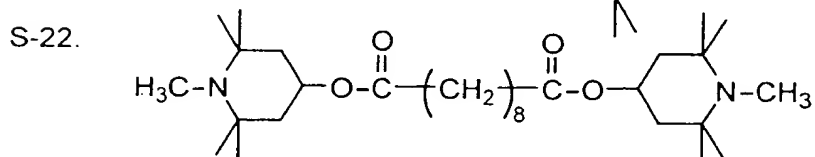
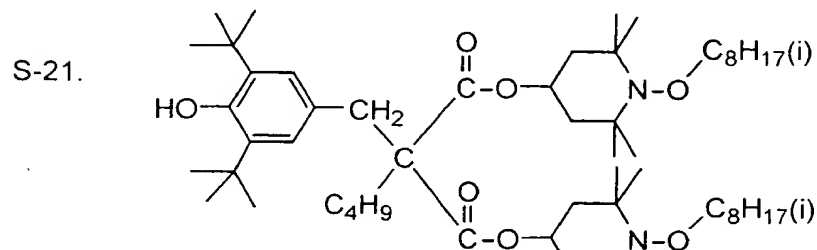
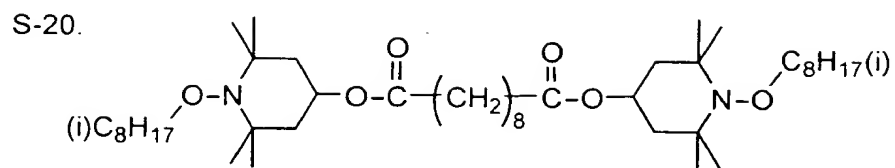
S-18.



S-19.



[0053]  
[Chem 9]



[0054]

Compounds of the general formulae (TS-I) and (TS-II) are known, and relevant patents are cited in, for example, Research Disclosure Nos. 17643 (IV, items I to J), 15162, 18716 (page 650, left column), 36544 (page 527), 307105 (page 872) and 15162.

[0055]

These compounds are sold as industrial products on the market and hence can be easily procured. With respect to those which are commercially available, detailed description is given in "The index of ANTIOXIDANTS and ANTIOZONANTS" edited by Michael and Irene Ash and published by Gower.

[0056]

The addition amount of compounds represented by the general formulae (TS-I) and (TS-II) according to the present invention is in the range of 0.0005 to 5.0% by weight, preferably 0.001 to 3.0% by weight, and more preferably 0.002 to 1.0% by weight. Herein, the addition amount refers to the total usage in plastic material.

[0057]

The substance capable of adsorbing substances having adverse effects on photographic properties according to the present invention will be described in detail below.

The aforementioned gases are known as substances



having adverse effects on photographic properties. As  
a result of investigations, the inventors have found  
that carbon black, alumina, titanium oxide and high-  
silica zeolite (produced by Union Showa K.K., trade  
5 name: deodorant Abscents 3000) can preferably be  
employed as adsorbents of such gases. The inventors  
have conducted further investigations, and consequently  
it has become apparent that specified carbon blacks  
which are defined by an equilibrium adsorption amount  
10 of acetaldehyde gas are preferred in the adsorption of  
a variety of such gases. Specifically, the  
acetaldehyde gas equilibrium adsorption amount of  
carbon black is preferably 2 mg/g or more, more  
preferably 3 mg/g or more, and most preferably 6 mg/g  
15 or more.

[0058]

In the use of carbon or the like, it is preferred  
that the adsorption amount be large. Accordingly, it  
is preferred that the adsorbent have a small particle  
20 diameter and be porous.

[0059]

The acetaldehyde gas equilibrium adsorption amount  
mentioned in the present invention is measured in the  
following manner.

25 [0060]

2.5 to 3.5 g of carbon black is weighed and  
charged in a glass tube (20 mm in inside diameter and

20 mm in length). In a 25°C atmosphere, an air containing acetaldehyde gas in a concentration of 100 ppm (hereinafter referred to as "mixed gas") is passed through the glass tube charged with carbon black at a gas flow rate of 0.417 normal liter/min (the normal liter refers to a volume in terms of 1 atm and 0°C). The acetaldehyde gas concentration of the mixed gas having passed through the glass tube charged with carbon black is measured by means of an acetaldehyde gas detector tube (No. 92, manufactured by Gastec Corporation) until the acetaldehyde gas concentration comes to agree with the acetaldehyde gas concentration (100 ppm) of the mixed gas before being passed through the glass tube. The amount of acetaldehyde gas having been adsorbed up to the time at which the acetaldehyde gas concentrations agree with each other is referred to as "acetaldehyde gas equilibrium adsorption amount".

[0061]

As examples of preferred commercially available carbon blacks for use in the present invention, there can be mentioned furnace carbon blacks #950 and #2600 produced by Mitsubishi Chemical Corporation.

[0062]

The aforementioned thermoplastic resin material member for use in the present invention preferably contains carbon black exhibiting an acetaldehyde gas equilibrium adsorption amount of 2 mg/g or more, in

dispersed form, in an amount of 0.05 to 15% by weight. Herein, the terminology "contain" refers to the total amount after the supplemental addition to the plastic material.

5 [0063]

In the present invention, the supplemental addition of the compound of the general formula (TS-I) or (TS-II) and/or the substance capable of adsorbing substances having adverse effects on photographic  
10 properties can be performed when crushed resin is pelletized by means of an extruder, when the thus pelletized resin alone or in combination with another resin is molded, and when crushed resin per se is mixed with another molding resin and molded, and the timing  
15 of supplemental addition is not particularly limited.

[0064]

The molding can be performed by injection molding and also by vacuum forming, blow molding or extrusion, and the molding method is not particularly limited.  
20 Further, extrusion can be performed by various ways which are also not particularly limited.

[0065]

In the performing of injection molding, the known injection molding method can be employed. The  
25 production of thermoplastic resin compositions for use in the injection molding can be performed by various methods, including the compound method, the powder

method, the master batch method and the liquid method.  
In particular, from the viewpoint of cost, prevention  
of contamination during operations and homogeneous  
dispersion of carbon black, it is preferred to employ  
5 the compound method or the master batch method.

[0066]

The thermoplastic resin material member may  
contain various additives, such as a chelating  
substance, a coupling agent, a dripproof substance and  
10 a surfactant, as described in JP-A's-6-67356 and  
8-118394.

[0067]

Although the substances capable of adsorbing  
substances having adverse effects on photographic  
15 properties, such as carbon black, for use in the  
present invention include those capable of imparting  
lightshielding properties as pigments, carbon black not  
having any specific capability of adsorbing substances  
having adverse effects on photographic properties, or  
20 pigments such as silica and titanium oxide may further  
be added in the event that enhanced lightshielding  
properties must be exhibited.

[0068]

The thermoplastic resin material members for use  
25 in the present invention are not limited to those  
accommodated together with a lightsensitive material in  
a container, such as a spool and a core, and include

the container wherein the lightsensitive material is accommodated per se. Also, members constituted of materials (e.g., a metal) other than the thermoplastic resin materials can be jointly accommodated in the photographic lightsensitive material packaging unit of the present invention.

[0069]

As the thermoplastic resin for use in the present invention, there can be mentioned known resins, such as polyethylene resins, ABS resin, polyvinyl chloride resin, acrylic resin, polycarbonate resin, polyphenylene oxide modified resin, polysulfone resin, polyether sulfone resin and polyallylate resin. Of these resins, polystyrene resins are preferred from the viewpoint of cost and thermal stability. Especially, a polystyrene resin (medium-impact polystyrene resin) obtained by mixing a rubber-containing polystyrene resin (HIPS: high impact resisting polystyrene) with common polystyrene resin (GS: general-purpose polystyrene) is preferred.

Furthermore, if necessary, a resin for property modification other than the thermoplastic reclaimed resins can be added in the present invention.

[0070]

There is no specific limitation to the composition of tabular silver halide emulsion used in the invention, but silver iodobromide or silver chloriodobromide

tabular grain emulsions are preferably used.

[0071]

In tabular silver halide grains (hereinafter also referred to as tabular grains) an aspect ratio means a ratio of diameter to a thickness of silver halide. That is, the aspect ratio is a value of diameter divided by a thickness of each silver halide grain. The diameter herein means a diameter of a circle having the same area as the projected area of a grain as obtained when observing silver halide grains through a microscope or an electron microscope..

[0072]

The color photographic lightsensitive material for use in the present invention has a support and, superimposed thereon, a red-sensitive silver halide emulsion layer, a green-sensitive silver halide emulsion layer and a blue-sensitive silver halide emulsion layer. It is preferred that each color-sensitive silver halide emulsion be in the form of a plurality of silver halide emulsion layers differing from each other in photographic speed. 60% or more of the total projected area of silver halide grains contained in at least one of these emulsion layers is occupied by tabular silver halide grains having an aspect ratio of 8.0 or more. The aspect ratio is more preferably 10 or more, and most preferably 12 or more. The upper limit of the aspect ratio is preferably 100.

When the aspect ratio is smaller than the above, the photographic speed would be unfavorably low. On the other hand, when the aspect ratio is larger than the above, an intrinsic desensitization by dye would unfavorably cause lowering of photographic speed and deteriorations of pressure resistance and storage stability.

[0073]

The method of taking a transmission electron micrograph by the replica technique and measuring the equivalent circular diameter and thickness of each individual grain can be mentioned as an example of aspect ratio determining method. In the mentioned method, the thickness is calculated from the length of replica shadow.

[0074]

The equivalent circle diameter of tabular grains for use in the present invention is preferably in the range of 0.3 to 5.0  $\mu\text{m}$ , more preferably 1.0 to 4.0  $\mu\text{m}$ . The equivalent circle diameter preferably has such a monodispersity that the variation coefficient of distribution of grain size expressed by the equivalent circle diameter (quotient of dispersion (standard deviation) divided by average grain size) is 20% or less, more preferably 18% or less.

[0075]

The thickness of tabular grains for use in the

present invention is preferably less than about 0.8  $\mu\text{m}$ .  
It is more preferably in the range of 0.05 to 0.6  $\mu\text{m}$ ,  
most preferably 0.1 to 0.5  $\mu\text{m}$ . The thickness of  
tabular grains preferably has such a monodispersity  
that the variation coefficient of grain thickness  
distribution is 20% or less.

[0076]

The configuration of tabular grains of the present  
invention is generally hexagonal. The terminology  
"hexagonal configuration" means that the shape of the  
principal plane of tabular grains is hexagonal, the  
neighboring side ratio (maximum side length/minimum  
side length) thereof being 2 or less. The neighboring  
side ratio is preferably 1.6 or less, more preferably  
1.2 or less. That the lower limit thereof is 1.0 is  
needless to mention. In the grains of high aspect  
ratio, especially, triangular tabular grains are  
increased in the tabular grains. The triangular  
tabular grains are produced when the Ostwald ripening  
has excessively been advanced. From the viewpoint of  
obtaining substantially hexagonal tabular grains, it is  
preferred that the period of this ripening be minimized.  
For this purpose, it is requisite to endeavor to raise  
the tabular grain ratio by nucleation. It is preferred  
that one or both of an aqueous silver ion solution and  
an aqueous bromide ion solution contain gelatin for the  
purpose of raising the probability of occurrence of



hexagonal tabular grains at the time of adding silver ions and bromide ions to a reaction mixture according to the double jet technique, as described in JP-A-63-11928 by Saito.

5 [0077]

The hexagonal tabular grains for use in the present invention are formed through the steps of nucleation, Ostwald ripening and growth. Although all of these steps are important for suppressing the spread  
10 of grain size distribution, especial attention should be paid so as to prevent the spread of size distribution at the first nucleation step because the spread of size distribution brought about in a previous step cannot be narrowed by an ensuing step. What is  
15 important in the nucleation step is the relationship between the temperature of reaction mixture and the period of nucleation comprising adding silver ions and bromide ions to a reaction mixture according to the double jet technique and producing precipitates.  
20 JP-A-63-92942 by Saito describes that it is preferred that the temperature of the reaction mixture at the time of nucleation be in the range of from 20 to 45°C for realizing a monodispersity enhancement. Further, JP-A-2-222940 by Zola et al describes that the suitable  
25 temperature at nucleation is 60°C or below.

[0078]

Gelatin may be further added during the grain

formation in order to obtain monodisperse tabular grains of high aspect ratio. The added gelatin preferably consists of a chemically modified gelatin as described in JP-A-10-148897 and JP-A-11-143002 (gelatin in which at least two -COOH groups have newly been introduced at a chemical modification of -NH<sub>2</sub> group contained in the gelatin). Although this chemically modified gelatin is a gelatin characterized in that at least two carboxyl groups have newly been introduced at a chemical modification of amino group contained in the gelatin, it is preferred that gelatin trimellitate be used as the same. Also, gelatin succinate is preferably used. The chemically modified gelatin is preferably added prior to the growth step, more preferably immediately after the nucleation. The addition amount thereof is preferably at least 60%, more preferably at least 80%, and most preferably at least 90%, based on the total weight of dispersion medium used in grain formation.

[0079]

The tabular grain emulsion is preferably constituted of silver iodobromide or silver chloriodobromide. Although silver chloride may be contained, the silver chloride content is preferably 8 mol% or less, more preferably 3 mol% or less, or 0 mol%. The silver iodide content is preferably 20 mol% or less since the variation coefficient of the

grain size distribution of the tabular grain emulsion is preferably 30% or less. The lowering of the variation coefficient of the distribution of equivalent circular diameter of the tabular grain emulsion can be facilitated by lowering the silver iodide content. The variation coefficient of the grain size distribution of the tabular grain emulsion is more preferably 20% or less, and the silver iodide content is more preferably 10 mol% or less.

10 [0080]

It is preferred that the tabular grain emulsion have some intragranular structure with respect to the silver iodide distribution. The silver iodide distribution may have a double structure, a treble structure, a quadruple structure or a structure of higher order.

[0081]

It is preferred that In the present invention, the tabular grains preferably have dislocation lines. The dislocation lines of the tabular grains can be observed by the direct method using a transmission electron microscope at low temperatures as described in, for example, J. F. Hamilton, Phot. Sci. Eng., 11, 57 (1967) and T. Shiozawa, J. Soc. Phot. Sci. Japan, 3, 5, 213 (1972). Illustratively, silver halide grains are harvested from the emulsion with the care that the grains are not pressurized with such a force that

dislocation lines occur on the grains, are put on a mesh for electron microscope observation and, while cooling the specimen so as to prevent damaging (printout, etc.) by electron beams, are observed by the transmission method. The greater the thickness of the above grains, the more difficult the transmission of electron beams. Therefore, the use of an electron microscope of high voltage type (at least 200 kV on the grains of 0.25  $\mu\text{m}$  in thickness) is preferred for ensuring clearer observation. The thus obtained photograph of grains enables determining the position and number of dislocation lines in each grain viewed in the direction perpendicular to the principal planes.

[0082]

The number of dislocation lines of the tabular grains according to the present invention is preferably at least 10 per grain on the average and more preferably at least 20 per grain on the average. When dislocation lines are densely present or when dislocation lines are observed in the state of crossing each other, it happens that the number of dislocation lines per grain cannot accurately be counted. However, in this instance as well, rough counting on the order of, for example, 10, 20 or 30 dislocation lines can be effected, so that a clear distinction can be made from the presence of only a few dislocation lines. The average number of dislocation lines per grain is

determined by counting the number of dislocation lines of each of at least 100 grains and calculating a number average thereof. There are instances when hundreds of dislocation lines are observed.

5                   [0083]

Dislocation lines can be introduced in, for example, the vicinity of the periphery of tabular grains. In this instance, the dislocation is nearly perpendicular to the periphery, and each dislocation  
10 line extends from a position corresponding to  $x\%$  of the distance from the center of tabular grains to the side (periphery) to the periphery. The value of  $x$  preferably ranges from 10 to less than 100, more preferably from 30 to less than 99, and most preferably  
15 from 50 to less than 98. In this instance, the figure created by binding the positions from which the dislocation lines start is nearly similar to the configuration of the grain. The created figure may be one which is not a complete similar figure but  
20 deviated. The dislocation lines of this type are not observed around the center of the grain. The dislocation lines are crystallographically oriented approximately in the (211) direction. However, the dislocation lines often meander and may also cross each  
25 other.

[0084]

Dislocation lines may be positioned either nearly

uniformly over the entire zone of the periphery of the tabular grains or local points of the periphery. That is, referring to, for example, hexagonal tabular silver halide grains, dislocation lines may be localized  
5 either only in the vicinity of six apexes or only in the vicinity of one of the apexes. Contrarily, dislocation lines can be localized only in the sides excluding the vicinity of six apexes.

[0085]

10 Furthermore, dislocation lines may be formed over regions including the centers of two mutually parallel principal planes of tabular grains. In the case where dislocation lines are formed over the entire regions of the principal planes, the dislocation lines may  
15 crystallographically be oriented approximately in the (211) direction when viewed in the direction perpendicular to the principal planes, and the formation of the dislocation lines may be effected either in the (110) direction or randomly. Further,  
20 the length of each dislocation line may be random, and the dislocation lines may be observed as short lines on the principal planes or as long lines extending to the side (periphery). The dislocation lines may be  
25 straight or often meander. In many instances, the dislocation lines cross each other.

[0086]

The position of dislocation lines may be localized

on the periphery, principal planes or local points as mentioned above, or the formation of dislocation lines may be effected on a combination thereof. That is, dislocation lines may be concurrently present on both  
5 the periphery and the principal planes.

[0087]

The introduction of dislocation lines in the tabular grains can be accomplished by disposing a specified phase of high silver iodide content within  
10 the grains. In the dislocation line introduction, the phase of high silver iodide content may be provided with discontinuous regions of high silver iodide content. Practically, the phase of high silver iodide content within the grains can be obtained by first  
15 preparing base grains, providing them with a phase of high silver iodide content and covering the outside thereof with a phase of silver iodide content lower than that of the phase of high silver iodide content. The silver iodide content of the base tabular grains is  
20 lower than that of the phase of high silver iodide content, and is preferably 0 to 20 mol%, more preferably 0 to 15 mol% of the silver halide in the base.

[0088]

25 The terminology "phase of high silver iodide content within the grains" refers to a silver halide solid solution containing silver iodide. The silver

halide of this solid solution is preferably silver iodide, silver iodobromide or silver chloriodobromide, more preferably silver iodide or silver iodobromide (the silver iodide content is in the range of 10 to 40 mol% based on the silver halides contained in the phase of high silver iodide content). For selectively causing the phase of high silver iodide content within the grains (hereinafter referred to as "internal high silver iodide phase") to be present on any place of the sides, corners and faces of the base grains, it is desirable to control forming conditions for the base grains, forming conditions for the internal high silver iodide phase and forming conditions for the phase covering the outside thereof.

With respect to the forming conditions for the base grains, the pAg (logarithm of inverse number of silver ion concentration), the presence or absence, type and amount of silver halide solvent and the temperature are important factors. Regulating the pAg at base grain growth to 8.5 or less, preferably 8 or less, enables selectively causing the internal high silver iodide phase to be present near the apex or on the face of the base grains in the subsequent step of forming the internal high silver iodide phase. On the other hand, regulating the pAg at base grain growth to at least 8.5, preferably at least 9, enables causing the internal high silver iodide phase to be present on the side of



the base grains in the subsequent step of forming the internal high silver iodide phase. The threshold value of the  $pAg$  is changed upward or downward depending on the temperature and the presence or absence, type and amount of silver halide solvent. When, for example, a thiocyanate is used as the silver halide solvent, the threshold value of the  $pAg$  is deviated toward a higher value. What is most important as the  $pAg$  at growth is the  $pAg$  at the termination of growth of base grains.

On the other hand, even when the  $pAg$  at growth does not satisfy the above value, the selected position of the internal high silver iodide phase can be controlled by carrying out, after the growth of base grains, the regulation to the above  $pAg$  and a ripening. During the period, ammonia, an amine compound, a thiourea derivative or a thiocyanate salt is effective as the silver halide solvent. For the formation of the internal high silver iodide phase, use can be made of the so-called conversion methods. These conversion methods include one in which, during grain formation, halide ions whose salts formed with silver ions exhibit a solubility lower than that of the salts formed with the halide ions that are forming the grains or the vicinity of the surface of the grains occurring at the time of grain formation, are added. In the present invention, it is preferred that the amount of added low-solubility halide ions be at least some value

(relating to halogen composition) relative to the surface area of grains occurring at the time of the addition.

[0089]

5           For example, it is preferred that, during grain formation, KI be added in an amount not smaller than some amount relative to the surface area of silver halide grains occurring at the time of the grain formation. Specifically, it is preferred  
10       that an iodide salt be added in an amount of at least  $8.2 \times 10^{-5} \text{ mol/m}^2$ .

          Preferred process for forming the internal high silver iodide phase comprises adding an aqueous solution of a silver salt simultaneously with the  
15       addition of an aqueous solution of halide salts containing an iodide salt.

[0090]

          For example, an aqueous solution of  $\text{AgNO}_3$  is added simultaneously with the addition of an aqueous solution  
20       of KI by the double jet. The addition initiating times and addition completing times of the aqueous solution of KI and the aqueous solution of  $\text{AgNO}_3$  may be differed from each other, that is, the one may be earlier or later than the other. The addition molar ratio of an  
25       aqueous solution of  $\text{AgNO}_3$  to an aqueous solution of KI is preferably at least 0.1, more preferably at least 0.5, and most preferably at least 1. The total

addition molar amount of an aqueous solution of  $\text{AgNO}_3$  relative to halide ions within the system and added iodide ions may fall in a silver excess region. It is preferred that the pAg exhibited when the aqueous  
5 solution of halide containing such iodide ions and the aqueous solution of silver salt are added by the double jet be decreased in accordance with the passage of double jet addition time. The pAg prior to the addition initiation is preferably in the range of 6.5  
10 to 13, more preferably 7.0 to 11. The pAg at the time of addition completion is most preferably in the range of 6.5 to 10.0.

[0091]

In the performing of the above process, it is  
15 preferred that the solubility in the mixture system be as low as possible. Accordingly, the temperature of the mixture system exhibited at the time of formation of the high silver iodide phase is preferably in the range of 30 to 80°C, more preferably 30 to 70°C.

20 [0092]

Furthermore, the formation of the internal high silver iodide phase can preferably be performed by adding fine grains of silver iodide, fine grains of silver iodobromide, fine grains of silver chloriodide  
25 or fine grains of silver chloriodobromide. It is especially preferred that the formation be effected by adding fine grains of silver iodide. Although these

fine grains generally have a size of 0.01 to 0.1  $\mu\text{m}$ ,  
use can also be made of fine grains with a size of not  
greater than 0.01  $\mu\text{m}$ , or 0.1  $\mu\text{m}$  or more. With respect  
to the process for preparing these fine grains of  
5 silver halide, reference can be made to descriptions  
of JP-A's-1-183417, 2-44335, 1-183644, 1-183645,  
2-43534 and 2-43535. The internal high silver iodide  
phase can be provided by adding these fine grains of  
silver halide and conducting a ripening. When the fine  
10 grains are dissolved by ripening, use can be made of  
the aforementioned silver halide solvent. It is not  
needed that all these added fine grains be immediately  
dissolved and disappear. It is satisfactory if, when  
the final grains have been completed, they are  
15 dissolved and disappear.

[0093]

The position of the internal high silver iodide  
phase, as measured from the center of, for example, a  
hexagon resulting from grain projection, is preferably  
20 present in the range of 5 to less than 100 mol%, more  
preferably 20 to less than 95 mol%, and most preferably  
50 to less than 90 mol%, based on the amount of silver  
of the whole grain. The amount of silver halide  
forming this internal high silver iodide phase, in  
25 terms of the amount of silver, is 50 mol% or less,  
preferably 20 mol% or less, based on the amount of  
silver of the whole grain. With respect to the above

high silver iodide phase, there are provided recipe values of the production of silver halide emulsion, not values obtained by measuring the halogen composition of final grains according to various analytical methods. The internal high silver iodide phase is often caused to completely disappear in final grains by, for example, recrystallization during the shell covering step, and all the above silver amounts relate to recipe values thereof.

10 [0094]

Therefore, although the observation of dislocation lines can be easily performed in the final grains by the above method, the internal silver iodide phase introduced for the introduction of dislocation lines often cannot be confirmed as a clear phase because the boundary silver iodide composition is continuously changed. The halogen composition at each grain part can be determined by a combination of X-ray diffractometry, the EPMA method (also known as the XMA method, in which silver halide grains are scanned by electron beams to thereby detect the silver halide composition), the ESCA method (also known as the XPS method, in which X rays are irradiated and photoelectrons emitted from grain surface are separated into spectra), etc.

25

[0095]

The outside phase which covers the internal high

silver iodide phase has a silver iodide content lower than that of the internal high silver iodide phase.

The silver iodide content of the covering outside phase is preferably in the range of 0 to 30 mol%,

5 more preferably 0 to 20 mol%, and most preferably 0 to 10 mol%, based on the silver halide contained in the covering outside phase.

[0096]

Although the temperature and pAg employed at  
10 the formation of the outside phase which covers the internal high silver iodide phase are arbitrary, the temperature preferably ranges from 30 to 80°C, most preferably from 35 to 70°C, and the pAg preferably ranges from 6.5 to 11.5. The use of the aforementioned  
15 silver halide solvent is occasionally preferred, and the most preferred silver halide solvent is a thiocyanate salt.

[0097]

Another method of introducing dislocation lines  
20 in the tabular grains comprises using an iodide ion-releasing agent as described in JP-A-6-11782, which can preferably be employed.

Also, dislocation lines can be introduced by appropriately combining this method of introducing  
25 dislocation lines with the aforementioned method of introducing dislocation lines.

[0098]

The terminology "twin plane spacing of silver halide grains" used herein means the distance between two twin planes with respect to the grains having two twin planes within each tabular grain, and means the largest of the twin plane distances with respect to the grains having three or more twin planes.

[0099]

The twin plane can be observed through a transmission electron microscope. Specifically, a support is coated with an emulsion comprising tabular grains to thereby prepare a sample in which the tabular grains are arranged approximately in parallel to the support. The sample is cut with a diamond knife to thereby prepare a 0.1  $\mu\text{m}$  thick section. The twin planes of the tabular grains can be detected by observing the section through a transmission electron microscope. When electron beams pass through the twin planes, a phase shift occurs in the electron waves. Thus, the presence of the twin planes can be recognized.

[0100]

For obtaining an estimate of the twin plane thickness of tabular grains, although reference can be made to the method described by J. F. Hamilton, L. F. Brady et al. in J. Appl. Phys. 35, 414-421 (1964), the above specified method is easier than the same.

[0101]

With respect to the silver halide grains for use

in the present invention, especially the tabular silver halide grains for use in the present invention, it is preferred that the twin plane spacing thereof be 0.020  $\mu\text{m}$  or less. The twin plane spacing is more preferably in the range of 0.007 to 0.017  $\mu\text{m}$ , and most preferably 0.007 to 0.015  $\mu\text{m}$ . When the twin plane spacing exceeds 0.02  $\mu\text{m}$ , the photographic speed would unfavorably be low.

[0102]

The variation coefficient of the intergranular iodine distribution of silver halide grains for use in the present invention is preferably 20% or less, more preferably 15% or less, and much more preferably 10% or less. When the variation coefficient of the iodine content distribution of each silver halide is greater than 20%, unfavorably, a high contrast is not realized and a sensitivity lowering is intense when a pressure is applied.

[0103]

Any known processes such as the process of adding fine grains as described, for example, in JP-A-1-183417 and the process of using an iodide ion-releasing agent as described in JP-A-2-68538 can be employed either individually or in combination for the production of silver halide grains whose intergranular iodine distribution is narrow for use in the present invention.

[0104]



The silver halide grains for use in the present invention preferably have a variation coefficient of intergranular iodine distribution of 20% or less. The process described in JP-A-3-213845 can be used as the most suitable process for converting the intergranular iodine distribution to a monodispersion. That is, a monodisperse intergranular iodine distribution can be accomplished by a process in which fine silver halide grains containing silver iodide in an amount of at least 95 mol% are formed by mixing together an aqueous solution of a water soluble silver salt and an aqueous solution of a water soluble halide (containing at least 95 mol% of iodide ions) by means of a mixer provided outside a reactor vessel for crystal growth and, immediately after the formation, fed in the reactor vessel. The terminology "reactor vessel" used herein means the vessel in which the nucleation and/or crystal growth of tabular silver halide grains is carried out.

[0105]

With respect to the above process of mixer preparation followed by adding procedure and the preparatory means for use therein, the following three techniques can be employed as described in JP-A-3-213845:

[0106]

(i) immediately after formation of fine grains in a mixer, the fine grains are transferred into a reactor

vessel;

[0107]

(ii) powerful and effective agitation is carried out in the mixer; and

5 [0108]

(iii) an aqueous solution of protective colloid is injected into the mixer.

[0109]

The protective colloid used in technique (iii)  
10 above may be separately injected in the mixer, or may be incorporated in the aqueous solution of silver halide or the aqueous solution of silver nitrate before the injection in the mixer. The concentration of protective colloid is at least 1% by weight,  
15 preferably in the range of 2 to 5% by weight. Examples of polymeric compounds exhibiting a protective colloid function to the silver halide grains for use in the present invention include polyacrylamide polymers, amino polymers, polymers having thioether groups,  
20 polyvinyl alcohol, acrylic polymers, hydroxyquinoline having polymers, cellulose, starch, acetal, polyvinylpyrrolidone and ternary polymers. Low-molecular-weight gelatin can preferably be used as the above polymeric compound. The molecular weight of  
25 low-molecular-weight gelatin is preferably 30,000 or less, more preferably 10,000 or less.

[0110]

The grain formation temperature in the preparation of fine silver halide grains is preferably 35°C or below, more preferably 25°C or below. The temperature of the reactor vessel in which fine silver halide grains are incorporated is at least 50°C, preferably at least 60°C, and more preferably at least 70°C.

[0111]

The grain size of fine-size silver halide for use in the present invention can be determined by placing grains on a mesh and making a direct observation through a transmission electron microscope. The size of fine grains of the present invention is 0.3  $\mu\text{m}$  or less, preferably 0.1  $\mu\text{m}$  or less, and more preferably 0.01  $\mu\text{m}$  or less. This fine silver halide may be added simultaneously with the addition of other halide ions and silver ions, or may be separately added. The fine silver halide grains are mixed in an amount of 0.005 to 20 mol%, preferably 0.01 to 10 mol%, based on the total silver halide.

[0112]

The silver iodide content of each individual grain can be measured by analyzing the composition of each individual grain by means of an X-ray microanalyzer. The terminology "variation coefficient of intergranular iodine distribution" means a value defined by the formula:

$$\text{variation coefficient} = (\text{standard deviation}/\text{av.})$$

silver iodide content)  $\times 100$

wherein the standard deviation, specifically the standard deviation of silver iodide content, and the average silver iodide content are obtained by measuring the silver iodide contents of at least 100, preferably at least 200, and more preferably at least 300 emulsion grains. The measuring of the silver iodide content of each individual grain is described in, for example, EP No. 147,868. There are cases in which a correlation exists between the silver iodide content  $Y_i$  (mol%) of each individual grain and the equivalent spherical diameter  $X_i$  ( $\mu\text{m}$ ) of each individual grain and cases in which no such correlation exists. It is preferred that no correlation exist therebetween. The structure associated with the silver halide composition of grains of the present invention can be identified by, for example, a combination of X-ray diffractometry, the EPMA method (also known as the XMA method, in which silver halide grains are scanned by electron beams to thereby detect the silver halide composition) and the ESCA method (also known as the XPS method, in which X rays are irradiated and photoelectrons emitted from grain surface are separated into spectra). In the measuring of silver iodide content in the present invention, the terminology "grain surface" refers to the region whose depth from surface is about  $50\text{\AA}$ , and the terminology "grain internal part" refers to the

region other than the above surface. The halogen composition of such a grain surface can generally be measured by the ESCA method.

[0113]

5           The emulsions for use in the silver halide  
lightsensitive material of the present invention are  
preferably subjected to selenium sensitization.  
Selenium compounds disclosed in hitherto published  
patents can be used as the selenium sensitizer in  
10   the present invention. In the use of unstable  
selenium compound and/or nonunstable selenium  
compound, generally, it is added to an emulsion  
and the emulsion is agitated at high temperature,  
preferably 40°C or above, for a given period of time.  
15   Compounds described in, for example, Jpn. Pat. Appln.  
KOKOKU Publication No. (hereinafter referred to as  
JP-B-) 44-15748, JP-B-43-13489, JP-A's-4-25832  
and 4-109240 are preferably used as the unstable  
selenium compound.

20           Selenium sensitization may effectively be  
performed in the presence of a silver halide solvent.

[0114]

Examples of the silver halide solvents which can  
be employed in the present invention include (a)  
25   organic thioethers described in U.S.P. Nos. 3,271,157,  
3,531,289, and 3,574,628, and JP-A's-54-1019  
and 54-158917, (b) thiourea derivatives described in,

for example, JP-A's-53-82408, 55-77737 and 55-2982, (c)  
silver halide solvents having a thiocarbonyl group  
interposed between an oxygen or sulfur atom and  
a nitrogen atom, described in JP-A-53-144319,  
5 (d) imidazoles described in JP-A-54-100717, (e)  
sulfites and (f) thiocyanates.

[0115]

Thiocyanates and tetramethylthiourea can be  
mentioned as especially preferred silver halide  
10 solvents. The amount of added solvent, although varied  
depending on the type thereof, is, for example,  
preferably in the range of  $1 \times 10^{-4}$  to  $1 \times 10^{-2}$  mol  
per mol of silver halide.

[0116]

15 The emulsion for use in the present invention is  
preferably subjected to gold sensitization in  
combination with the selenium sensitization. The  
oxidation number of gold of the gold sensitizer used in  
the gold sensitization may be either +1 or +3, and gold  
20 compounds customarily used as gold sensitizers can be  
employed. Representative examples thereof include  
chloroauric acid salts, potassium chloroaurate,  
auric trichloride, potassium auric thiocyanate,  
potassium iodoaurate, tetracyanoauric acid, ammonium  
25 aurothiocyanate, pyridyltrichlorogold, gold sulfide and  
gold selenide. The addition amount of gold sensitizer,  
although varied depending on various conditions, is

preferably between  $1 \times 10^{-7}$  mol and  $5 \times 10^{-5}$  mol per mol of silver halide as a yardstick.

[0117]

5 With respect to the emulsion for use in the present invention, it is desired to perform the chemical sensitization in combination with sulfur sensitization.

10 The sulfur sensitization is generally performed by adding a sulfur sensitizer and agitating the emulsion at high temperature, preferably 40°C or above, for a given period of time.

[0118]

15 In the above sulfur sensitization, those known as sulfur sensitizers can be used. For example, use can be made of thiosulfates, allylthiocarbamidothiourea, allyl isothiocyanate, cystine, p-toluenethiosulfonates and rhodanine. Use can also be made of other sulfur sensitizers described in, for example, U.S.P. Nos. 1,574,944, 2,410,689, 2,278,947, 20 2,728,668, 3,501,313, and 3,656,955, and DE No. 1,422,869, JP-B-56-24937 and JP-A-55-45016. The addition amount of sulfur sensitizer is satisfactory if it is sufficient to effectively increase the sensitivity of the emulsion. This amount, 25 although varied to a large extent under various conditions such as the pH, temperature and size of silver halide grains, is preferably in the range

of  $1 \times 10^{-7}$  to  $5 \times 10^{-5}$  mol per mol of silver halide.

[0119]

The silver halide emulsion for use in the  
lightsensitive material of the present invention can be  
5 subjected to a reduction sensitization during the grain  
formation, or after the grain formation but before  
the chemical sensitization, during the chemical  
sensitization or after the chemical sensitization.

The reduction sensitization can be performed by  
10 a method selected from among the method in which  
a reduction sensitizer is added to the silver halide  
emulsion, the method commonly known as silver ripening  
in which growth or ripening is carried out in an  
environment of pAg as low as 1 to 7 and the method  
15 commonly known as high-pH ripening in which growth or  
ripening is carried out in an environment of pH as high  
as 8 to 11. At least two of these methods can be used  
in combination.

The above method in which a reduction sensitizer  
20 is added is preferred from the viewpoint that the level  
of reduction sensitization can be finely regulated.

[0120]

Examples of known reduction sensitizers include  
stannous salts, ascorbic acid and derivatives thereof,  
25 amines and polyamines, hydrazine derivatives,  
formamidinesulfinic acid, silane compounds and  
borane compounds. In the reduction sensitization



according to the present invention, appropriate one  
may be selected from among these known reduction  
sensitizers and used or at least two may be selected  
and used in combination. Preferred reduction  
5 sensitizers are stannous chloride, thiourea dioxide,  
dimethylaminoborane, ascorbic acid and derivatives  
thereof. Although the addition amount of reduction  
sensitizer must be selected because it depends on the  
emulsion manufacturing conditions, it is preferred that  
10 the addition amount range from  $10^{-7}$  to  $10^{-3}$  mol per mol  
of silver halide.

[0121]

Each reduction sensitizer is dissolved in water or  
any of organic solvents such as alcohols, glycols,  
15 ketones, esters and amides and added during the grain  
growth. Although the reduction sensitizer may be put  
in a reaction vessel in advance, it is preferred that  
the addition be effected at an appropriate time during  
the grain growth. It is also suitable to add in  
20 advance the reduction sensitizer to an aqueous solution  
of a water-soluble silver salt or a water-soluble  
alkali halide and to precipitate silver halide grains  
with the use of the resultant aqueous solution.  
Alternatively, the reduction sensitizer solution  
25 may preferably be either divided and added a plurality  
of times in accordance with the grain growth or  
continuously added over a prolonged period of time.

[0122]

An oxidizer capable of oxidizing silver is preferably used during the process of producing the emulsion for use in the light-sensitive material of the present invention. The silver oxidizer is a compound having an effect of acting on metallic silver to thereby convert the same to silver ion. A particularly effective compound is one that converts very fine silver grains, formed as a by-product in the step of forming silver halide grains and the step of chemical sensitization, into silver ions. Each silver ion produced may form a silver salt sparingly soluble in water, such as a silver halide, silver sulfide or silver selenide, or may form a silver salt easily soluble in water, such as silver nitrate. The silver oxidizer may be either an inorganic or an organic substance. Examples of suitable inorganic oxidizers include ozone, hydrogen peroxide and its adducts (e.g.,  $\text{NaBO}_2 \cdot \text{H}_2\text{O}_2 \cdot 3\text{H}_2\text{O}$ ,  $2\text{NaCO}_3 \cdot 3\text{H}_2\text{O}_2$ ,  $\text{Na}_4\text{P}_2\text{O}_7 \cdot 2\text{H}_2\text{O}_2$  and  $2\text{Na}_2\text{SO}_4 \cdot \text{H}_2\text{O}_2 \cdot 2\text{H}_2\text{O}$ ), peroxy acid salts (e.g.,  $\text{K}_2\text{S}_2\text{O}_8$ ,  $\text{K}_2\text{C}_2\text{O}_6$  and  $\text{K}_2\text{P}_2\text{O}_8$ ), peroxy complex compounds (e.g.,  $\text{K}_2[\text{Ti}(\text{O}_2)\text{C}_2\text{O}_4] \cdot 3\text{H}_2\text{O}$ ,  $4\text{K}_2\text{SO}_4 \cdot \text{Ti}(\text{O}_2)\text{OH} \cdot \text{SO}_4 \cdot 2\text{H}_2\text{O}$  and  $\text{Na}_3[\text{VO}(\text{O}_2)(\text{C}_2\text{H}_4)_2] \cdot 6\text{H}_2\text{O}$ ), permanganates (e.g.,  $\text{KMnO}_4$ ), chromates (e.g.,  $\text{K}_2\text{Cr}_2\text{O}_7$ ) and other oxyacid salts, halogen elements such as iodine and bromine, perhalogenates (e.g., potassium periodate), salts of high-valence metals (e.g., potassium

hexacyanoferrate (II)) and thiosulfonates.

[0123]

Examples of suitable organic oxidizers include quinones such as p-quinone, organic peroxides such as  
5 peracetic acid and perbenzoic acid and active halogen-releasing compounds (e.g., N-bromosuccinimide, chloramine T and chloramine B).

[0124]

Oxidizers preferred in the present invention are  
10 inorganic oxidizers selected from among ozone, hydrogen peroxide and its adducts, halogen elements and thiosulfonates and organic oxidizers selected from among quinones.

[0125]

15 The use of the silver oxidizer in combination with the above reduction sensitization is preferred. This combined use can be effected by performing the reduction sensitization after the use of the oxidizer or vice versa or by simultaneously performing the  
20 reduction sensitization and the use of the oxidizer. These methods can be performed during the step of grain formation or the step of chemical sensitization.

[0126]

The emulsion for use in the present invention can  
25 effectively exhibit its advantages by subjecting it to a spectral sensitization with a methine dye or the like. Examples of employed dyes include cyanine dyes,

merocyanine dyes, composite cyanine dyes, composite  
merocyanine dyes, holopolar cyanine dyes, hemicyanine  
dyes, styryl dyes and hemioxonol dyes. Particularly  
useful dyes are those belonging to cyanine dyes,  
5 merocyanine dyes and composite merocyanine dyes. These  
dyes may contain any of nuclei commonly used in cyanine  
dyes as basic heterocyclic nuclei. Examples of such  
nuclei include a pyrroline nucleus, an oxazoline  
nucleus, a thiazoline nucleus, a pyrrole nucleus, an  
10 oxazole nucleus, a thiazole nucleus, a selenazole  
nucleus, an imidazole nucleus, a tetrazole nucleus and  
a pyridine nucleus; nuclei comprising these nuclei  
fused with alicyclic hydrocarbon rings; and nuclei  
comprising these nuclei fused with aromatic hydrocarbon  
15 rings, such as an indolenine nucleus, a benzindolenine  
nucleus, an indole nucleus, a benzoxazole nucleus, a  
naphthoxazole nucleus, a benzothiazole nucleus, a  
naphthothiazole nucleus, a benzoselenazole nucleus, a  
benzimidazole nucleus and a quinoline nucleus. These  
20 nuclei may have substituents on carbon atoms thereof.

[0127]

The merocyanine dye or composite merocyanine  
dye may have a 5- or 6-membered heterocyclic nucleus  
such as a pyrazolin-5-one nucleus, a thiohydantoin  
25 nucleus, a 2-thioxazolidine-2,4-dione nucleus,  
a thiazolidine-2,4-dione nucleus, a rhodanine nucleus  
or a thiobarbituric acid nucleus as a nucleus having

a ketomethylene structure.

[0128]

These spectral sensitizing dyes may be used either individually or in combination. The spectral sensitizing dyes are often used in combination for the purpose of attaining supersensitization. Representative examples thereof are described in U.S.P. Nos. 2,688,545, 2,977,229, 3,397,060, 3,522,052, 3,527,641, 3,617,293, 3,628,964, 3,666,480, 3,672,898, 3,679,428, 3,703,377, 3,769,301, 3,814,609, 3,837,862, and 4,026,707, GB Nos. 1,344,281 and 1,507,803, JP-B's-43-4936 and 53-12375, and JP-A's-52-110618 and 52-109925.

[0129]

The emulsion used in the present invention may contain with a dye which itself exerts no spectral sensitizing effect or a substance which absorbs substantially none of visible radiation and exhibits supersensitization, together with the above spectral sensitizing dye.

[0130]

The addition timing of the spectral sensitizing dye to the emulsion may be performed at any stage of the process for preparing the emulsion which is known as being useful. Although the doping is most usually conducted at a stage between the completion of the chemical sensitization and the coating, the spectral

sensitizing dye can be added simultaneously with the chemical sensitizer to thereby simultaneously effect the spectral sensitization and the chemical sensitization as described in U.S.P. Nos. 3,628,969 and 4,225,666. Alternatively, the spectral sensitization can be conducted prior to the chemical sensitization and, also, the spectral sensitizing dye can be added prior to the completion of silver halide grain precipitation to thereby initiate the spectral sensitization as described in JP-A-58-113928. Further, the above sensitizing dye can be divided prior to addition, that is, part of the sensitizing dye can be added prior to the chemical sensitization with the rest of the sensitizing dye added after the chemical sensitization as taught in U.S.P. No. 4,225,666. Still further, the spectral sensitizing dye can be added at any stage during the formation of silver halide grains according to the method disclosed in U.S.P. No. 4,183,756 and other methods.

[0131]

Although the sensitizing dye can be used in an amount of  $4 \times 10^{-6}$  to  $8 \times 10^{-3}$  mol per mol of silver halide contained in the addition layer, the use thereof in an amount of about  $5 \times 10^{-5}$  to  $2 \times 10^{-3}$  mol per mol of silver halide is more effective when the size of silver halide grains is in the preferred range of 0.2 to 1.2  $\mu\text{m}$ .

[0132]

The fogging during aging of the silver halide emulsion for use in the present invention can be improved by adding and dissolving a previously prepared silver iodobromide emulsion at the time of chemical sensitization. Although the timing of the addition is arbitrary as long as it is performed during chemical sensitization, it is preferred that the silver iodobromide emulsion be first added and dissolved and, thereafter, a sensitizing dye and a chemical sensitizer be added in this order. The employed silver iodobromide emulsion has an iodine content lower than the surface iodine content of host grains, which is preferably a pure silver bromide emulsion. This silver iodobromide emulsion, although the size thereof is not limited as long as it is completely dissolvable, preferably has an equivalent spherical diameter of 0.1  $\mu\text{m}$  or less, more preferably 0.05  $\mu\text{m}$  or less. Although the addition amount of silver iodobromide emulsion depends on employed host grains, basically, it preferably ranges from 0.005 to 5 mol%, more preferably from 0.1 to 1 mol%, based on the mole of silver.

[0133]

The emulsion for use in the present invention is preferably doped with hexacyanoiron (II) complex or hexacyanoruthenium complex (hereinafter also referred

to simply as "metal complex"). The addition amount of the metal complex is preferably in the range of  $10^{-7}$  to  $10^{-3}$  mol per mol of silver halide, more preferably  $1.0 \times 10^{-5}$  to  $5 \times 10^{-4}$  mol per mol of silver halide.

5 [0134]

The addition and incorporation of the metal complex for use in the present invention may be performed at any stage through the process of preparing silver halide grains which consists of nucleation,  
10 growth, physical ripening and chemical sensitization. Also, the addition and incorporation may be performed in some divisions. However, it is preferred that at least 50% of the total content of metal complex contained in each silver halide grain be contained in a  
15 layer underlying the outermost surface of silver halide grain where 1/2 or less of the silver content from the surface is present. The layer containing the metal complex may be overlaid with a layer which does not contain any metal complex.

20 [0135]

The incorporation of the above metal complex is preferably accomplished by dissolving the metal complex in water or a suitable solvent and directly adding the solution to the reaction mixture during the formation  
25 of silver halide grains, or by adding the metal complex solution to the aqueous solution of halide, aqueous solution of silver salt or other solution for



preparation of silver halide grains and thereafter  
conducting grain formation. Alternatively, the  
incorporation of metal complex is also preferably  
accomplished by adding silver halide grains in which  
5 the metal complex has been introduced in advance,  
dissolving them and depositing them on other silver  
halide grains.

[0136]

With respect to the hydrogen ion concentration of  
10 the reaction mixture to which the metal complex is  
added, the pH value is preferably in the range of 1  
to 10, more preferably 3 to 7.

In the lightsensitive material of the present  
invention, it is only required that at least one  
15 red-sensitive, at least one green-sensitive and at  
least one blue-sensitive lightsensitive layer be  
formed on a support. A typical example thereof is  
a silver halide photographic lightsensitive material  
having, on its support, at least one lightsensitive  
20 layer constituted by a plurality of silver halide  
emulsion layers which have substantially the same color  
sensitivity but have different speeds. Each of the  
lightsensitive layers is a unit lightsensitive layer  
which is sensitive to any of blue light, green light  
25 and red light. In a multilayered silver halide color  
photographic lightsensitive material, these unit  
lightsensitive layers are generally arranged in the

order of red-, green- and blue-sensitive layers from a support side. However, according to the intended use, this arrangement order may be reversed, or an arrangement order can be employed in which a different  
5 lightsensitive layer is interposed between the layers of the same color sensitivity. Nonlightsensitive layers can be formed between the silver halide lightsensitive layers and as the uppermost layer and the lowermost layer. These may contain, e.g., couplers,  
10 DIR compounds and color mixing inhibitors described later. As a plurality of silver halide emulsion layers constituting each unit lightsensitive layer, a two-layered structure of high- and low-speed emulsion layers is preferably arranged so that the  
15 sensitivity is sequentially decreased toward a support as described in DE No. 1,121,470 or GB No. 923,045. Also, as described in JP-A's-57-112751, 62-200350, 62-206541 and 62-206543, layers can be arranged so that a low-speed emulsion layer is formed on a side apart from  
20 a support while a high-speed emulsion layer is formed on a side close to the support.

[0137]

Specifically, layers can be arranged, from the farthest side from a support, in the order of  
25 low-speed blue-sensitive layer (BL)/high-speed blue-sensitive layer (BH)/high-speed green-sensitive layer (GH)/low-speed green-sensitive layer (GL)/high-

speed red-sensitive layer (RH)/low-speed red-sensitive layer (RL), the order of BH/BL/GL/GH/RH/RL or the order of BH/BL/GH/GL/RL/RH.

[0138]

5           In addition, as described in JP-B-55-34932, layers can be arranged, from the farthest side from a support, in the order of blue-sensitive layer/GH/RH/GL/RL. Furthermore, as described in JP-A's-56-25738 and 62-63936, layers can be arranged, from the farthest  
10 side from a support, in the order of blue-sensitive layer/GL/RL/GH/RH.

[0139]

As described in JP-B-49-15495, three layers can be arranged so that a silver halide emulsion layer having  
15 the highest sensitivity is arranged as an upper layer, a silver halide emulsion layer having sensitivity lower than that of the upper layer is arranged as an interlayer, and a silver halide emulsion layer having sensitivity lower than that of the interlayer is  
20 arranged as a lower layer; i.e., three layers having different sensitivities can be arranged so that the sensitivity is sequentially decreased toward the support. Even when a layer structure is constituted by three layers having different sensitivities as  
25 mentioned above, these layers can be arranged in the order of medium-speed emulsion layer/high-speed emulsion layer/low-speed emulsion layer from the

farthest side from a support in a layer sensitive to one color as described in JP-A-59-202464.

[0140]

In addition, the order of high-speed emulsion layer/low-speed emulsion layer/medium-speed emulsion layer or low-speed emulsion layer/medium-speed emulsion layer/high-speed emulsion layer can be adopted.

Furthermore, the arrangement can be changed as described above even when four or more layers are formed.

[0141]

It is preferable to utilize an interlayer inhibitory effect as means for improving a color reproduction. It is preferred that the weight-average sensitivity wavelength ( $\lambda_{-R}$ ) of spectral sensitivity distribution of interlayer effect exerted on the red-sensitive silver halide emulsion layer (in the event of a plurality of layers, the plurality of layers as a whole) from other layers at 500 nm to 600 nm satisfy the relationship:  $500 \text{ nm} < \lambda_{-R} \leq 560 \text{ nm}$ ; the weight-average sensitivity wavelength ( $\lambda_G$ ) of spectral sensitivity distribution of the green-sensitive silver halide emulsion layer (in the event of a plurality of layers, the plurality of layers as a whole) satisfy the relationship:  $520 \text{ nm} < \lambda_G \leq 580 \text{ nm}$ ; and  $\lambda_G - \lambda_{-R} \geq 5 \text{ nm}$ .

[0142]

The sensitizing dye and solid disperse dye for use

in the above utilization of interlayer inhibitory effect can be those described in JP-A-11-305396. Further, the above specified sensitivity and weight-average sensitivity wavelength of spectral sensitivity distribution of interlayer effect exerted on the red-sensitive silver halide emulsion layer from other layers can be determined by the method described in JP-A-11-305396.

[0143]

10           The silver halide photographic light-sensitive material for use in the present invention preferably contains at least one compound which reacts with developing agent oxidation products obtained by development to thereby release a development inhibitor or a precursor thereof. For example, use can be made of DIR (development inhibitor releasing) couplers, DIR-hydroquinone and couplers capable of releasing DIR-hydroquinone or a precursor thereof.

[0144]

20           Although, for example, the size and configuration of silver halide grains for use in the layer capable of exerting an interlayer effect on the red-sensitive layer are not particularly limited, it is preferred to use so-called tabular grains of high aspect ratio, a monodisperse emulsion having uniform grain size, or silver iodobromide grains having an iodine layer structure. Further, for extending an exposure latitude,

it is preferred to mix a plurality of emulsions whose grain sizes are different from each other.

[0145]

5        Although the donor layer capable of exerting the interlayer effect on the red-sensitive layer may be provided by coating on any position on the support, it is preferred that the donor layer be provided by coating at a position which is closer to the support than the blue-sensitive layer and which is more remote from the support than the red-sensitive layer. It is further preferred that the donor layer be positioned closer to the support than the yellow filter layer.

[0146]

15        It is more preferred that the donor layer capable of exerting the interlayer effect on the red-sensitive layer be provided at a position which is closer to the support than the green-sensitive layer and which is more remote from the support than the red-sensitive layer. The donor layer is most preferably arranged at a position neighboring to a side of the green-sensitive layer close to the support. The terminology "neighboring" used herein means that an inter layer or any other layer is not interposed therebetween.

20        There may be a plurality of layers capable of exerting the interlayer effect on the red-sensitive layer. These layers may be positioned so that they neighbor to each other or are apart from each other.

[0147]

The emulsion for use in the lightsensitive material of the present invention may be any of the surface latent image type in which latent images are  
5 mainly formed in the surface, the internal latent image type in which latent images are formed in the internal portion of grains and the type in which latent images exist in both the surface and the internal portion of grains. However, it is requisite that the emulsion  
10 be a negative type. The emulsion of the internal latent image type may specifically be, for example, a core/shell internal-latent-image type emulsion described in JP-A-63-264740, whose productive process is described in JP-A-59-133542. The thickness of  
15 the shell of this emulsion, although varied depending on development processing, etc., is preferably in the range of 3 to 40 nm, more preferably 5 to 20 nm.

[0148]

The silver halide emulsion is generally subjected  
20 to physical ripening, chemical sensitization and spectral sensitization before use. Additives employed in these steps are described in RD Nos. 17643, 18716 and 307105. Positions where the description is made are listed in the following table.

25 [0149]

With respect to the lightsensitive material of the present invention, at least two emulsions which

are different from each other in at least one of the characteristics, specifically the grain size, grain size distribution, halogen composition, grain configuration and sensitivity of lightsensitive silver halide emulsion, can be mixed together and used in one layer.

[0150]

It is preferred that silver halide grains having a grain surface fogged as described in U.S.P. No. 4,082,553, silver halide grains having a grain internal portion fogged as described in U.S.P. No. 4,626,498 and JP-A-59-214852 and colloidal silver be used in lightsensitive silver halide emulsion layers and/or substantially nonlightsensitive hydrophilic colloid layers. The expression "silver halide grains having a grain surface or grain internal portion fogged" refers to silver halide grains which can be developed uniformly (nonimagewise) irrespective of the nonexposed or exposed zone of lightsensitive material. The process for producing the grains is described in U.S.P. No. 4,626,498 and JP-A-59-214852. The silver halides constituting internal nuclei of core/shell silver halide grains having a grain internal portion fogged may have different halogen composition. Any of silver chloride, silver chlorobromide, silver iodobromide and silver chloriodobromide can be used as the silver halide having a grain surface or grain



internal portion fogged. The average grain size of these fogged silver halide grains is preferably in the range of 0.01 to 0.75  $\mu\text{m}$ , more preferably 0.05 to 0.6  $\mu\text{m}$ . With respect to grain configuration, regular grains may be used and although a polydisperse emulsion can be used, monodispersity (at least 95% of the weight or number of silver halide grains have grain sizes falling within  $\pm 40\%$  of the average grain size) is preferred.

10 [0151]

In the present invention, it is preferred to use nonlightsensitive fine grain silver halide. The expression "nonlightsensitive fine grain silver halide" refers to silver halide fine grains which are not sensitive at the time of imagewise exposure for obtaining dye image and which are substantially not developed at the time of development processing thereof. Those not fogged in advance are preferred. The fine grain silver halide has a silver bromide content of 0 to 100 mol%, and, if necessary, may contain silver chloride and/or silver iodide. Preferably, silver iodide is contained in an amount of 0.5 to 10 mol%. The average grain size (average of equivalent circular diameter of projected area) of fine grain silver halide is preferably in the range of 0.01 to 0.5  $\mu\text{m}$ , more preferably 0.02 to 0.2  $\mu\text{m}$ .

[0152]

The fine grain silver halide can be prepared by the same process as used in the preparation of common lightsensitive silver halide. It is not needed to optically sensitize the surface of silver halide grains. Further, a spectral sensitization thereof is also not needed. However, it is preferred to add known stabilizers such as triazole, azaindene, benzothiazolium and mercapto compounds and zinc compounds thereto prior to the addition thereof to a coating liquid. Colloidal silver can be contained in the fine grain silver halide containing layers.

[0153]

The above various additives can be used in the lightsensitive material according to the present technology, to which other various additives can also be added in conformity with the object.

The additives are described in detail in Research Disclosure Item 17643 (December 1978), Item 18716 (November 1979) and Item 308119 (December 1989). A summary of the locations where they are described will be listed in the following table.

[0154]

	Types of additives	RD17643	RD18716	RD308119
1	Chemical sensitizers	page 23	page 648 right column	page 996
2	Sensitivity-		page 648	

		increasing agents		right column	
5	3	Spectral sensitizers, - 24 super-sensitizers	pages 23	page 648, right column to page 649, right column	page 996, right column to page 998, right column
10	4	Brighteners	page 24		page 998 right column
15	5	Antifoggants, stabilizers	pages 24 - 25	page 649 right column	page 998, right column to page 1000, right column
20	6	Light absorbents, filter dyes, ultraviolet absorbents	pages 25 - 26	page 649, right column to page 650, left column	page 1003, left column to page 1003, right column
25	7	Stain preventing agents	page 25, right column	page 650, left to right columns	page 1002, right column
	8	Dye image stabilizers	page 25		page 1002, right column
30	9	Film hardeners	page 26	page 651, left column	page 1004, right column page 1005, left column
35	10	Binders	page 26	page 651, left column	page 1003, right column to page 1004, right column
40	11	Plasticizers, lubricants	page 27	page 650, right column	page 1006, left to right columns
45	12	Coating aids, surfactants	pages 26 - 27	page 650, right column	page 1005, left column to page 1006, left column
	13	Antistatic	page 27	page 650,	page 1006,

agents

right column right column  
to page 1007,  
left column

5 14 Matting agents page 1008,  
left column  
to page 1009,  
left column.

[0155]

10 With respect to the photographic lightsensitive  
material of the present invention and the emulsion  
suitable for use in the photographic lightsensitive  
material and also with respect to layer arrangement and  
related techniques, silver halide emulsions, dye  
15 forming couplers, DIR couplers and other functional  
couplers, various additives and development processing  
which can be used in the photographic lightsensitive  
material, reference can be made to EP 0565096A1  
(published on October 13, 1993) and patents cited  
20 therein. Individual particulars and the locations  
where they are described will be listed below.

[0156]

1. Layer arrangement: page 61 lines 23 to 35, page 61  
line 41 to page 62 line 14,
- 25 2. Interlayers: page 61 lines 36 to 40,
3. Interlayer effect imparting layers: page 62  
lines 15 to 18,
4. Silver halide halogen compositions: page 62  
lines 21 to 25,
- 30 5. Silver halide grain crystal habits: page 62

- lines 26 to 30,
6. Silver halide grain sizes: page 62 lines 31 to 34,
7. Emulsion production methods: page 62 lines 35 to 40,
8. Silver halide grain size distributions: page 62  
5 lines 41 to 42,
9. Tabular grains: page 62 lines 43 to 46,
10. Internal structures of grains: page 62 lines 47  
to 53,
11. Latent image forming types of emulsions: page 62  
10 line 54 to page 63 to line 5,
12. Physical ripening and chemical sensitization of  
emulsion: page 63 lines 6 to 9,
13. Emulsion mixing: page 63 lines 10 to 13,
14. Fogging emulsions: page 63 lines 14 to 31,
- 15 15. Nonlightsensitive emulsions: page 63 lines 32  
to 43,
16. Silver coating amounts: page 63 lines 49 to 50,
17. Formaldehyde scavengers: page 64 lines 54 to 57,
18. Mercapto antifoggants: page 65 lines 1 to 2,
- 20 19. Fogging agent, etc.-releasing agents: page 65  
lines 3 to 7,
20. Dyes: page 65, lines 7 to 10,
21. Color coupler summary: page 65 lines 11 to 13,
22. Yellow, magenta and cyan couplers: page 65  
25 lines 14 to 25,
23. Polymer couplers: page 65 lines 26 to 28,
24. Diffusive dye forming couplers: page 65 lines 29

- to 31,
25. Colored couplers: page 65 lines 32 to 38,
26. Functional coupler summary: page 65 lines 39 to 44,
27. Bleaching accelerator-releasing couplers: page 65  
5 lines 45 to 48,
28. Development accelerator-releasing couplers: page  
65 lines 49 to 53,
29. Other DIR couplers: page 65 line 54 to page 66 to  
line 4,
- 10 30. Method of dispersing couplers: page 66 lines 5  
to 28,
31. Antiseptic and mildewproofing agents: page 66  
lines 29 to 33,
32. Types of sensitive materials: page 66 lines 34  
15 to 36,
33. Thickness of lightsensitive layer and swell speed:  
page 66 line 40 to page 67 line 1,
34. Back layers: page 67 lines 3 to 8,
35. Development processing summary: page 67 lines 9  
20 to 11,
36. Developing solution and developing agents: page 67  
lines 12 to 30,
37. Developing solution additives: page 67 lines 31  
to 44,
- 25 38. Reversal processing: page 67 lines 45 to 56,
39. Processing solution open ratio: page 67 line 57  
to page 68 line 12,

40. Development time: page 68 lines 13 to 15,  
41. Bleach-fix, bleaching and fixing: page 68 line 16  
to page 69 line 31,  
42. Automatic processor: page 69 lines 32 to 40,  
5 43. Washing, rinse and stabilization: page 69 line 41  
to page 70 line 18,  
44. Processing solution replenishment and recycling:  
page 70 lines 19 to 23,  
45. Developing agent built-in sensitive material: page  
10 70 lines 24 to 33,  
46. Development processing temperature: page 70  
lines 34 to 38, and  
47. Application to film with lens: page 70 lines 39  
to 41.

15 [0157]

Moreover, preferred use can be made of a bleaching  
solution containing 2-pyridinecarboxylic acid or  
2,6-pyridinedicarboxylic acid, a ferric salt such  
as ferric nitrate and a persulfate as described in  
20 EP No. 602,600. When this bleaching solution is used,  
it is preferred that the steps of stop and water  
washing be conducted between the steps of color  
development and bleaching. An organic acid such as  
acetic acid, succinic acid or maleic acid is preferably  
25 used as a stop solution. For pH adjustment and  
bleaching fog, it is preferred that the bleaching  
solution contains an organic acid such as acetic acid,

succinic acid, maleic acid, glutaric acid or adipic acid in an amount of 0.1 to 2 mol/liter (hereinafter liter referred to as "L").

[0158]

5           A magnetic recording layer usable in the present invention will be described below.

          This magnetic recording layer is formed by coating the surface of a support with an aqueous or organic solvent-based coating solution which is prepared by  
10       dispersing magnetic grains in a binder.

[0159]

          As the magnetic grains, it is possible to use grains of, e.g., ferromagnetic iron oxide such as  $\gamma\text{Fe}_2\text{O}_3$ , Co-deposited  $\gamma\text{Fe}_2\text{O}_3$ , Co-deposited magnetite,  
15       Co-containing magnetite, ferromagnetic chromium dioxide, a ferromagnetic metal, ferromagnetic alloy, Ba ferrite of a hexagonal system, Sr ferrite, Pb ferrite, and Ca ferrite. Co-deposited ferromagnetic iron oxide such as Co-deposited  $\gamma\text{Fe}_2\text{O}_3$  is preferable. The grain can take  
20       the shape of any of, e.g., a needle, rice grain, sphere, cube, and plate. The specific area is preferably  $20 \text{ m}^2/\text{g}$  or more, and more preferably  $30 \text{ m}^2/\text{g}$  or more as  $S_{\text{BET}}$ .

[0160]

25           The saturation magnetization ( $\sigma_s$ ) of the ferromagnetic substance is preferably  $3.0 \times 10^4$  to  $3.0 \times 10^5 \text{ A/m}$ , and especially preferably  $4.0 \times 10^4$  to



2.5  $\times 10^5$  A/m. A surface treatment can be performed for the ferromagnetic grains by using silica and/or alumina or an organic material. Also, the surface of the ferromagnetic grain can be treated with a silane coupling agent or a titanium coupling agent as described in JP-A-6-161032. A ferromagnetic grain whose surface is coated with an inorganic or organic substance described in JP-A-4-259911 or JP-A-5-81652 can also be used.

10 [0161]

As a binder used together with the magnetic grains, it is possible to use a thermoplastic resin described in JP-A-4-219569, thermosetting resin, radiation-curing resin, reactive resin, acidic, alkaline, or biodegradable polymer, natural polymer (e.g., a cellulose derivative and sugar derivative), and their mixtures. The Tg of the resin is -40°C to 300°C, and its weight average molecular weight is 2,000 to 1,000,000. Examples are a vinyl-based copolymer, cellulose derivatives such as cellulosediacetate, cellulose triacetate, cellulose acetate propionate, cellulose acetate butylate, and cellulose tripropionate, acrylic resin, and polyvinylacetal resin. Gelatin is also preferable. Cellulose di(tri)acetate is particularly preferable. This binder can be hardened by the addition of an epoxy-, aziridine-, or isocyanate-based crosslinking agent. Examples of

the isocyanate-based crosslinking agent are isocyanates such as tolylenediisocyanate, 4,4'-diphenylmethanediisocyanate, hexamethylenediisocyanate, and xylylenediisocyanate, reaction products of these isocyanates and polyalcohol (e.g., a reaction product of 3 mols of tolylenediisocyanate and 1 mol of trimethylolpropane), and polyisocyanate produced by condensation of any of these isocyanates. These examples are described in JP-A-6-59357.

[0162]

As a method of dispersing the magnetic substance in the binder, as described in JP-A-6-35092, a kneader, pin type mill, and annular mill are preferably used singly or together. Dispersants described in JP-A-5-088283 and other known dispersants can be used. The thickness of the magnetic recording layer is 0.1 to 10  $\mu\text{m}$ , preferably 0.2 to 5  $\mu\text{m}$ , and more preferably 0.3 to 3  $\mu\text{m}$ . The weight ratio of the magnetic grains to the binder is preferably 0.5 : 100 to 60 : 100, and more preferably 1 : 100 to 30 : 100. The coating amount of the magnetic grains is 0.005 to 3  $\text{g}/\text{m}^2$ , preferably 0.01 to 2  $\text{g}/\text{m}^2$ , and more preferably 0.02 to 0.5  $\text{g}/\text{m}^2$ . The transmitting yellow density of the magnetic recording layer is preferably 0.01 to 0.50, more preferably 0.03 to 0.20, and especially preferably 0.04 to 0.15. The magnetic recording layer can be

formed in the whole area of, or into the shape of stripes on, the back surface of a photographic support by coating or printing. As a method of coating the magnetic recording layer, it is possible to use  
5 any of an air doctor, blade, air knife, squeegee, impregnation, reverse roll, transfer roll, gravure, kiss, cast, spray, dip, bar, and extrusion. A coating solution described in JP-A-5-341436 is preferable.

[0163]

10 The magnetic recording layer can be given a lubricating property improving function, curling adjusting function, antistatic function, adhesion preventing function, and head polishing function. Alternatively, another functional layer can be  
15 formed and these functions can be given to that layer. A polishing agent in which at least one type of grains are aspherical inorganic grains having a Mohs hardness of 5 or more is preferable. The composition of this aspherical inorganic grain is preferably an oxide such  
20 as aluminum oxide, chromium oxide, silicon dioxide, titanium dioxide, and silicon carbide, a carbide such as silicon carbide and titanium carbide, or a fine powder of diamond. The surfaces of the grains constituting these polishing agents can be treated with  
25 a silane coupling agent or titanium coupling agent. These grains can be added to the magnetic recording layer or overcoated (as, e.g., a protective layer

or lubricant layer) on the magnetic recording layer.  
A binder used together with the grains can be any of  
those described above and is preferably the same binder  
as in the magnetic recording layer. Sensitive  
5 materials having the magnetic recording layer are  
described in US5,336,589, US5,250,404, US5,229,259,  
US5,215,874, and EP466,130.

[0164]

A polyester support used in the present invention  
10 will be described below. Details of the polyester  
support and sensitive materials, processing, cartridges,  
and examples (to be described later) are described in  
Journal of Technical Disclosure No. 94-6023 (JIII; 1994,  
March 15). Polyester used in the present invention is  
15 formed by using diol and aromatic dicarboxylic acid as  
essential components. Examples of the aromatic  
dicarboxylic acid are 2,6-, 1,5-, 1,4-, and  
2,7-naphthalenedicarboxylic acids, terephthalic acid,  
isophthalic acid, and phthalic acid. Examples of the  
20 diol are diethyleneglycol, triethyleneglycol,  
cyclohexanedimethanol, bisphenol A, and bisphenol.  
Examples of the polymer are homopolymers such as  
polyethyleneterephthalate, polyethylenenaphthalate, and  
polycyclohexanedimethanolteterephthalate.  
25 Polyester containing 50 to 100 mol% of  
2,6-naphthalenedicarboxylic acid is particularly  
preferable. Polyethylene-2,6-naphthalate is especially

preferable among other polymers. The average molecular weight ranges between about 5,000 and 200,000. The  $T_g$  of the polyester of the present invention is  $50^\circ\text{C}$  or higher, preferably  $90^\circ\text{C}$  or higher.

5 [0165]

To give the polyester support a resistance to curling, the polyester support is heat-treated at a temperature of  $40^\circ\text{C}$  to less than  $T_g$ , more preferably  $T_g - 20^\circ\text{C}$  to less than  $T_g$ . The heat treatment can be  
10 performed at a fixed temperature within this range or can be performed together with cooling. The heat treatment time is 0.1 to 1500 hrs, more preferably 0.5 to 200 hrs. The heat treatment can be performed for a roll-like support or while a support is conveyed  
15 in the form of a web. The surface shape can also be improved by roughening the surface (e.g., coating the surface with conductive inorganic fine grains such as  $\text{SnO}_2$  or  $\text{Sb}_2\text{O}_5$ ). It is desirable to knurl and slightly raise the end portion, thereby preventing the cut  
20 portion of the core from being photographed. These heat treatments can be performed in any stage after support film formation, after surface treatment, after back layer coating (e.g., an antistatic agent or lubricating agent), and after undercoating.  
25 A preferable timing is after the antistatic agent is coated.

[0166]

An ultraviolet absorbent can be incorporated into this polyester. Also, to prevent light piping, dyes or pigments such as Diaresin manufactured by Mitsubishi Kasei Corp. or Kayaset manufactured by  
5 NIPPON KAYAKU CO. LTD. commercially available for polyester can be incorporated.

[0167]

In the present invention, it is preferable to perform a surface treatment in order to adhere the  
10 support and the sensitive material constituting layers. Examples of the surface treatment are surface activation treatments such as a chemical treatment, mechanical treatment, corona discharge treatment, flame  
15 treatment, ultraviolet treatment, high-frequency treatment, glow discharge treatment, active plasma treatment, laser treatment, mixed acid treatment, and ozone oxidation treatment. Among other surface  
20 treatments, the ultraviolet radiation treatment, flame treatment, corona treatment, and glow treatment are preferable.

[0168]

An undercoating layer can include a single layer or two or more layers. Examples of an undercoating layer binder are copolymers formed by using, as  
25 a starting material, a monomer selected from vinylchloride, vinylidenechloride, butadiene, methacrylic acid, acrylic acid, itaconic acid,

and maleic anhydride. Other examples are polyethyleneimine, an epoxy resin, grafted gelatin, nitrocellulose, and gelatin. Resorcin and p-chlorophenol are examples of a compound which swells a support. Examples of a gelatin hardener added to the undercoating layer are chromium salt (e.g., chromium alum), aldehydes (e.g., formaldehyde and glutaraldehyde), isocyanates, an active halogen compound (e.g., 2,4-dichloro-6-hydroxy-s-triazine), epichlorohydrin resin, and active vinylsulfone compound.  $\text{SiO}_2$ ,  $\text{TiO}_2$ , inorganic fine grains, or polymethylmethacrylate copolymer fine grains (0.01 to 10  $\mu\text{m}$ ) can also be contained as a matting agent.

[0169]

In the present invention, an antistatic agent is preferably used. Examples of this antistatic agent are carboxylic acid, carboxylate, a macromolecule containing sulfonate, cationic macromolecule, and ionic surfactant compound.

[0170]

As the antistatic agent, it is especially preferable to use fine grains of at least one crystalline metal oxide selected from  $\text{ZnO}$ ,  $\text{TiO}_2$ ,  $\text{SnO}_2$ ,  $\text{Al}_2\text{O}_3$ ,  $\text{In}_2\text{O}_3$ ,  $\text{SiO}_2$ ,  $\text{MgO}$ ,  $\text{BaO}$ ,  $\text{MoO}_3$ , and  $\text{V}_2\text{O}_5$ , and having a volume resistivity of  $10^7 \Omega \cdot \text{cm}$  or less, more preferably  $10^5 \Omega \cdot \text{cm}$  or less and a grain size of 0.001 to 1.0  $\mu\text{m}$ , fine grains of composite oxides (e.g., Sb, P,

B, In, S, Si, and C) of these metal oxides, fine grains of sol metal oxides, or fine grains of composite oxides of these sol metal oxides.

[0171]

5           The content in a sensitive material is preferably 5 to 500 mg/m<sup>2</sup>, and especially preferably 10 to 350 mg/m<sup>2</sup>. The ratio of a conductive crystalline oxide or its composite oxide to the binder is preferably 1/300 to 100/1, and more preferably 1/100 to 100/5.

10           [0172]

          A sensitive material of the present invention preferably has a slip property. Slip agent-containing layers are preferably formed on the surfaces of both a sensitive layer and back layer. A preferable slip  
15           property is 0.01 to 0.25 as a coefficient of kinetic friction. This represents a value obtained when a stainless steel sphere 5 mm in diameter is conveyed at a speed of 60 cm/min (25°C, 60%RH). In this  
20           evaluation, a value of nearly the same level is obtained when the surface of a sensitive layer is used as a sample to be measured.

[0173]

          Examples of a slip agent usable in the present invention are polyorganocyloxane, higher fatty acid  
25           amide, higher fatty acid metal salt, and ester of higher fatty acid and higher alcohol. As the polyorganocyloxane, it is possible to use, e.g.,



polydimethylcyloxane, polydiethylcyloxane,  
polystyrylmethylcyloxane, or polymethylphenylcyloxane.  
A layer to which the slip agent is added is preferably  
the outermost emulsion layer or back layer.

5 Polydimethylcyloxane or ester having a long-chain alkyl  
group is particularly preferable.

[0174]

A sensitive material of the present invention  
preferably contains a matting agent. This matting  
10 agent can be added to either the emulsion surface  
or back surface and is especially preferably added  
to the outermost emulsion layer. The matting  
agent can be either soluble or insoluble in  
processing solutions, and the use of both types  
15 of matting agents is preferable. Preferable  
examples are polymethylmethacrylate grains,  
poly(methylmethacrylate/methacrylic acid = 9/1 or 5/5  
(molar ratio)) grains, and polystyrene grains.  
The grain size is preferably 0.8 to 10  $\mu\text{m}$ , and a narrow  
20 grain size distribution is preferable. It is  
preferable that 90% or more of all grains have  
grain sizes 0.9 to 1.1 times the average grain size.  
To increase the matting property, it is preferable  
to simultaneously add fine grains with a grain size of  
25 0.8  $\mu\text{m}$  or smaller. Examples are polymethylmethacrylate  
grains (0.2  $\mu\text{m}$ ), poly(methylmethacrylate/methacrylic  
acid = 9/1 (molar ratio, 0.3  $\mu\text{m}$ ) grains,

polystyrene grains (0.25  $\mu\text{m}$ ), and colloidal silica grains (0.03  $\mu\text{m}$ ).

[0175]

5 A film cartridge used in the present invention will be described below. The principal material of the cartridge used in the present invention can be a metal or synthetic plastic.

Preferable plastic materials are polystyrene, polyethylene, polypropylene, and polyphenylether.

10 The cartridge of the present invention can also contain various antistatic agents. For this purpose, carbon black, metal oxide grains, nonion-, anion-, cation-, and betaine-based surfactants, or a polymer can be preferably used. These cartridges subjected to the

15 antistatic treatment are described in JP-A-1-312537 and JP-A-1-312538. It is particularly preferable that the resistance be  $10^{12} \Omega$  or less at 25°C and 25%RH. Commonly, plastic cartridges are manufactured by using plastic into which carbon black or a pigment is

20 incorporated in order to give a light-shielding property. The cartridge size can be a presently available 135 size. To miniaturize cameras, it is effective to decrease the diameter of a 25-mm cartridge of 135 size to 22 mm or less. The volume of

25 a cartridge case is 30  $\text{cm}^3$  or less, preferably 25  $\text{cm}^3$  or less. The weight of plastic used in the cartridge and the cartridge case is preferably 5 to 15g.

[0176]

Furthermore, a cartridge which feeds a film by rotating a spool can be used in the present invention. It is also possible to use a structure in which a film leader is housed in a cartridge main body and fed through a port of the cartridge to the outside by rotating a spool shaft in the film feed direction. These structures are disclosed in USP Nos. 4,834,306 and 5,226,613. Photographic films used in the present invention can be so-called raw films before being developed or developed photographic films. Also, raw and developed photographic films can be accommodated in the same new cartridge or in different cartridges.

[0177]

15 A color photographic light-sensitive material of the present invention is also suitably used as a negative film for an advanced photo system (to be referred to as an APS hereinafter). Examples are NEXIA A, NEXIA F, and NEXIA H (ISO 200, 100, and 400, respectively) manufactured by Fuji Photo Film Co., Ltd. (to be referred to as Fuji Film hereinafter). These films are so processed as to have an APS format and set in an exclusive cartridge. These APS cartridge films are loaded into APS cameras such as the Fuji Film EPION Series represented by the EPION 300Z. A color light sensitive film of the present invention is also suited as a film-fitted lens such as Fuji Film FUJICOLOR

UTSURUNDESU (Quick Snap) SUPER SLIM.

[0178]

A photographed film is printed through the following steps in a miniature laboratory system.

- 5 (1) Reception (an exposed cartridge film is received from a customer)
- (2) Detaching step (the film is transferred from the cartridge to an intermediate cartridge for development)
- (3) Film development
- 10 (4) Reattaching step (the developed negative film is returned to the original cartridge)
- (5) Printing (prints of three types C, H, and P and an index print are continuously automatically printed on color paper [preferably Fuji Film SUPER FA8])
- 15 (6) Collation and shipment (the cartridge and the index print are collated by an ID number and shipped together with the prints)

[0179]

As these systems, the Fuji Film MINILABO CHAMPION  
20 SUPER FA-298, FA-278, FA-258, FA-238 and Fuji Film  
DIGITALLABO SYSTEM, FRONTIER are preferable. Examples  
of a film processor for the MINILABO CHAMPION are the  
FP922AL/FP562B/FP562B, AL/FP362B/FP362BL AL and a  
recommended processing chemical is the FUJICOLOR  
25 JUST-IT CN-16L and CN-16Q. Examples of a printer  
processor are the PP3008AR/PP3008A/PP1828AR/PP1828A/  
PP1258AR/PP1258A/PP728AR/PP728A, and a recommended

processing chemical is the FUJICOLOR JUST-IT CP-47L and CP-40FAII. In the FRONTIER SYSTEM, SCANNER & IMAGE-PROCESSOR SP-1000 and LASER PRINTER & PAPER PROCESSOR LP-1000P, or LASER PRINTER LP-1000W are used. A  
5     detacher used in the detaching step and a reattacher used in the reattaching step are preferably the Fuji Film DT200 or DT100 and AT200 or AT100, respectively.

[0180]

The APS can also be enjoyed by PHOTO JOY SYSTEM  
10     whose main component is the Fuji Film Aladdin 1000 digital image scanner. For example, a developed APS cartridge film is directly loaded into the Aladdin 1000, or image information of a negative film, positive film, or print is input to the Aladdin 1000 by using the  
15     FE-550 35-mm film scanner or the PE-550 flat head scanner. Obtained digital image data can be easily processed and edited. This data can be printed out by the NC-550AL digital color printer using a photo-fixing heat-sensitive color printing system or  
20     the PICTOROGRAPHY 3000 using a laser exposure thermal development transfer system, or by existing laboratory equipment through a film recorder. The Aladdin 1000 can also output digital information directly to a floppy disk or Zip disk or to an CD-R via a CD writer.

25     [0181]

In a home, a user can enjoy photographs on a TV set simply by loading a developed APS cartridge film

into the Fuji Film Photo Player AP-1. Image information can also be continuously input to a personal computer by loading a developed APS cartridge film into the Fuji Film Photo Scanner AS-1. The Fuji Film Photo Vision FV-10 or FV-5 can be used to input a film, print, or three-dimensional object. Furthermore, image information recorded in a floppy disk, Zip disk, CD-R, or hard disk can be variously processed on a computer by using the Fuji Film Photo Factory application software. The Fuji Film NC-2 or NC-2D digital color printer using a photo-fixing heat-sensitive color printing system is suited to outputting high-quality prints from a personal computer.

[0182]

To keep developed APS cartridge films, the FUJICOLOR POCKET ALBUM AP-5 POP L, AP-1 POP L, or AP-1 POP KG, or the CARTRIDGE FILE 16 is preferable.

[0183]

[EXAMPLE]

The present invention will be described in greater detail below by way of its examples. However, the present invention is in no way limited to these examples.

[0184]

(Example 1)

A color lightsensitive material to be charged in a lens-fitted lightsensitive material packaging unit was

produced in the following manner.

Silver halide emulsions were produced in the following manner. The structures of compounds employed in the production will be listed afterward.

5 [0185]

Preparation of emulsion Em-X (comparative emulsion)

1300 milliliters (hereinafter referred to as "mL") of an aqueous solution containing 30.0 g of KBr, 23.7 g of KI, 18.0 g of ammonium nitrate and 28.5 g of gelatin was maintained at 76°C and vigorously agitated. An aqueous solution containing 59.0 g of silver nitrate and an aqueous solution containing 11.0 g of KBr were added thereto at constant rates over a period of 9 min.

15 [0186]

Subsequently, 14.8 g of ammonia was added, and the mixture was allowed to stand still for 20 min. The pH value thereof was adjusted to 6 with the use of acetic acid, and further  $1.5 \times 10^{-5}$  mol of thiourea dioxide and  $1 \times 10^{-5}$  mol of oxidizer (F-14) defined below were added. Further, 724 mL of an aqueous solution containing 119.0 g of silver nitrate was added at a constant flow rate of 9.05 mL/min over a period of 12 min, and thereafter, while maintaining the flow rate, added together with an aqueous solution containing 90.0 g of KBr by the double jet method at a constant rate over a period of 56 min. During the addition, a

constant potential of -10 mV in terms of saturated calomel electrode was maintained. Thereafter, the potential was changed to -20 mV, and the addition was continued for 12 min.

5 [0187]

Common washing was carried out, and gelatin was added so as to adjust the pH and pAg values at 40°C to 5.8 and 8.8, respectively. The thus obtained emulsion contained tabular grains having an average equivalent  
10 sphere diameter of 1.80  $\mu\text{m}$ , an average equivalent circle diameter of 2.30  $\mu\text{m}$  and an average aspect ratio of 3.5. The ratio in projected area of grains having an aspect ratio of 8 or more to all the grains was 10%. The twin plane spacing was measured in the  
15 aforementioned manner, and it was found that the twin plane spacing was 0.065  $\mu\text{m}$ .

[0188]

This emulsion was heated to 56°C, and the optimum chemical sensitization thereof was effected by the  
20 addition of sensitizing dye ExS-12, chloroauric acid, potassium thiocyanate, sodium thiosulfate and compound (F-3) defined later. After the completion of chemical sensitization, compound (F-12) was added.

[0189]

25 Preparation of emulsions Em-Y/Z (comparative emulsions)

1500 mL of an aqueous solution containing 19.5 g



of KBr, 15.0 g of KI, 18.0 g of ammonium nitrate and 30.0 g of gelatin was maintained at 76°C and vigorously agitated. An aqueous solution containing 60.0 g of silver nitrate and an aqueous solution containing  
5 23.0 g of KBr were added thereto at constant rates over a period of 8 min.

[0190]

Subsequently, 28 g of ammonia was added, and the mixture was allowed to stand still for 10 min. The pH  
10 value thereof was adjusted to 6 with the use of acetic acid, and further  $1.5 \times 10^{-5}$  mol of thiourea dioxide and  $1 \times 10^{-5}$  mol of oxidizer (F-14) defined below were added. Further, an aqueous solution containing 120.0 g of silver nitrate and an aqueous solution containing  
15 82.5 g of KBr and 5.0 g of KI were added by the double jet method at constant rates over a period of 30 min.

Common washing was carried out, and gelatin was added so as to adjust the pH and pAg values at 40°C to 5.8 and 8.8, respectively.

20 [0191]

The thus obtained emulsion contained tabular grains having an average equivalent sphere diameter of 1.40  $\mu\text{m}$ , an average equivalent circle diameter of 1.77  $\mu\text{m}$  and an average aspect ratio of 3. The ratio in  
25 projected area of grains having an aspect ratio of 8 or more to all the grains was 10%.

The twin plane spacing was measured in the

aforementioned manner, and it was found that the twin plane spacing was 0.060  $\mu\text{m}$ .

[0192]

(Preparation of emulsion Em-Y)

5           This emulsion was heated to 56°C, and the optimum chemical sensitization thereof was effected by the addition of sensitizing dyes ExS-1, ExS-2 and ExS-3, chloroauric acid, potassium thiocyanate, sodium thiosulfate and compound (F-3) defined later. After  
10 the completion of chemical sensitization, compound (F-3) was added. Thus, emulsion Em-Y was obtained.

[0193]

(Preparation of emulsion Em-Z)

15           Emulsion Em-Z was prepared in the same manner as the emulsion Em-Y, except that the chemical sensitization was carried out with the use of sensitizing dyes ExS-5, ExS-6 and ExS-7 in place of the above sensitizing dyes.

[0194]

20           Preparation of emulsion Em-1 (emulsion of the present invention)

(Preparation of seed emulsion)

25           1200 mL of an aqueous solution containing 1.0 g of a low-molecular-weight oxidized gelatin whose weight average molecular weight was 15,000 and 0.9 g of KBr was vigorously agitated while maintaining the temperature thereof at 35°C. 40 mL of an aqueous

solution containing 1.85 g of  $\text{AgNO}_3$  and 35 mL of an aqueous solution containing 1.82 g of  $\text{KBr}$  and 1.0 g of a low-molecular-weight gelatin whose weight average molecular weight was 15,000 were added by the double jet method over a period of 30 sec to thereby effect a nucleation. Immediately after the completion of addition, 5.4 g of  $\text{KBr}$  was added and heated to  $75^\circ\text{C}$ , and the mixture was ripened. After the completion of ripening, 35 g of gelatin obtained by chemically modifying an alkali-processed gelatin of 100 thousand weight average molecular weight with succinic anhydride was added. Thereafter, the pH was adjusted to 5.5. 250 mL of an aqueous solution containing 36 g of  $\text{AgNO}_3$  and 282 mL of an aqueous solution containing 21.2 g of  $\text{KBr}$  and 2.81 g of  $\text{KI}$  were added by the double jet method over a period of 25 min, while maintaining the silver potential at -5 mV. Thereafter, 650 mL of an aqueous solution containing 200 g of  $\text{AgNO}_3$  and 900 mL of an aqueous solution containing 134.1 g of  $\text{KBr}$  and 13.9 g of  $\text{KI}$  were added by the double jet method over a period of 100 min while increasing the flow rate so that the final flow rate was 1.4 times the initial flow rate. During this period, the silver potential was maintained at +5 mV against saturated calomel electrode. The thus obtained emulsion was washed, and gelatin was added so that the pH was adjusted to 5.7, the  $\text{pAg}$  to 8.8, the weight in terms of silver per kg of emulsion

to 139.0 g and the gelatin weight to 56 g. Thus, a seed emulsion was obtained.

[0195]

1200 mL of an aqueous solution containing 33 g of  
5 g of lime-processed gelatin having a calcium  
concentration of 1 ppm and 3.4 g of KBr was vigorously  
agitated while maintaining the temperature thereof at  
75°C. 89 g of the above seed emulsion was added, and  
further 0.3 of modified silicone oil (L7602, produced  
10 by Nippon Unicar Company, Limited) was added.  $\text{H}_2\text{SO}_4$   
was added to thereby adjust the pH value to 5.8. 2 mg  
of sodium benzenethiosulfonate and 2 mg of thiourea  
dioxide were added. 600 mL of an aqueous solution  
containing 51.0 g of  $\text{AgNO}_3$  and 600 mL of an aqueous  
15 solution containing 36.2 g of KBr and 3.49 g of KI were  
added by the double jet method over a period of 85 min  
while increasing the flow rate so that the final flow  
rate was 1.1 times the initial flow rate. During this  
period, the silver potential was maintained at -35 mV  
20 against saturated calomel electrode. Further, 300 mL  
of an aqueous solution containing 44.7 g of  $\text{AgNO}_3$  and  
300 mL of an aqueous solution containing 30.6 g of KBr  
and 3.06 g of KI were added by the double jet method  
over a period of 56 min while increasing the flow rate  
25 so that the final flow rate was 1.1 times the initial  
flow rate. During this period, the silver potential  
was maintained at -35 mV against saturated calomel

electrode. Subsequently, an aqueous solution of KBr and 180 mL of an aqueous solution containing 36.9 g of AgNO<sub>3</sub> were added over a period of 40 min. During this period, the silver potential was maintained at +10 mV  
5 against saturated calomel electrode. KBr was added so as to adjust the silver potential to -70 mV.

Thereafter, 1.38 g, in terms of the weight of KI, of AgI fine grain emulsion of 0.037  $\mu$ m grain size was added. Immediately after the completion of addition,  
10 100 mL of an aqueous solution containing 17.4 g of AgNO<sub>3</sub> was added over a period of 15 min. The mixture was washed with water, and gelatin was added so as to adjust the pH and pAg at 40°C to 5.8 and 8.7, respectively. This emulsion was heated to 60°C, and  
15 compound 2 and sensitizing dyes ExS-10 and ExS-13 were added. The optimum chemical sensitization thereof was effected by the addition of potassium thiocyanate, chloroauric acid, sodium thiosulfate, hexafluorophenyldiphenylphosphine selenide, compound  
20 (F-11) and compound 3. At the completion of chemical sensitization, compound (F-3) defined later was added.

[0196]

The thus obtained emulsion contained tabular grains having an average equivalent sphere diameter of  
25 1.65  $\mu$ m, an average equivalent circle diameter of 3.10  $\mu$ m, a variation coefficient of equivalent circle diameter of 20% and an average aspect ratio of 10.0.

The ratio in projected area of grains having an aspect ratio of 8 or more to all the grains was 90%. The twin plane spacing, measured in the aforementioned manner, was 0.015  $\mu\text{m}$ .

5 [0197]

The thus obtained grains were observed through a transmission electron microscope while cooling the same with liquid nitrogen. As a result, it was found that grains each having no dislocation line in a region  
10 extending from the grain center to 80% of its projected area constituted about 98% of all the grains, and that there were 10 or more dislocation lines per grain on grain peripheral portions extending from the grain extreme periphery to 20% of the projected area.

15 [0198]

Preparation of emulsions Em-2/3 (emulsions of the present invention)

1300 mL of an aqueous solution containing 1.6 g of a low-molecular-weight oxidized gelatin whose weight  
20 average molecular weight was 15,000 and 1.0 g of KBr was vigorously agitated while maintaining the temperature at 58°C and adjusting the pH to 9.

[0199]

25 An aqueous solution containing 1.3 g of  $\text{AgNO}_3$  and an aqueous solution containing 1.1 g of KBr and 0.7 g of a low-molecular-weight gelatin whose weight average molecular weight was 15,000 were added by the double

jet method over a period of 30 sec to thereby effect a nucleation. 6.6 g of KBr was added and heated to 78°C, and the mixture was ripened. After the completion of ripening, 15.0 g of gelatin obtained by chemically  
5 modifying an alkali-processed gelatin of 100 thousand weight average molecular weight with succinic anhydride was added. Thereafter, the pH was adjusted to 5.5. An aqueous solution containing 15.8 g of KBr and 1.92 g of KI and 230 mL of an aqueous solution containing 29.3 g  
10 of AgNO<sub>3</sub> were added by the double jet method over a period of 30 min. During this period, the silver potential was maintained at -20 mV against saturated calomel electrode. Thereafter, an aqueous solution containing 64.5 g of AgNO<sub>3</sub> and 233 mL of an aqueous  
15 solution containing 42.3 g of KBr and 5.14 g of KI were added by the double jet method over a period of 37 min while increasing the flow rate so that the final flow rate was 1.33 times the initial flow rate. During this period, while the addition was being effected, the  
20 silver potential was maintained at -20 mV. Thereafter, an aqueous solution containing 70.8 g of AgNO<sub>3</sub> and an aqueous solution of KBr were added by the double jet method over a period of 35 min, while maintaining the silver potential at -10 mV.

25 [0200]

The mixture was cooled to 40°C, and 4.9 g of compound 1 was added. Further, 32 mL of a 0.8 M

aqueous sodium sulfite solution was added. The mixture had its pH value adjusted to 9.0 with the use of an aqueous solution of NaOH and was held still for 5 min. The resultant mixture was heated to 55°C, and the pH value thereof was adjusted to 5.5 with H<sub>2</sub>SO<sub>4</sub>. 1 mg of sodium benzenethiosulfonate was added, and further 13 g of lime-processed gelatin having a calcium concentration of 1 ppm was added. After the completion of addition, an aqueous solution of KBr and 250 mL of an aqueous solution containing 71.0 g of AgNO<sub>3</sub> were added over a period of 20 min, while maintaining the silver potential at +75 mV. During this period,  $1.0 \times 10^{-5}$  mol of yellow prussiate of potash was added per mol of silver, and  $1 \times 10^{-8}$  mol of K<sub>2</sub>IrCl<sub>6</sub> added per mol of silver. The mixture was washed with water, and gelatin was added so as to adjust the pH and pAg at 40°C to 6.5 and 8.8, respectively.

[0201]

The thus obtained emulsion contained tabular grains having an average equivalent sphere diameter of 1.33  $\mu\text{m}$ , an average equivalent circle diameter of 2.63  $\mu\text{m}$  and an average aspect ratio of 11.4. The ratio in projected area of grains having an aspect ratio of 8 or more to all the grains was 95%, and the twin plane spacing of tabular grains was 0.012  $\mu\text{m}$ .

[0202]

The thus obtained grains were observed through a



transmission electron microscope while cooling the same with liquid nitrogen. As a result, it was found that grains each having no dislocation line in a region extending from the grain center to 80% of its projected area constituted about 90% of all the grains, and that there were 10 or more dislocation lines per grain on grain peripheral portions extending from the grain extreme periphery to 20% of the projected area.

[0203]

10 (Preparation of emulsion Em-2)

The obtained emulsion was heated to 56°C, and compound 2 and sensitizing dyes ExS-1, ExS-2 and ExS-3 were added. Thereafter, the optimum chemical sensitization thereof was effected by the addition of potassium thiocyanate, chloroauric acid, sodium thiosulfate, hexafluorophenyldiphenylphosphine selenide, compound (F-11) defined later and compound 3. At the completion of chemical sensitization, compound (F-2) defined later was added.

20 [0204]

(Preparation of emulsion Em-3)

Emulsion Em-3 was prepared in the same manner as the emulsion Em-2, except that the chemical sensitization was carried out with the sensitizing dyes changed to sensitizing dyes ExS-7, ExS-8 and ExS-9.

[0205]

(Preparation of emulsion Em-N)

1250 mL of an aqueous solution containing 48 g of deionized gelatin and 0.75 g of KBr was vigorously agitated while maintaining the temperature at 70°C.

[0206]

5           276 mL of an aqueous solution containing 12.0 g of AgNO<sub>3</sub>) and an equimolar-concentration aqueous solution of KBr were added to the aqueous solution by the double jet method over a period of 7 min while maintaining the pAg at 7.26. Subsequently, 600 mL of an aqueous  
10       solution containing 108.0 g of AgNO<sub>3</sub> and an equimolar-concentration aqueous solution of a mixture of KBr and KI (2.0 mol% KI) were added by the double jet method over a period of 18 min 30 sec while maintaining the pAg at 7.30. Further, 18.0 mL of a 0.1% by weight  
15       aqueous thiosulfonic acid solution was added 5 min before the completion of the addition. The obtained emulsion was desalted and washed by the customary flocculation method, and re-dispersed. At 40°C, the pH and pAg were adjusted to 6.2 and 7.6, respectively.  
20       The temperature of the emulsion was controlled at 40°C, and compound 2 and sensitizing dyes ExS-10 and ExS-12 were added. Further, potassium thiocyanate, chloroauric acid, sodium thiosulfate, hexafluorophenyldiphenylphosphine selenide, compound  
25       (F-11) and compound 3 were added to the emulsion, and heated to 68°C to thereby effect the optimum chemical sensitization thereof. At the completion of chemical

sensitization, compound (F-2) defined later was added.

The obtained emulsion contained cubic grains having an equivalent sphere diameter of 0.19  $\mu\text{m}$  and a variation coefficient of equivalent sphere diameter of 14%.

5

[0207]

Emulsions Em-B to D, Em-F to J, Em-L to M were prepared in the same manner as the above emulsions Em-1, 2 and 3, except that the temperature, pH, silver potential, amount of silver nitrate, amount of KI, amount of compounds, type of sensitizing dyes, amount of seed emulsion, etc. were appropriately changed.

10

[0208]

Lists of the thus obtained emulsions are given in Tables 1 and 2.

15

[0209]

[Table 1]

Table 1

	Equivalent circle diameter ( $\mu\text{m}$ )	Aspect ratio	Equivalent sphere diameter ( $\mu\text{m}$ )	Grain shape	Dislocation line (number/grain)	Twin plane spacing ( $\mu\text{m}$ )	Ratio of grains having 8 or more aspect ratio to the total projected area (%)
Em-B	1.50	6.0	0.80	Tabular	10 or more	0.012	45
Em-C	0.85	7.1	0.51	Tabular	10 or more	0.012	55
Em-D	0.40	2.7	0.35	Tabular	10 or more	0.011	10 or less
Em-F	2.00	3.0	0.92	Tabular	10 or more	0.013	10
Em-G	1.60	7.0	0.79	Tabular	10 or more	0.012	50
Em-H	0.85	7.1	0.51	Tabular	10 or more	0.012	55
Em-I	0.58	3.2	0.45	Tabular	10 or more	0.010	15
Em-J	2.00	7.0	0.92	Tabular	10 or more	0.012	50
Em-L	1.25	4.3	0.89	Tabular	10 or more	0.011	15
Em-M	0.55	4.6	0.37	Tabular	10 or more	0.010	20
Em-N	—	—	0.19	Cubic	—	—	10 or less
Em-X	2.30	3.5	1.80	Thick plate twin crystal	Unable to measure	0.065	10
Em-Y	1.77	3.0	1.40	Thick plate twin crystal	Unable to measure	0.060	10
Em-Z	1.77	3.0	1.40	Thick plate twin crystal	Unable to measure	0.060	10

[0210]

[Table 2]

Table 2

	Equivalent circle diameter ( $\mu\text{m}$ )	Aspect ratio	Equivalent sphere diameter ( $\mu\text{m}$ )	Grain shape	Dislocation line (number/grain)	Twin plane spacing ( $\mu\text{m}$ )	Ratio of grains having 8 or more aspect ratio to the total projected area (%)
Em-1	3.10	10.0	1.65	Tabular	10 or more	0.015	90
Em-2	2.63	11.4	1.33	Tabular	10 or more	0.012	95
Em-3	2.63	11.4	1.33	Tabular	10 or more	0.012	95

[0211]

Preparation of coating sample

A support of cellulose triacetate film furnished  
with a substratum was coated with a plurality of layers  
5 of the following compositions, thereby preparing  
multilayer color lightsensitive material sample 001.

(Composition of lightsensitive layer)

Main materials for use in each layer are  
classified as follows:

10 ExC: cyan coupler;      ExS: spectral sensitizing dye  
UV: ultraviolet absorber;  
ExM: magenta coupler;    HBS: high-boiling organic  
                                 Solvent;  
ExY: yellow coupler;    H: gelatin hardener

15 (For each specific compound, in the following  
description, numeral is assigned after the character,  
and the formula is shown later).

The figure given beside the description of each  
component is for the coating amount expressed in the  
20 unit of g/m<sup>2</sup>. With respect to a silver halide, the  
coating amount is in terms of silver. With respect to  
a spectral sensitizing dye, the coating amount is  
expressed in the unit of mol per mol of silver halide  
present in the same layer.

25 [0212]

1st layer (1st antihalation layer)

Black colloidal silver	silver	0.070
Gelatin		0.660

	ExM-1		0.048
	Cpd-2		0.001
	F-8		0.001
	HBS-1		0.090
5	HBS-2		0.010
	[0213]		
	2nd layer (2nd antihalation layer)		
	Black colloidal silver	silver	0.090
	Gelatin		0.830
10	ExM-1		0.057
	ExF-1		0.002
	F-8		0.001
	HBS-1		0.090
	HBS-2		0.010
15	[0214]		
	3rd layer (Interlayer)		
	ExC-2		0.010
	Cpd-1		0.086
	UV-2		0.029
20	UV-3		0.052
	UV-4		0.011
	HBS-1		0.100
	Gelatin		0.580
	[0215]		
25	4th layer (Low-speed red-sensitive emulsion layer)		
	Em-D	silver	0.57
	Em-C	silver	0.47

	ExC-1	0.222
	ExC-2	0.010
	ExC-3	0.072
	ExC-4	0.148
5	ExC-5	0.005
	ExC-6	0.008
	ExC-8	0.071
	ExC-9	0.010
	ExS-1	$1.4 \times 10^{-3}$
10	ExS-2	$6.0 \times 10^{-4}$
	ExS-3	$2.0 \times 10^{-5}$
	UV-2	0.036
	UV-3	0.067
	UV-4	0.014
15	Cpd-2	0.010
	Cpd-4	0.012
	HBS-1	0.240
	HBS-5	0.010
	Gelatin	1.630
20	[0216]	
5th layer (Medium-speed red-sensitive emulsion layer)		
	Em-B	silver 0.63
	ExC-1	0.111
	ExC-2	0.039
25	ExC-3	0.018
	ExC-4	0.074
	ExC-5	0.019



	ExC-6	0.024
	ExC-8	0.010
	ExC-9	0.005
	ExS-1	$6.3 \times 10^{-4}$
5	ExS-2	$2.6 \times 10^{-4}$
	ExS-3	$8.7 \times 10^{-6}$
	Cpd-2	0.020
	Cpd-4	0.021
	HBS-1	0.129
10	Gelatin	0.900

[0217]

6th layer (High-speed red-sensitive emulsion layer)

	Em-Y	silver	1.27
	ExC-1		0.122
15	ExC-6		0.032
	ExC-8		0.110
	ExC-9		0.005
	ExC-10		0.159
	ExS-1		$3.2 \times 10^{-4}$
20	ExS-2		$2.6 \times 10^{-4}$
	ExS-3		$8.8 \times 10^{-6}$
	Cpd-2		0.068
	Cpd-4		0.015
	HBS-1		0.440
25	Gelatin		1.610

[0218]

7th layer (Interlayer)

	Cpd-1	0.081
	Cpd-6	0.002
	Solid disperse dye ExF-4	0.015
	HBS-1	0.049
5	Polyethyl acrylate latex	0.088
	Gelatin	0.759

[0219]

8th layer (Layer capable of exerting interlayer effect  
on red-sensitive layer)

10	Em-J	silver	0.40
	Cpd-4		0.010
	ExM-2		0.082
	ExM-3		0.006
	ExM-4		0.026
15	ExY-1		0.010
	ExY-4		0.040
	ExC-7		0.007
	ExS-4		$7.0 \times 10^{-4}$
	ExS-5		$2.5 \times 10^{-4}$
20	HBS-1		0.203
	HBS-3		0.003
	HBS-5		0.010
	Gelatin		0.570

[0220]

25	9th layer (Low-speed green-sensitive emulsion layer)		
	Em-H	silver	0.23
	Em-G	silver	0.15

	Em-I	silver	0.26
	ExM-2		0.388
	ExM-3		0.040
	ExY-1		0.003
5	ExY-3		0.002
	ExC-7		0.009
	ExS-5		$3.0 \times 10^{-4}$
	ExS-6		$8.4 \times 10^{-5}$
	ExS-7		$1.1 \times 10^{-4}$
10	ExS-8		$4.5 \times 10^{-4}$
	ExS-9		$1.3 \times 10^{-4}$
	HBS-1		0.337
	HBS-3		0.018
	HBS-4		0.260
15	HBS-5		0.110
	Cpd-5		0.010
	Gelatin		1.470

[0221]

10th layer (Medium-speed green-sensitive emulsion  
20 layer)

	Em-F	silver	0.42
	ExM-2		0.084
	ExM-3		0.012
	ExM-4		0.005
25	ExY-3		0.002
	ExC-6		0.003
	ExC-7		0.007

	ExC-8		0.008
	ExS-7		$1.0 \times 10^{-4}$
	ExS-8		$7.1 \times 10^{-4}$
	ExS-9		$2.0 \times 10^{-4}$
5	HBS-1		0.096
	HBS-3		0.002
	HBS-5		0.002
	Cpd-5		0.004
	Gelatin		0.382
10	[0222]		
	11th layer (High-speed green-sensitive emulsion layer)		
	Em-Z	silver	0.95
	ExC-6		0.002
	ExC-8		0.010
15	ExM-1		0.014
	ExM-2		0.023
	ExM-3		0.023
	ExM-4		0.005
	ExM-5		0.040
20	ExY-3		0.003
	ExS-7		$8.4 \times 10^{-4}$
	ExS-8		$5.9 \times 10^{-4}$
	ExS-9		$1.7 \times 10^{-4}$
	Cpd-3		0.004
25	Cpd-4		0.007
	Cpd-5		0.010
	HBS-1		0.259

	HBS-5		0.020 <sub>7</sub>
	Polyethyl acrylate latex		0.099
	Gelatin		0.781
	[0223]		
5	12th layer (Yellow filter layer)		
	Cpd-1		0.088
	Solid disperse dye ExF-2		0.051
	Solid disperse dye ExF-8		0.010
	HBS-1		0.049
10	Gelatin		0.593
	[0224]		
	13th layer (Low-speed blue-sensitive emulsion layer)		
	Em-N	silver	0.12
	Em-M	silver	0.09
15	Em-L	silver	0.50
	ExC-1		0.024
	ExC-7		0.011
	ExY-1		0.002
	ExY-2		0.956
20	ExY-4		0.091
	ExS-10		$8.5 \times 10^{-5}$
	ExS-11		$6.4 \times 10^{-4}$
	ExS-12		$8.5 \times 10^{-5}$
	ExS-13		$5.0 \times 10^{-4}$
25	Cpd-2		0.037
	Cpd-3		0.004
	HBS-1		0.372

	HBS-5		0.047
	Gelatin		2.201
	[0225]		
	14th layer (High-speed blue-sensitive emulsion layer)		
5	Em-X	silver	1.22
	ExY-2		0.235
	ExY-4		0.018
	ExS-10		$1.5 \times 10^{-4}$
	ExS-13		$2.0 \times 10^{-4}$
10	Cpd-2		0.075
	Cpd-3		0.001
	HBS-1		0.087
	Gelatin		1.156
	[0226]		
15	15th layer (1st protective layer)		
	0.07 $\mu$ m silver iodobromide emulsion		
		silver	0.28
	UV-1		0.358
	UV-2		0.179
20	UV-3		0.254
	UV-4		0.025
	F-11		0.0081
	SC-1		0.078
	ExF-5		0.0024
25	ExF-6		0.0012
	ExF-7		0.0010
	HBS-1		0.175

HBS-4 0.050

Gelatin 2.231

[0227]

16th layer (2nd protective layer)

5 H-1 0.400

B-1 (diameter 1.7  $\mu$ m) 0.050

B-2 (diameter 1.7  $\mu$ m) 0.150

B-3 0.050

SC-1 0.200

10 Gelatin 0.711.

[0228]

In addition to the above components, W-1 to W-6, B-4 to B-6, F-1 to F-17, a lead salt, a platinum salt, an iridium salt and a rhodium salt were appropriately added to the above individual layers in order to improve the storage life, processability, resistance to pressure, antiseptic and mildewproofing properties, antistatic properties and applicability thereof.

[0229]

20 Preparation of dispersion of organic solid disperse dye:

The ExF-2 of the 12th layer was dispersed by the following method. Specifically,

Wet cake of ExF-2 (contg. 17.6 wt.% water)

25 2.800 kg

Sodium octylphenyldiethoxymethanesulfonate

(31 wt.% aq. soln.) 0.376 kg

F-15 (7% aq. soln.)	0.011 kg
Water	4.020 kg
Total	7.210 kg

(adjusted to pH = 7.2 with NaOH).

5 [0230]

Slurry of the above composition was agitated by means of a dissolver to thereby effect a preliminary dispersion, and further dispersed by means of agitator mill LMK-4 under such conditions that the peripheral  
10 speed, delivery rate and packing ratio of 0.3 mm-diameter zirconia beads were 10 m/s, 0.6 kg/min and 80%, respectively, until the absorbance ratio of the dispersion became 0.29. Thus, a solid particulate dispersion was obtained, wherein the average particle  
15 diameter of dye particulate was 0.29  $\mu\text{m}$ .

[0231]

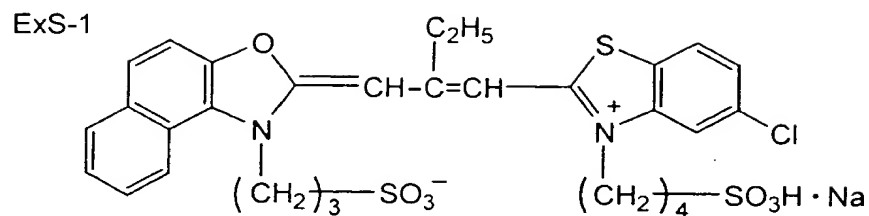
Solid dispersions of ExF-4 and ExF-8 were obtained in similar manners. The average particle diameters of these dye particulates were 0.28  $\mu\text{m}$  and 0.49  $\mu\text{m}$ ,  
20 respectively.

[0232]

The compounds employed in the emulsion preparation and compounds incorporated in the above layers in the preparation of coating sample will be specified below.  
25

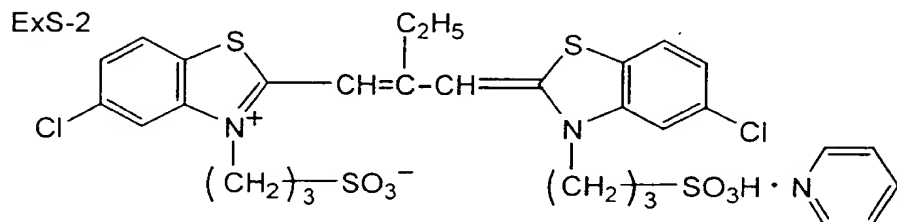


[0233]  
[Chem 10]



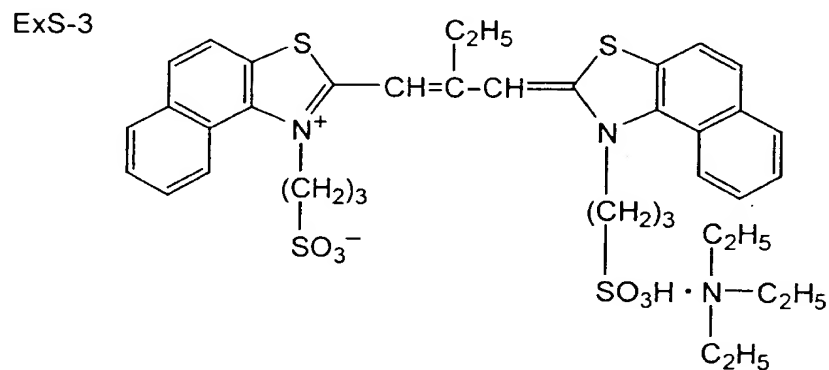
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[0234]  
[Chem 11]



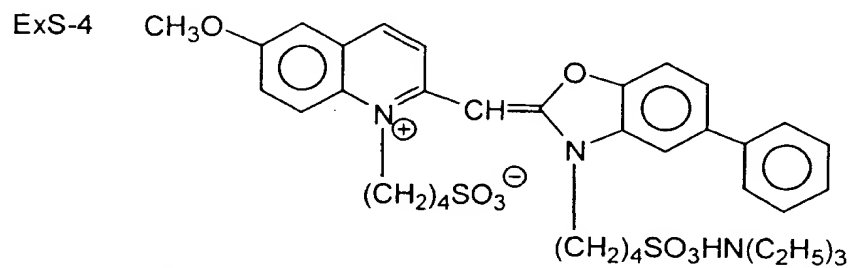
10

[0235]  
[Chem 12]



15

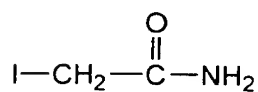
[0236]  
[Chem 13]



20

[0237]  
[Chem 14]

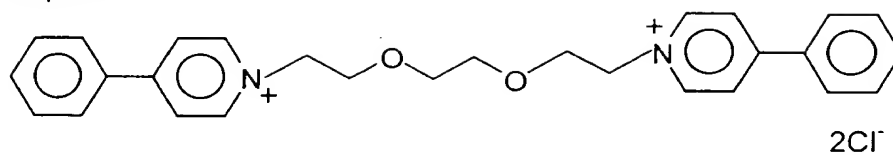
Compound 1



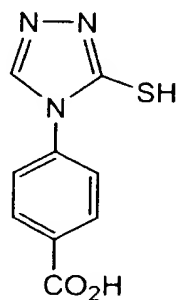
[0238]  
[Chem 15]

5

Compound 2



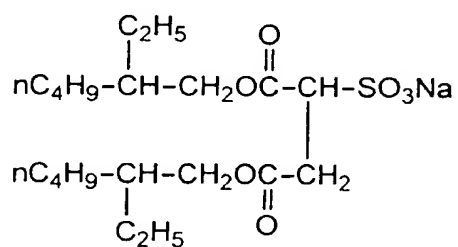
[0239]  
[Chem 16]  
Compound 3



10

[0240]  
[Chem 17]

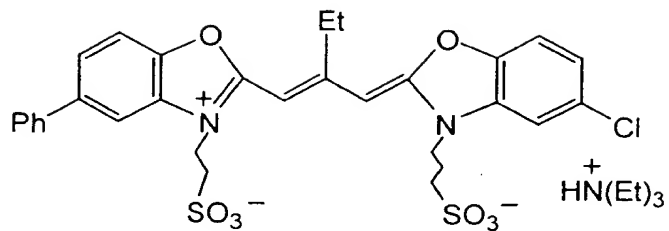
Compound 5



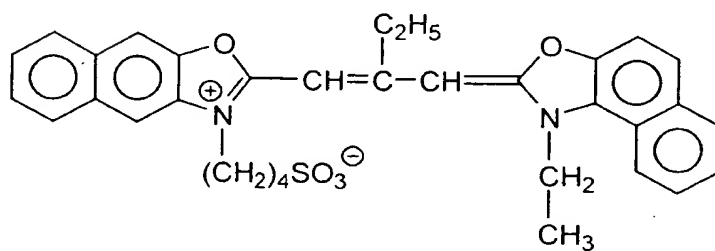
15

[0241]  
[Chem 18]

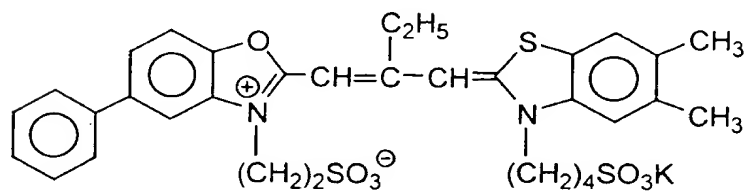
ExS-5



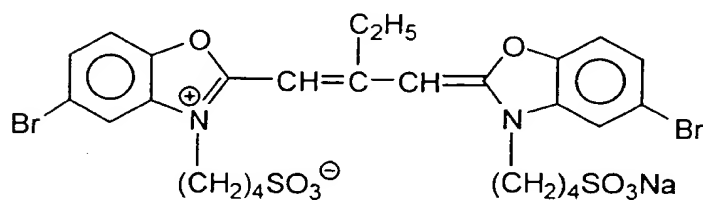
ExS-6



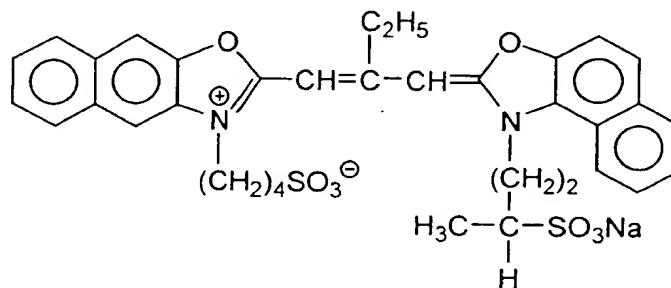
ExS-7



ExS-8

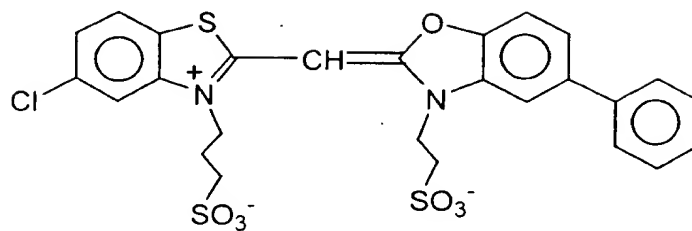


ExS-9

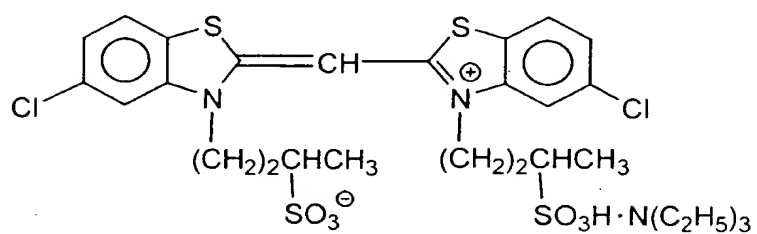


[0242]-[0245]  
[Chem 19]-[Chem 22]

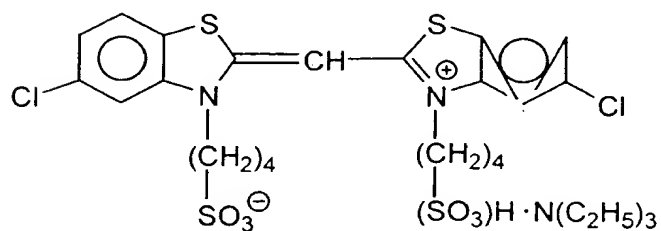
ExS-10



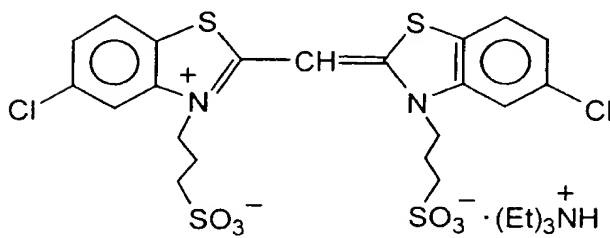
ExS-11



ExS-12

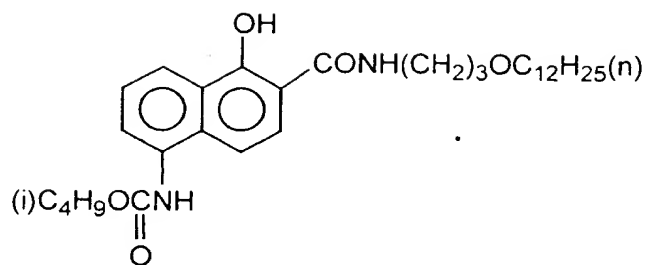


ExS-13

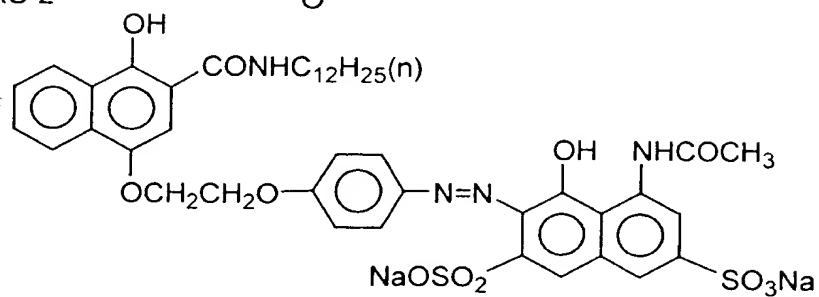


[0246]  
[Chem 23]

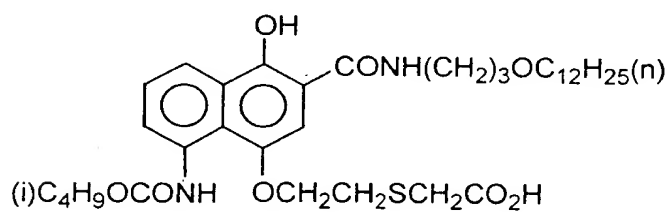
ExC-1



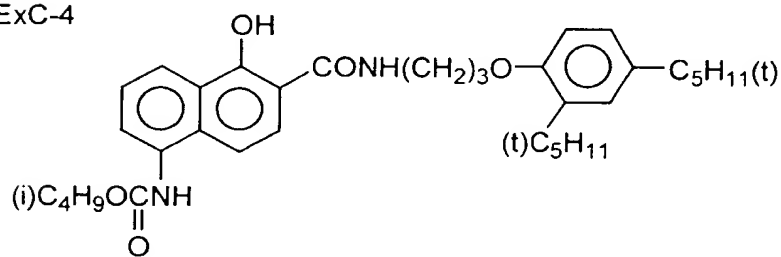
ExC-2



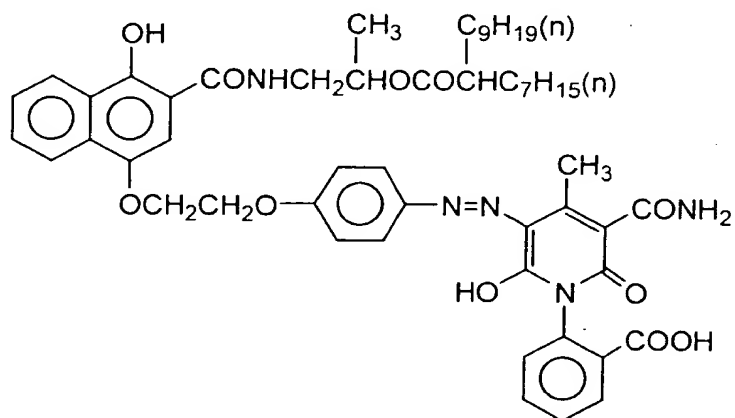
ExC-3



ExC-4

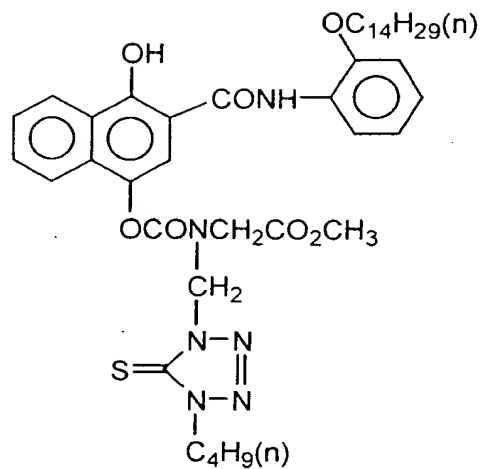


ExC-5

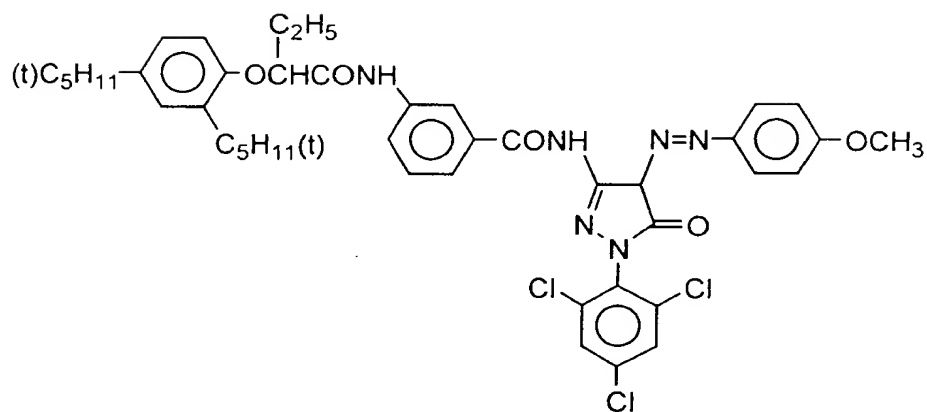


[0247]  
[Chem 24]

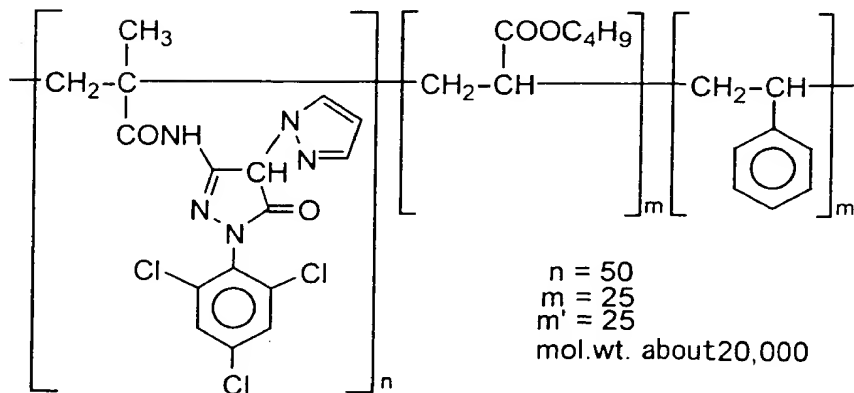
ExC-6



ExM-1

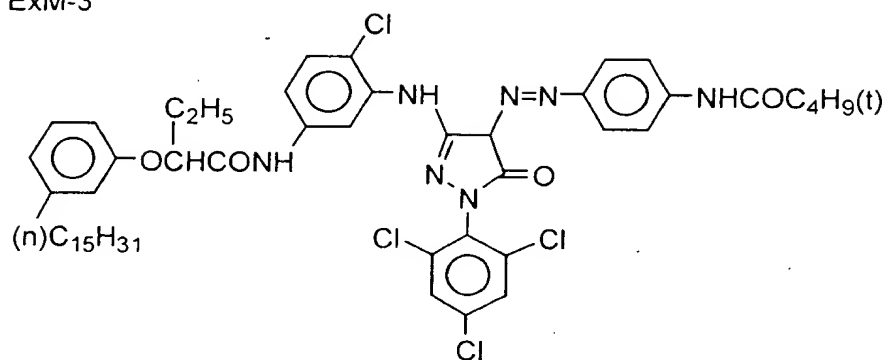


ExM-2

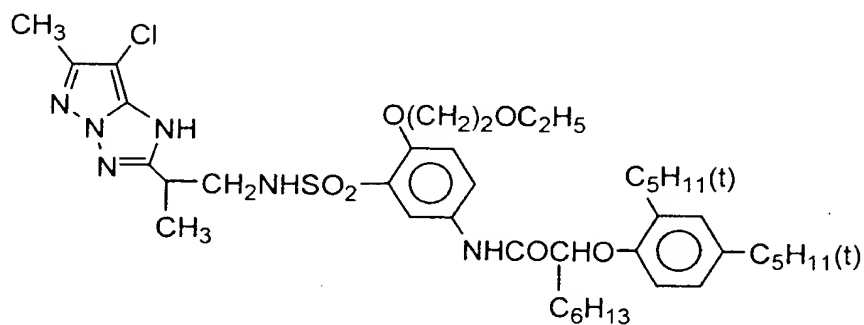


[0248]  
[Chem 25]

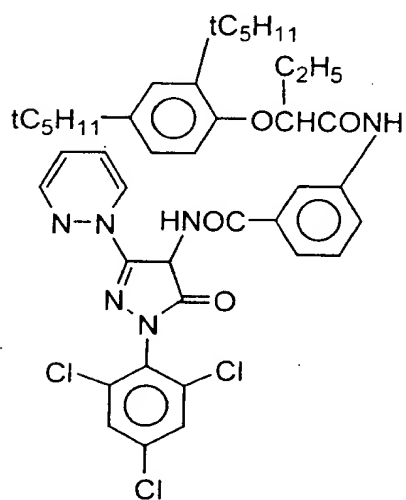
ExM-3



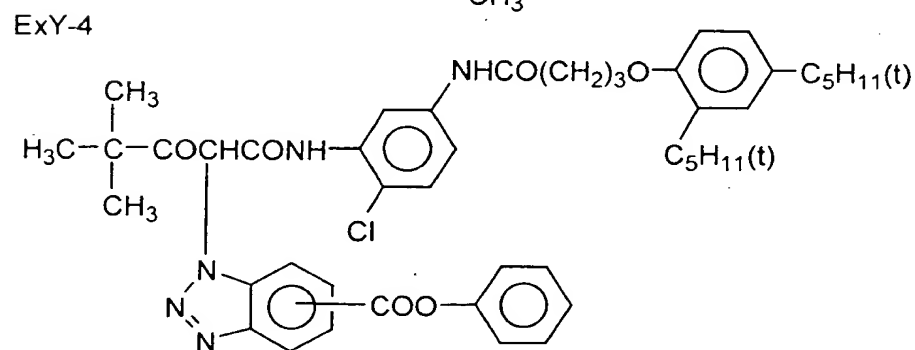
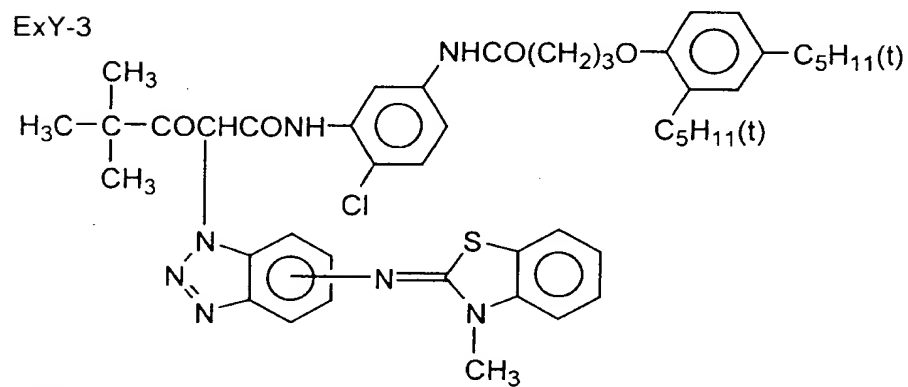
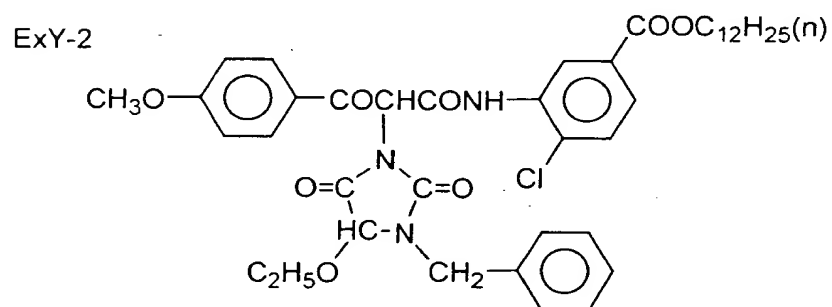
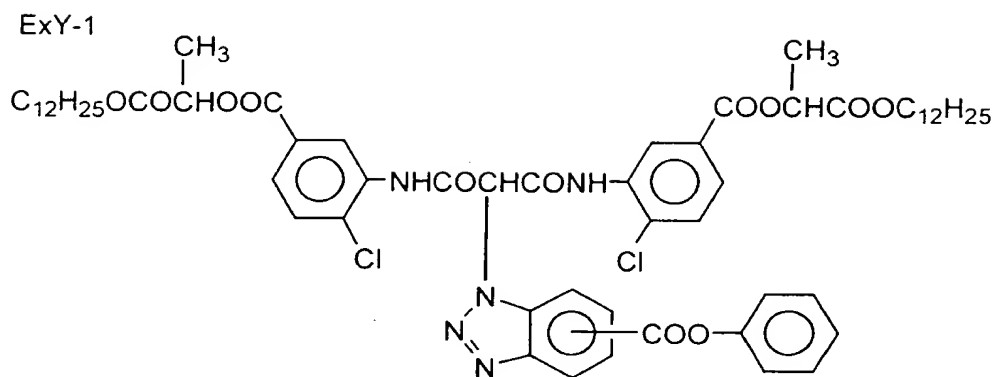
ExM-4



ExM-5



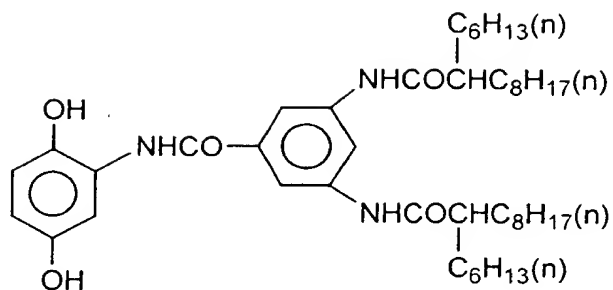
[0249]  
[Chem 26]



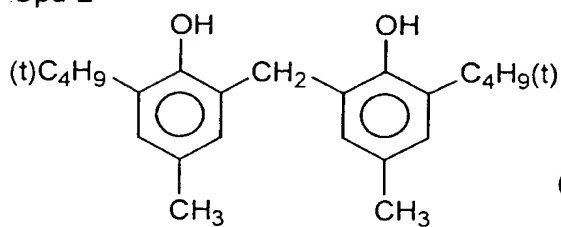


[0250]  
[Chem 27]

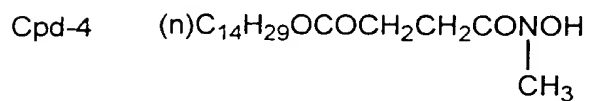
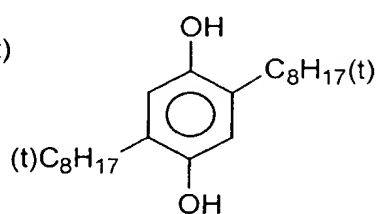
Cpd-1



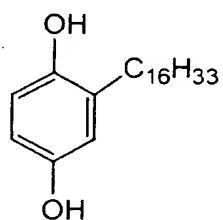
Cpd-2



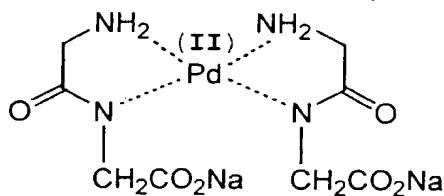
Cpd-3



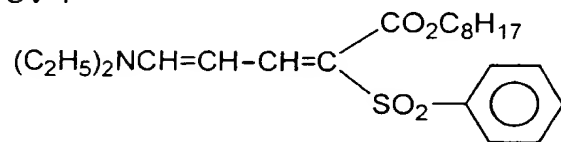
Cpd-5



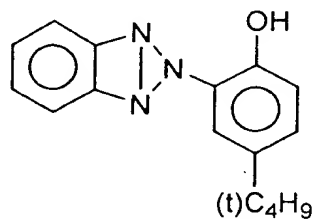
Cpd-6



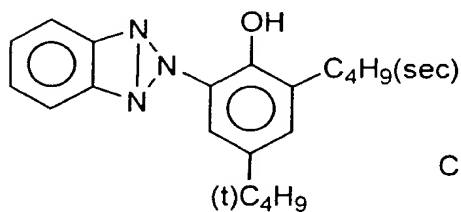
UV-1



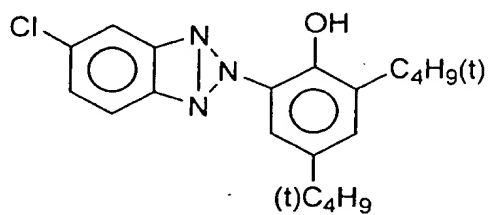
UV-2

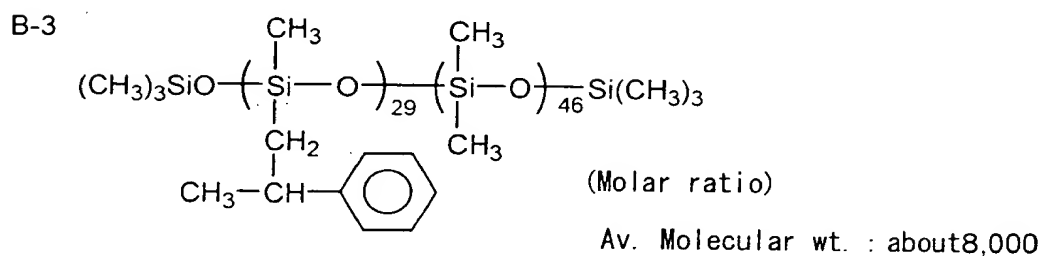
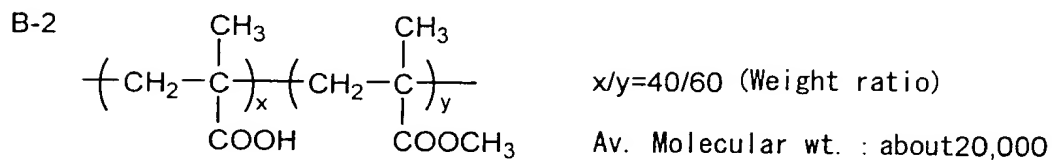
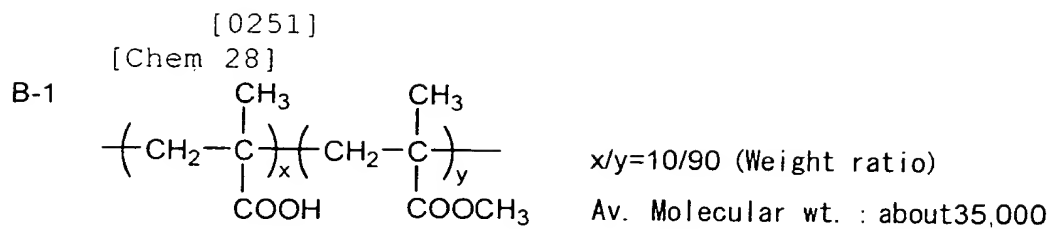


UV-3

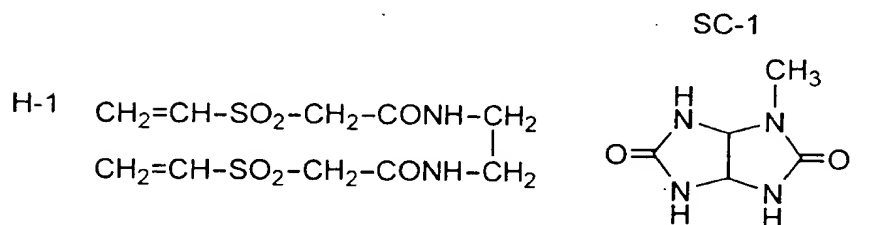


UV-4



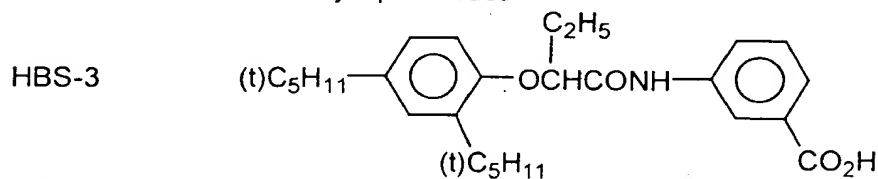


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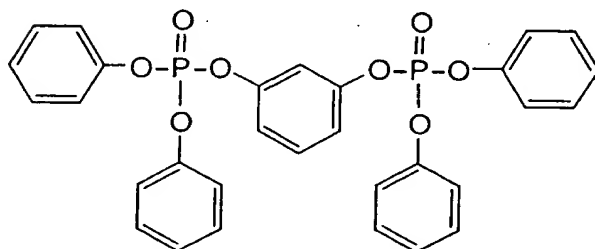
HBS-1 Tricresyl phosphate

HBS-2 Di-n-butyl phthalate



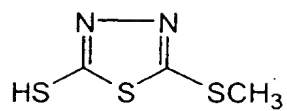
HBS-4 Tri(2-ethylhexyl) phosphate

HBS-5

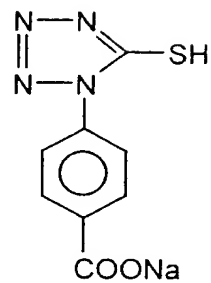


[0252]  
[Chem 29]

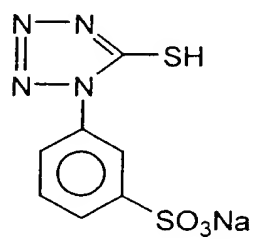
F-1



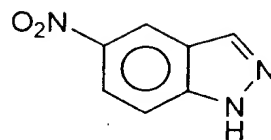
F-2



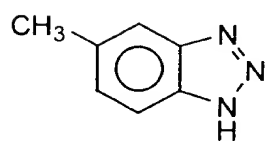
F-3



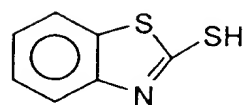
F-4



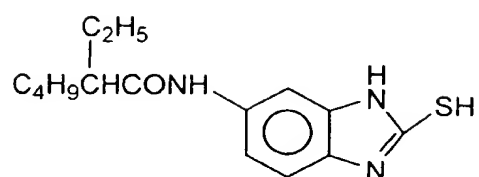
F-5



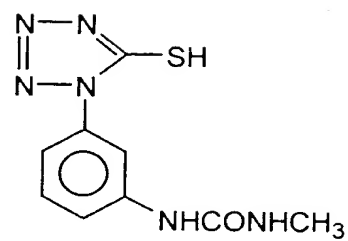
F-6



F-7

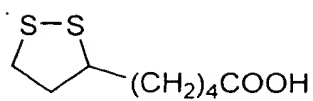


F-8

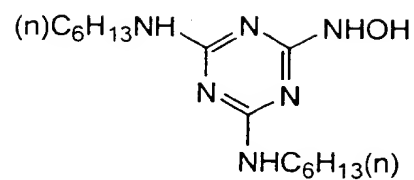


[0253]  
[Chem 30]

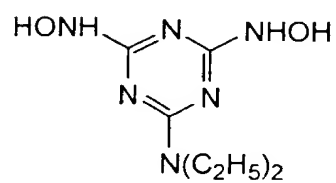
F-9



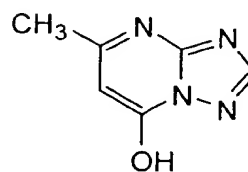
F-10



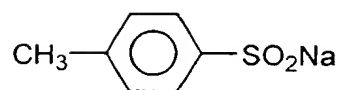
F-11



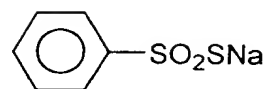
F-12



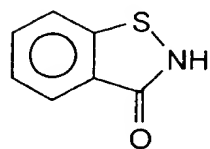
F-13



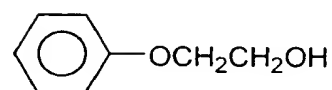
F-14



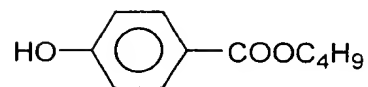
F-15



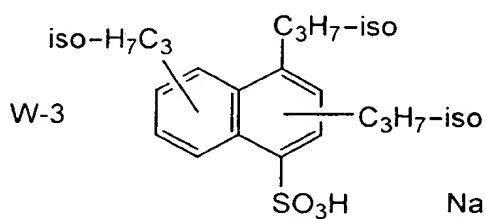
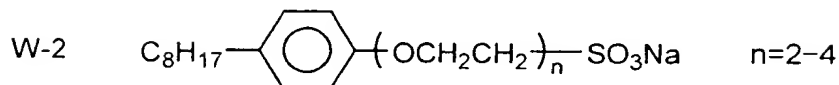
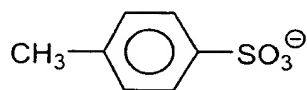
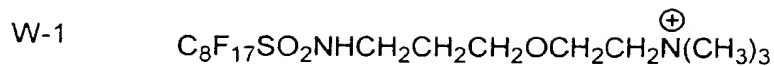
F-16



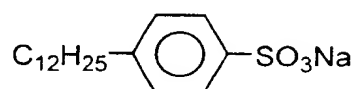
F-17



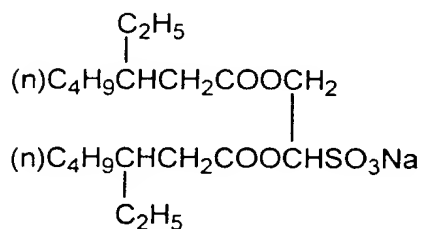
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[Chem 31]



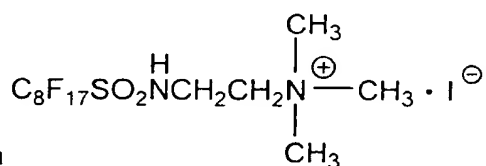
W-4



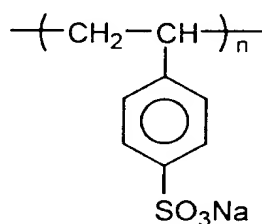
W-5



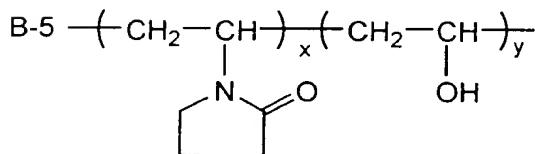
W-6



B-4

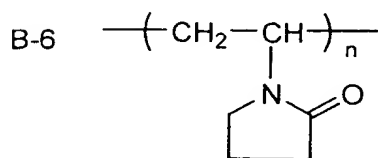


Av. Molecular wt. : about 750,000



$x/y=70/30$  (Weight ratio)

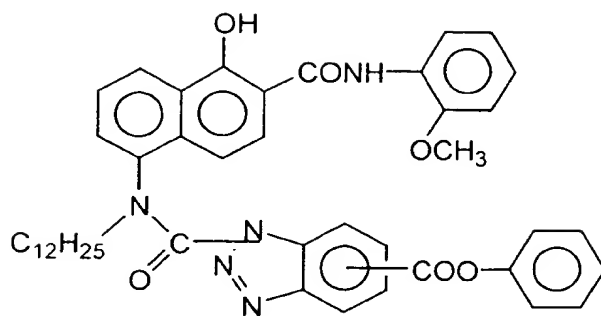
Av. Molecular wt. : about 17,000



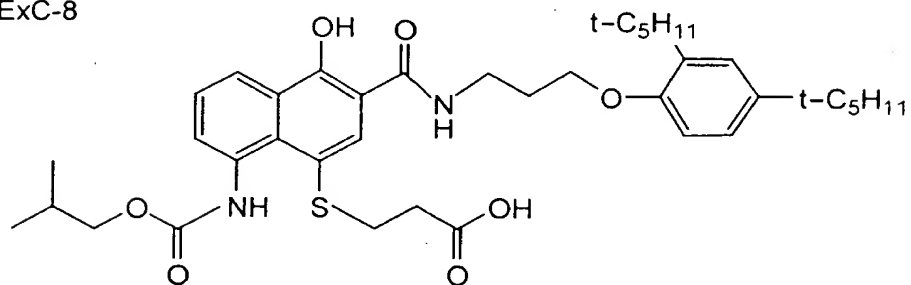
Av. molecular wt. : about 10,000

[0255]  
[Chem 32]

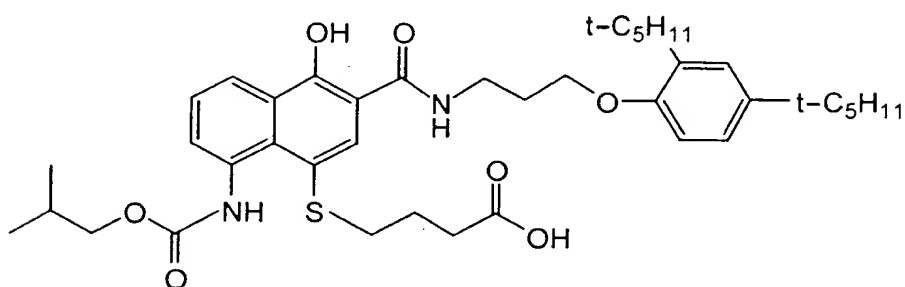
ExC-7



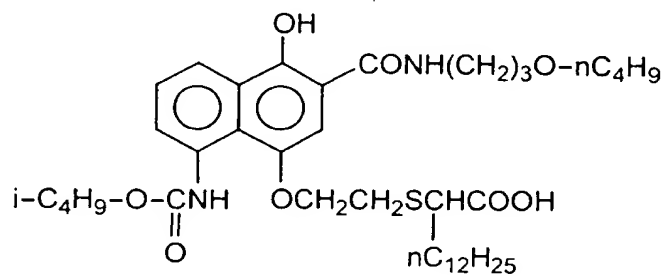
ExC-8



ExC-9

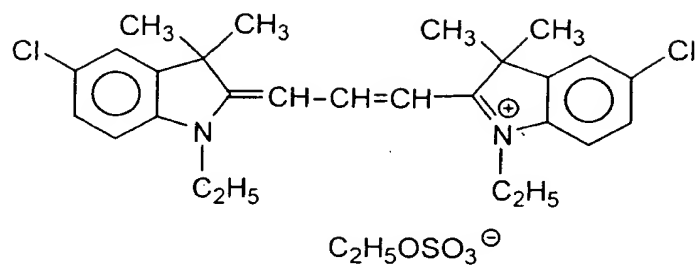


ExC-10

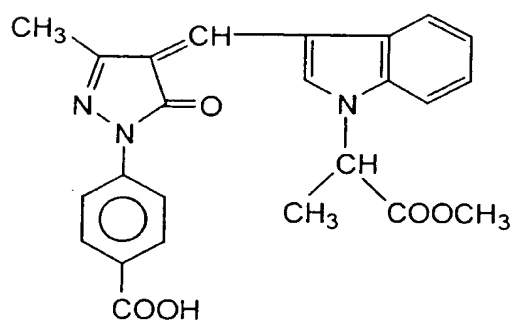


[0256]  
[Chem 33]

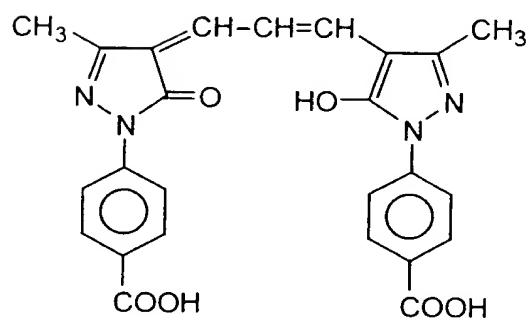
ExF-1



ExF-2

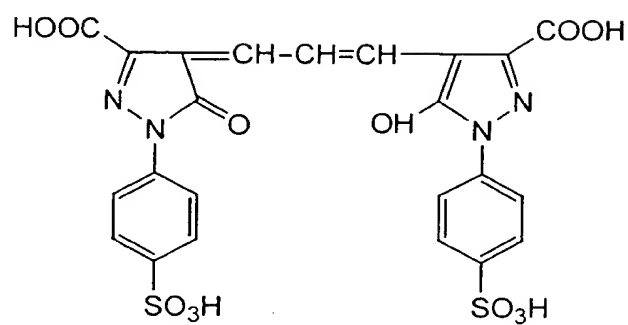


ExF-4

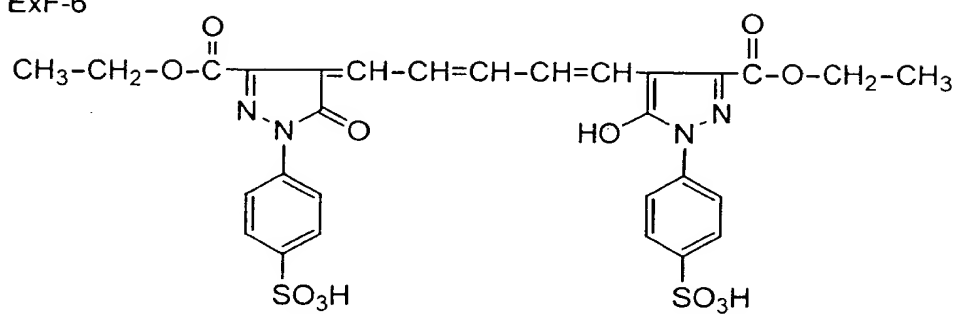


[0257]  
[Chem 34]

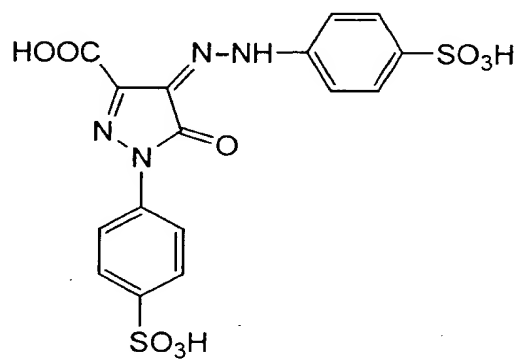
ExF-5



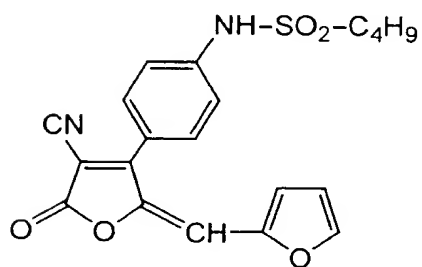
ExF-6



ExF-7



ExF-8





[0258]

Sample 002 was prepared in the same manner as the above sample 001, except that only the silver halide emulsions of the 6th, 11th and 14th layers were changed as specified in Table 3.

Next, lens-fitted packaging units were molded with the following sample resins, loading samples 001 and 002, thereby to obtain lens-fitted lightsensitive material packaging units.

[0259]

Figure 1 is a perspective view of a fabricated lens-fitted film unit. Now, the molding of a cartridge and the assembly of a unit will be described.

Referring to Figure 1, three members designated as front cover 4, body base 3 and back cover 5 were formed by means of hot-runner-type metal molds. Other parts, which are not described in detail, were assembled into the body, followed by assembly of the front cover. The thus obtained unit was loaded with the above prepared samples 001 and 002. Finally, the back cover was assembled thereinto, thereby obtaining a lens-fitted lightsensitive material packaging unit. This lens-fitted lightsensitive material packaging unit together with a separately supplied explanatory pasteboard was packaged by a packaging machine with the use of a packaging film produced by laminating a polyethylene film with an aluminum foil. The package was well-known

pillow type package whereby a bag configuration was formed with three-way hot melt seal, thereby obtaining a sealed package inhibiting the infiltration of external air.

5 [0260]

Sample resins 1 to 19 were produced in the following manner, molded into unit members, and assembled into lens-fitted lightsensitive material packaging units, which were packaged with a packaging film. The photographic performance of obtained lens-fitted lightsensitive material packaging units was tested. Each of the resins was molded into the front cover 4, body base 3 and back cover 5.

[0261]

15 The sample resins were produced according to the following procedures. The extruder employed in the production of sample resins was a vent type single-screw extruder of 100 mm screw diameter and of L/D = 28. The extrusion temperature was 230°C.

20 [0262]

(Preparation of sample resin 1)

A carbon master batch was produced by the known process as described in the Example portion of JP-A-6-130565. Specifically, 49% by weight of carbon black of 1.5 mg/g acetaldehyde gas equilibrium adsorption amount, 8.0 pH and 24 nm average particle diameter, 1% by weight of zinc stearate and 50% by

weight of PS natural resin were mixed together and kneaded by means of a Banbury mixer. The mixture was milled by means of mixing rolls, thereby obtaining a rectangular high carbon content resin. Subsequently, 49% by weight of obtained high carbon content resin, 48.5% by weight of PS natural resin, 1.5% by weight of compound S-8 mentioned above and 1% by weight of zinc stearate were mixed together, and melted and kneaded by means of the above vent type single-screw extruder. Thus, cylindrical carbon master batch M1 was obtained. The carbon master batch M1 and PS natural resin were mixed at a ratio of 1:35 and extruded once through an extruder, thereby obtaining sample resin 1.

[0263]

(Preparation of sample resin 2)

Sample resin 2 was prepared in the same manner as the above sample resin 1, except that, in place of the carbon master batch M1, carbon master batch M2 was produced using a carbon black of 2.1 mg/g acetaldehyde gas equilibrium adsorption amount, 7.5 pH and 16 nm average particle diameter.

[0264]

(Preparation of sample resin 3)

Sample resin 3 was prepared in the same manner as the above sample resin 1, except that the above compound S-1 was employed in place of the compound S-1.

(Preparation of sample resin 4)

Sample resin 4 was prepared in the same manner as the above sample resin 2, except that the above compound S-1 was employed in place of the compound S-1.

[0265]

5 (Preparation of sample resin 5)

Sample resin 5 was prepared in the same manner as the above sample resin 1, except that the extrusion by means of the same extruder was carried out five times to thereby effect a resin reclamation.

10 (Preparation of sample resin 6)

Sample resin 6 was prepared in the same manner as the above sample resin 2, except that, as in the preparation of the sample resin 5, the extrusion by means of the extruder was carried out five times to thereby effect a resin reclamation.

[0266]

(Preparation of sample resin 7)

Sample resin 7 was prepared in the same manner as the above sample resin 3, except that, as in the preparation of the sample resin 5, the extrusion by means of the extruder was carried out five times to thereby effect a resin reclamation.

(Preparation of sample resin 8)

Sample resin 8 was prepared in the same manner as the above sample resin 4, except that, as in the preparation of the sample resin 5, the extrusion by means of the extruder was carried out five times to

thereby effect a resin reclamation.

[0267]

(Preparation of sample resin 9)

Sample resin 9 was prepared in the same manner as  
5 the above sample resin 1, except that the extrusion by  
means of the same extruder was carried out four times,  
followed by 1/30 supplemental addition of the carbon  
master batch resin M1 and by further extrusion  
performed once, to thereby effect a resin reclamation.

10 (Preparation of sample resin 10)

Sample resin 10 was prepared in the same manner as  
the above sample resin 2, except that the extrusion by  
means of the same extruder was carried out four times,  
followed by 1/30 supplemental addition of the carbon  
15 master batch resin M1 and by further extrusion  
performed once, to thereby effect a resin reclamation.

[0280]

(Preparation of sample resin 11)

Sample resin 11 was prepared in the same manner as  
20 the above sample resin 1, except that, in place of the  
carbon master batch M1, a carbon master batch was  
produced using a carbon black of 0.6 mg/g acetaldehyde  
gas equilibrium adsorption amount and 28 nm average  
particle diameter, thereby obtaining a precursor resin,  
25 and except that the extrusion of the precursor resin by  
means of the same extruder was carried out four times,  
followed by 1/30 supplemental addition of the carbon

master batch resin and by further extrusion performed once, to thereby effect a resin reclamation.

[0269]

(Preparation of sample resin 12)

5           Sample resin 12 was prepared in the same manner as the above sample resin 1, except that, in place of the carbon master batch M1, a carbon master batch was produced using a carbon black of 3.2 mg/g acetaldehyde gas equilibrium adsorption amount and 12 nm average  
10   particle diameter, thereby obtaining a precursor resin, and except that the extrusion of the precursor resin by means of the same extruder was carried out four times, followed by 1/30 supplemental addition of the carbon master batch resin and by further extrusion performed  
15   once, to thereby effect a resin reclamation.

[0270]

(Preparation of sample resin 13)

          Sample resin 13 was prepared in the same manner as the above sample resin 1, except that the extrusion by  
20   means of the same extruder was carried out four times, followed by supplemental addition of the compound S-8 in the same amount as the reduction thereof caused by pyrolysis during the extrusions and followed by further extrusion performed once, to thereby effect a resin  
25   reclamation.

[0271]

(Preparation of sample resin 14)

Sample resin 14 was prepared in the same manner as the above sample resin 3, except that the extrusion by means of the same extruder was carried out four times, followed by supplemental addition of the compound S-1 in the same amount as the reduction thereof caused by pyrolysis during the extrusions and followed by further extrusion performed once, to thereby effect a resin reclamation.

[0272]

(Preparation of sample resin 15)

Sample resin 15 was prepared in the same manner as the above sample resin 1, except that antioxidant S-26 was added and that the extrusion of thus obtained precursor resin by means of the same extruder was carried out four times, followed by supplemental addition of the antioxidant S-26 in the same amount as the reduction thereof caused by pyrolysis during the extrusions and followed by further extrusion performed once, to thereby effect a resin reclamation.

[0273]

(Preparation of sample resin 16)

Sample resin 16 was prepared in the same manner as the above sample resin 1, except that the above compound S-12 was used and that the extrusion of thus obtained precursor resin by means of the same extruder was carried out four times, followed by supplemental addition of the compound S-12 in the same amount as the

reduction thereof caused by pyrolysis during the extrusions and followed by further extrusion performed once, to thereby effect a resin reclamation.

[0274]

5 (Preparation of sample resin 17)

Sample resin 17 was prepared in the same manner as the above sample resin 1, except that the extrusion by means of the same extruder was carried out four times, followed by 1/30 supplemental addition of the carbon  
10 master batch resin M1 and further supplemental addition of the compound S-8 in the same amount as the reduction thereof caused by pyrolysis during the extrusions and followed by further extrusion performed once, to thereby effect a resin reclamation.

15 [0275]

(Preparation of sample resin 18)

Sample resin 18 was prepared in the same manner as the above sample resin 2, except that the extrusion by means of the same extruder was carried out four times,  
20 followed by 1/30 supplemental addition of the carbon master batch resin M2 and further supplemental addition of the compound S-8 in the same amount as the reduction thereof caused by pyrolysis during the extrusions and followed by further extrusion performed once, to  
25 thereby effect a resin reclamation.

[0276]

(Preparation of sample resin 19)



Sample resin 19 was prepared in the same manner as the above sample resin 3, except that the extrusion by means of the same extruder was carried out four times, followed by 1/30 supplemental addition of the carbon master batch resin M1 and further supplemental addition of the compound S-1 in the same amount as the reduction thereof caused by pyrolysis during the extrusions and followed by further extrusion performed once, to thereby effect a resin reclamation.

10 [0277]

(Preparation of sample resin 20)

Sample resin 20 was prepared in the same manner as the above sample resin 4, except that the extrusion by means of the same extruder was carried out four times, followed by 1/30 supplemental addition of the carbon master batch resin M2 and further supplemental addition of the compound S-1 in the same amount as the reduction thereof caused by pyrolysis during the extrusions and followed by further extrusion performed once, to thereby effect a resin reclamation.

20

[0278]

(Preparation of sample resin 21)

Sample resin 21 was prepared in the same manner as the above sample resin 14, except that the extrusion by means of the same extruder was carried out four times, followed by 1/30 supplemental addition of the carbon master batch resin M2 and further supplemental addition

25

of the compound S-1 in the same amount as the reduction thereof caused by pyrolysis during the extrusions and followed by further extrusion performed once, to thereby effect a resin reclamation.

5 [0279]

The particulars of these sample resins 1 to 21 are listed in Table 4 later. There, the adsorptive capacity of adsorbent (carbon black) was evaluated on the basis of the above equilibrium adsorption amount of  
10 acetaldehyde gas.

[0280]

The lightsensitive materials 001 and 002 were exposed to light for 1/100 sec using gelatin filter SC-39 manufactured by Fuji Photo Film Co. Ltd., and  
15 continuous wedge, and then the following development processing was conducted to obtain specific speed.

[0281]

Determination of specific photographic speed

Generally, ISO speed, which is an international  
20 standard, is used for speed of a lightsensitive material. According to the ISO standard, the lightsensitive material is development processed on the fifth day after an exposure to light, and the development processing is performed according to the  
25 processing instructed by each company. So, in the present invention, the time period from the exposure to light to the development processing was shortened, and

a predetermined development processing is conducted.

[0282]

This method of determining specific photographic speed accords with JIS K 7614-1981, but is different  
5 from JIS K 7614-1981 in that the development processing is completed in a range of 30 min to 6 hour after sensitometric exposure, and that the following Fuji Color processing formula CN-16 is conducted for the development processing. Others are substantially the  
10 same as the determination method described in JIS.

[0283]

The test condition, exposure to light, density measurement and determination of specific photographic speed were the same as those described in JP-63-226650,  
15 except for the following development processing.

[0284]

The development was performed in the following manner by using the automatic processor FP-360B manufactured by Fuji Photo Film Co. Ltd. Note that the  
20 processor was remodeled so that the overflow solution of the bleaching bath was not carried over to the following bath, but all of it was discharged to a waste fluid tank. The FP-360B processor was loaded with evaporation compensation means described in Journal of  
25 Technical Disclosure No. 94-4992.

[0285]

The processing steps and the processing solution

compositions are presented below.

(Processing steps)

	Step	Time		Temperature	Replenishment rate*		Tank volume
5	Color development	3 min	5 sec	37.8°C	20	mL	11.5L
10	Bleaching	50 sec		38.0°C	5	mL	5L
	Fixing (1)	50 sec		38.0°C	-		5L
	Fixing (2)	50 sec		38.0°C	8	mL	5L
15	Washing	30 sec		38.0°C	17	mL	3L
	Stabilization (1)	20 sec		38.0°C	-		3L
20	Stabilization (2)	20 sec		38.0°C	15	mL	3L
	Drying	1 min	30 sec	60°C			
25	[0286]						

\*The replenishment rate was per 1.1m of a 35-mm wide sensitized material (equivalent to one 24 Ex. 1)

The stabilizer and the fixing solution were counterflowed in the order of (2) → (1), and all of the overflow of the washing water was introduced to the fixing bath (2). Note that the amounts of the developer carried over to the bleaching step, the bleaching solution carried over to the fixing step, and the fixer carried over to the washing step were 2.5 mL, 2.0 mL and 2.0 mL per 1.1m of a 35-mm wide sensitized material, respectively. Note also that each crossover time was 6 sec, and this time was included in the processing time of each preceding step.

The opening area of the above processor for the color developer and the bleaching solution were 100 cm<sup>2</sup> and 120 cm<sup>2</sup>, respectively, and the opening areas for other solutions were about 100 cm<sup>2</sup>.

5

[0287]

The compositions of the processing solutions are presented below.

	(Color developer)	[Tank solution] (g)	[Replenisher] (g)
10	Diethylenetriamine pentaacetic acid	3.0	3.0
15	Disodium catechol-3,5- disulfonate	0.3	0.3
	Sodium sulfite	3.9	5.3
20	Potassium carbonate	39.0	39.0
	Disodium-N,N-bis (2-sulfonatoethyl) hydroxylamine	1.5	2.0
25	Potassium bromide	1.3	0.3
	Potassium iodide	1.3 mg	-
30	4-hydroxy-6-methyl-1,3,3a,7 tetrazaindene	0.05	-
	Hydroxylamine sulfate	2.4	3.3
35	2-methyl-4-[N-ethyl-N- (β-hydroxyethyl)amino] aniline sulfate	4.5	6.5
	Water to make	1.0L	1.0L
40	pH (adjusted by potassium hydroxide and sulfuric acid)	10.05	10.18

[0288]

45

(Bleaching solution)	[Tank solution] (g)	[Replenisher] (g)
----------------------	------------------------	----------------------

	Ferric ammonium 1,3-diaminopropanetetraacetate monohydrate	113	170
5	Ammonium bromide	70	105
	Ammonium nitrate	14	21
10	Succinic acid	34	51
	Maleic acid	28	42
	Water to make	1.0L	1.0L
15	pH (adjusted by ammonia water)	4.6	4.0

[0289]

(Fixer (1) Tank solution)

20 A 5:95 mixture (v/v) of the above bleaching tank solution and the below fixing tank solution  
pH 6.8

[0290]

25	(Fixer (2))	[Tank solution] (g)	[Replenisher] (g)
	Ammonium thiosulfate (750 g/L)	240 mL	720 mL
30	Imidazole	7	21
	Ammonium Methanthiosulfonate	5	15
35	Ammonium Methanesulfinat	10	30
40	Ethylenediamine tetraacetic acid	13	39
	Water to make	1L	1L
45	pH (adjusted by ammonia water and acetic acid)	7.4	7.45

[0291]

(Washing water)

Tap water was supplied to a mixed-bed column filled with an H type strongly acidic cation exchange resin (Amberlite IR-120B: available from Rohm & Haas Co.) and an OH type basic anion exchange resin (Amberlite IR-400) to set the concentrations of calcium and magnesium to be 3 mg/L or less. Subsequently, 20 mg/L of sodium isocyanuric acid dichloride and 150 mg/L of sodium sulfate were added. The pH of the solution ranged from 6.5 to 7.5.

[0292]

(Stabilizer)	common to tank solution and replenisher	(g)
Sodium p-toluenesulfinate		0.03
Polyoxyethylene-p-monononyl phenylether (average polymerization degree 10)		0.2
Sodium 1,2-benzisothiazoline-3-on		0.10
Disodium ethylenediamine tetraacetate		0.05
1,2,4-triazole		1.3
1,4-bis(1,2,4-triazole-1-ylmethyl) piperazine		0.75
Water to make		1.0 L
pH		8.5

35

[0293]

Further, the relative speed was obtained by the determination method of the above specific photographic speed.

Fog is defined by minimum density of yellow

density, magenta density and cyan density (DYmin, DMmin, DCmin). Speed of each color sensitive layer was defined as a logarithmic value of a reciprocal of an exposure amount giving 0.15 higher than each of DYmin, 5 DMmin, and Dcmin. The speed of sample 002 was expressed in a relative value assuming the speed of sample 001 as a control of 100.

[0294]

10 Table 3 shows the experimental results of specific photographic speed and relative speed together with the difference in the emulsion construction between samples 001 and 002. In sample 002 in which the emulsion of the present invention is used, increment in speed from sample 001 is apparent.

15



[0295]

[Table 3]

Table 3 Emulsion construction and speed

Sample No.	Emulsion in 6th layer	Emulsion in 11th layer	Emulsion in 14th layer	Specific speed	Relative speed (red)	Relative speed (green)	Relative speed (blue)	Remarks
001	Em-Y	Em-Z	Em-X	1450	100	100	100	Lightsensitive material for comparison
002	Em-2	Em-3	Em-1	1690	132	120	112	Lightsensitive material of the invention

[0296]

Next, samples 001 and 002 were loaded in 21 kinds  
of packaging units using the above sample resins 1 to  
21 to prepare 42 kinds lens-fitted photographic  
5 material packaging units. These are summarized in  
Table 4.

[0296]

[Table 4]

Table 4 Contents of resin used in packaging unit

\* Shaded portion indicates addition during reclamation

	Sample resin No.									
	1	2	3	4	5	6	7	8	9	10
Adsorbent ability (mg/g)	1.5	2.1	1.5	2.1	1.5	2.1	1.5	2.1	1.5	2.1
Molecular weight of added compound	S-8 (341)	S-8 (341)	S-1 (531)	S-1 (531)	S-8 (341)	S-8 (341)	S-1 (531)	S-1 (531)	S-8 (341)	S-8 (341)
History of extrusion (number)	1	1	1	1	5	5	5	5	5	5
Adsorbing ability supplementally added adsorbent during reclamation (mg/g)	-	-	-	-	-	-	-	-	1.5	1.5
Molecular weight of supplementally added compound during reclamation	-	-	-	-	-	-	-	-	-	-
Remarks	Comp.	Comp.	Comp.	Comp.	Comp.	Comp.	Comp.	Comp.	Inv.	Inv.



[0298]

A difference in minimum densities ( $\Delta$  fog) was identified. The difference is between a lens-fitted unit immediately processed and that left to stand under atmosphere at temperature of 45°C and humidity of 60% for 30 days, and then open a package and take out a film from an unit, and then development processed. The smaller the value is the better because deterioration in photographic performance is smaller.

10

[0299]

Table 5 shows the differences in minimum densities of yellow density, magenta density and cyan density of the 42 kinds lens-fitted units.

[0300]

[Table 5]

Table 5  $\Delta$  fog of each lens-fitted packaging unit

\* Shadowed portion indicates lens-fitted unit of the invention

Photosensitive material No. (ISO speed)	Sample resin No.									
	1	2	3	4	5	6	7	8	9	10
001 (1450)	R	0.03	0.03	0.03	0.04	0.15	0.15	0.14	0.16	0.03
	G	0.04	0.04	0.04	0.04	0.17	0.18	0.16	0.19	0.04
	B	0.03	0.03	0.03	0.03	0.13	0.14	0.13	0.14	0.03
002 (1690) Emulsion of the invention is used	R	0.05	0.06	0.04	0.05	0.25	0.26	0.22	0.27	0.06
	G	0.06	0.07	0.06	0.06	0.29	0.31	0.28	0.31	0.07
	B	0.04	0.05	0.04	0.05	0.21	0.24	0.21	0.18	0.06

Table 5 (continued)

Photosensitive material No. (ISO speed)	Sample resin No.										
	11	12	13	14	15	16	17	18	19	20	21
001 (1450)	R	0.04	0.03	0.03	0.03	0.04	0.03	0.03	0.03	0.03	0.03
	G	0.06	0.04	0.04	0.04	0.05	0.04	0.05	0.04	0.04	0.04
	B	0.03	0.03	0.04	0.03	0.03	0.03	0.03	0.03	0.03	0.03
002 (1690) Emulsion of the invention is used	R	0.06	0.04	0.06	0.05	0.07	0.04	0.06	0.03	0.04	0.04
	G	0.07	0.05	0.07	0.06	0.08	0.06	0.06	0.04	0.06	0.06
	B	0.05	0.03	0.05	0.04	0.06	0.04	0.04	0.03	0.04	0.03

[0301]

It is apparent from Table 5 that, in the use of a  
lightsensitive material highly sensitized with an  
emulsion of high aspect ratio such as the photographic  
5 lightsensitive material 001, fog occurs with the  
passage of storage time even if use is made of virgin  
resins such as sample resins 1 to 4. The deterioration  
of storage fog by reclaimed resins such as sample  
resins 5 to 8, although recognized with respect to  
10 samples including the photographic lightsensitive  
material 001, is far conspicuous with respect to the  
photographic lightsensitive material 002 including an  
emulsion of high aspect ratio.

[0302]

15 However, with respect to the lens-fitted packaging  
units wherein the sample resins 9 to 21 of the present  
invention are combined with the photographic  
lightsensitive material 002, it is apparent that this  
problem is remedied. Hence, even if the reclaimed  
20 resins are to be employed, lens-fitted packaging units  
which are lessened in the storage life deterioration as  
compared with the use of virgin resins can be provided.

[0303]

25 First, with respect to sample resins 9 to 12,  
there is recognized an improvement by the addition of  
carbon black as a substance capable of providing  
adverse effects on photographic properties at the time

of reclamation. The effect of improvement is most conspicuous with respect to sample resin 12 exhibiting an acetaldehyde gas equilibrium adsorption amount of 2 mg/g or more.

5 [0304]

Further, with respect to sample resins 13 to 16, an improvement is attained by the addition of a compound represented by the general formula (TS-I) or (TS-II) at the time of reclamation. The effect of improvement is more conspicuous in the use of sample resins 13, 14 and 16 wherein the molecular weight of compound is 300 or more than in the use of sample resin 15 wherein the molecular weight of compound is less than 300.

15 [0305]

It is apparent from the results of sample resins 17 to 21 that adding both carbon black and a compound represented by the general formula (TS-I) or (TS-II) at the time of reclamation is especially preferred.

20 [Brief explanation of Drawing]

[Figure 1]

Figure 1 is an exploded perspective view of lens-fitted film unit which constitutes one form of the lightsensitive material package of the present invention.

[Explanation of symbols]

2: Film unit body; 3: Body base; 4: Front cover; 5:



Rear cover; 6: Exposure unit; 10: Patrone chamber; 11:  
Film role chamber; 12: patrone; 13: Photographic film.

[Name of Document] Abstract

[Abstract]

[Object] To provide a light-sensitive material package wherein a molding containing a substance capable of adsorbing harmful substances, in particular gasified harmful substances, in reclaimed resins or capable of suppressing the occurrence thereof, which molding has thus no adverse effects on photographic light-sensitive materials, in particular a photographic light-sensitive material of high-speed film, is accommodated in order to expand the use of reclaimed resins in plastic material members.

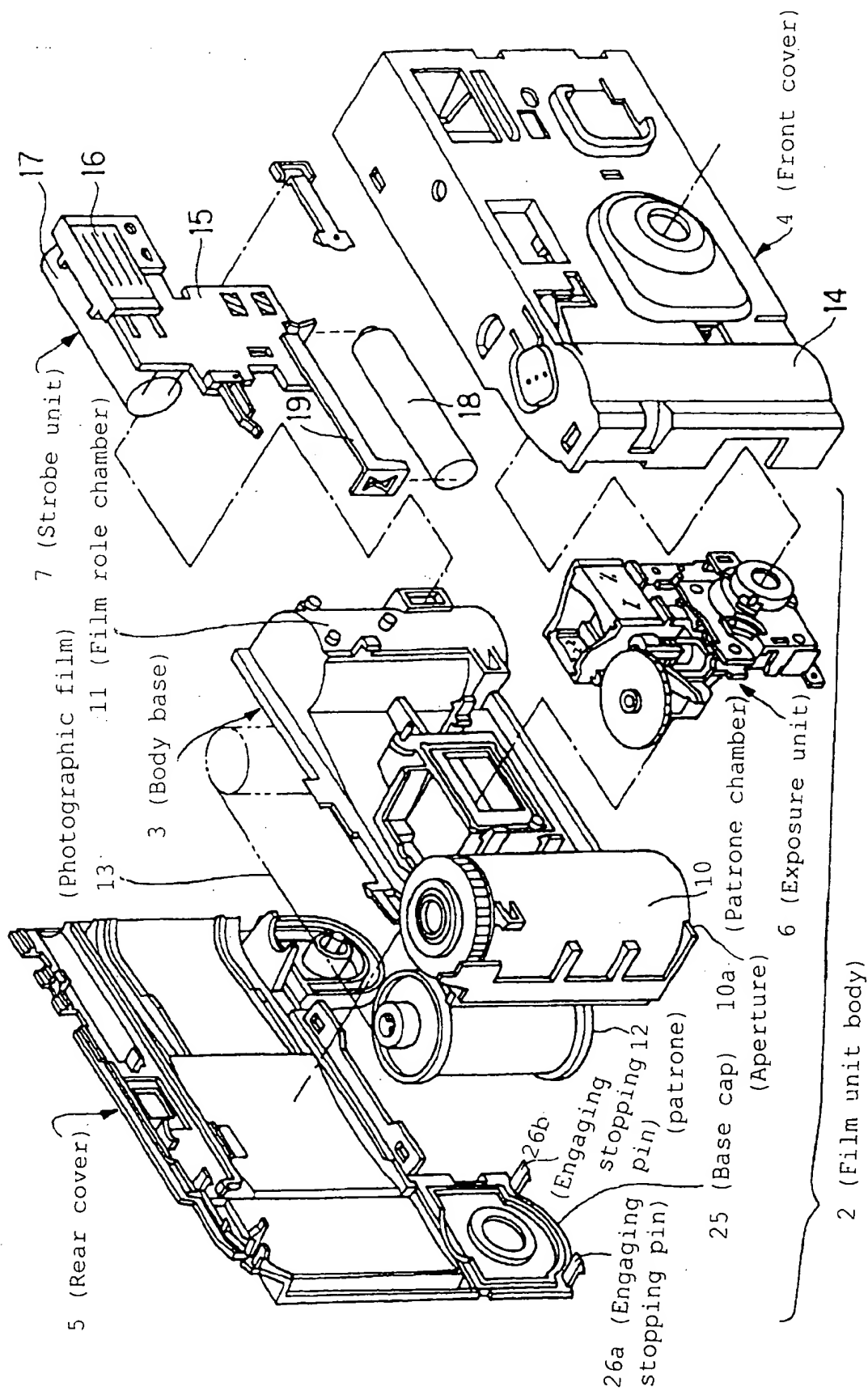
[Means to solve] A light-sensitive material package containing a silver halide color photographic light-sensitive material having at least one each of a red-sensitive, green-sensitive and blue-sensitive silver halide emulsion layer on a support, and a plastic material member using a thermoplastic reclaimed resin, and the photographic light-sensitive material and the plastic material member being arranged in a common gas-phase atmosphere and sealed in the package, characterized in that 60% or more of the total projected area of silver halide grains contained in at least one of the light-sensitive emulsion layers is occupied by tabular silver halide grains having an aspect ratio of 8.0 or more, and the plastic material member is that produced from a resin to which a

substance capable of adsorbing a substance having an adverse effect on a photographic property has been supplementally added prior to molding thereof.

[Selected Drawing] None

[Name of Document) Drawing

[Figure 1]



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